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<p>(54) Title: TOPICAL COMPOSITIONS COMPRISING PROTECTED FUNCTIONAL THIOLS</p> <p>(57) Abstract</p> <p>This invention relates to a topical composition for treating amino acid based substrates comprising a protected thiol compound having the formula R—(S—Pr)_m where R is a functional group, S is sulfur, and Pr is a heterocyclic protecting group, and m is an integer between 1 and 100. The invention further relates to systems which comprise this protected thiol compound and an activating mechanism. The protected thiol compounds of the present invention may be used in hair care compositions, textile care compositions, cosmetic compositions, oral care compositions, skin care, nail care, laundry care, acne care and animal care compositions. A preferred embodiment of the present invention provides a silicone composition and method for making. The composition comprises a polysiloxane or silicone resin, at least one linker, and at least one molecular hook.</p>		

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**TOPICAL COMPOSITIONS COMPRISING
PROTECTED FUNCTIONAL THIOLS**

TECHNICAL FIELD

The present invention relates to topical compositions for treating amino acid based substrates. The topical compositions comprise cosmetic or therapeutic actives that have been bound to a protected thiol which acts as a molecular 'hook' to impart "permanent" benefits to the amino acid based substrates. The amino acid based substrates can include, for example, proteinaceous materials such as keratin, as found in human hair, animal fur, velus hair on skin, finger and toe nails; various animal body parts, such as horns, hooves and feathers; other naturally occurring protein containing materials, such as wool; and synthetic polymers. Of particular interest are compositions which deliver and attach cosmetic actives to human hair.

BACKGROUND OF THE INVENTION

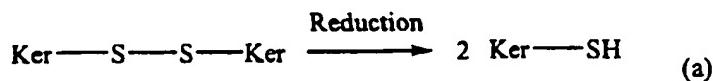
It is well known in the art that amino-acid based fibers, particularly hair, can be treated with agents that deliver one or more cosmetic benefits, such as conditioning, styling or setting. The conventional cosmetic products which have been known and used commercially have relied upon two key factors: deposition and retention. The cosmetic actives must first be physically deposited onto the hair fiber where the active imparts a benefit to a sufficient degree. Secondly, it is essential that the cosmetic actives be retained on the hair beyond the completion of the treatment. For example, when hair is rinsed to remove unwanted excess composition (e.g., a conditioner) a sufficient amount of the cosmetic active (humectant, moisturizer, etc.) remains bonded to the hair so as to maintain the desired cosmetic benefits.

The bonding of the cosmetic active material to the hair is generally of the nature of physico-chemical intermolecular forces, e.g., physisorption. Such physical forces comprise, for example, hydrogen bonding, electrostatic interactions, van der Waals interactions and the like. As an example, cationic cosmetic agents, generally of the quaternary ammonium type, are known

to bond to hair by virtue of the interaction of their cations with anionic amino acid residues within keratin, e.g., glutamic acid, aspartic acid, cysteic acid etc. A major problem, however, with physisorption is the inevitable short lived retention of the cosmetic agent on hair. This is due to the relatively weak physical forces which bind the cosmetic to hair and which are easily disrupted by other treatments, e.g. washing. And, given the frequent need for treating hair, performance retention is difficult to achieve and generally does not last in excess of the period between washes.

One approach that has been disclosed in the art to overcome the above problem to provide truly durable or "permanent" cosmetic benefits to hair that are retained through multiple washes is to utilize molecular "hooks" to chemically bond cosmetic actives to hair keratin, e.g., chemisorption. Chemisorption results in a permanent juncture that is essentially resistant to physical wear from subsequent washings or physical abrasion. Two conventional approaches to achieve chemisorption comprise the use of either electrophilic reactive moieties or thiol reactive moieties attached to the cosmetic active. Electrophilic reactive moieties are designed to react with thiol functional groups present in hair and thiol reactive moieties are designed to react with electrophilic functional groups within the hair to create a covalent bond.

U.S. Patent 5,523,080 issued to Gough et al. on June 4, 1996, U.S. Patent 5,211,942 issued to Deppert et al. on May 18, 1993, and UK Patent Application GB2197887 published on June 2, 1988, all disclose the use of electrophilic moieties. These electrophilic chemistries include the use of azlactone, (haloalkyl)trialkylammonium salts, and acyl halides. All of these molecular hooks have potential to react with hair via an electrophilic mechanism which necessitates sufficient nucleophilic functional groups present within the keratin structure with which to react to a sufficient degree to achieve the desired durable benefits. For hair, this poses a dilemma in that it is generally known that hair does not naturally possess a sufficient concentration of nucleophilic functional groups under consumer mild conditions to drive the reaction. However, it is also generally known that by chemically reducing the disulfide bonds present within the cystine amino acid residues of hair, in a manner analogous to cold waving, sufficient quantities of nucleophilic cystine residues can be produced. Pre-reduction of hair, to enable the chemical reaction with suitable electrophilic cosmetic actives, is illustrated below in reactions (a) and (b). Ker represents keratin protein, R-X represents an alkyl halide electrophilic cosmetic active, R represents a cosmetic agent and X⁻ is a halide anion such as bromide or chloride.





While electrophilic cosmetic actives have been demonstrated effective at providing durable cosmetic benefits to hair, the approach has disadvantages that arise from the required pre-reduction step. First, the reduction step is known to be a very harsh chemical process that imparts considerable damage to hair. Second, the effective reducing agents are typically mercaptans of low molecular weight and are odiferous. The pre-reduction process generates unpleasant malodor that remains on the hair for greater than a week time in most instances. Thirdly, in addition to unpleasant malodor and resulting hair damage, the required pre-reduction imparts an additional step to the process with attendant added inconvenience to the user.

U.S. Patent 5,087,733 and U.S. Patent 5,206,013 both issued to Deppert et al. on February 11, 1992 and April 27, 1993 respectively, as well as U.S. Patent 4,973,475 issued to Schnetzinger and Ciaudelli on November 27, 1990, describe the use of quaternary ammonium thiols which fall under the general class of nucleophilic reactive actives. Such nucleophilic actives are generally intended to react with cystine amino acid residues present within hair via formation of a mixed disulfide covalent linkage as is demonstrated in the chemical equation (c).



Ker represents keratin and R-SH represents a suitable nucleophilic active where R is a cosmetic agent and -SH representing a nucleophilic moiety. It is generally known that thiols are the preferred nucleophilic reactive moieties that possess enough reactive strength to chemically bond with the disulfide bond of cystine, Ker-S-S-Ker, under safe and mild consumer conditions (e.g., relatively non toxic, less than 120°F, pH 2 to 11). Most other prospective nucleophilic molecular handles are either highly toxic (e.g., selenols), or are unreactive under mild conditions (e.g., alkoxides with pKa ~ 15).

There are two major drawbacks to the use of nucleophilic thiols as reactive moieties to form covalent bonds with keratin. First, thiol nucleophilic moieties are known to be unstable in the presence of air. Atmosphere induced oxidation of the thiols to the corresponding, and unreactive, disulfide as is shown in the following equation (d) where R-SH represents a suitable nucleophilic cosmetic active R being an alkyl cosmetic agent and -SH representing the nucleophilic moiety:



Such oxidative deactivation of the nucleophilic thiol moieties severely limits their mode of usage. Thus, nucleophilic thiols are generally not stable enough to be utilized as such in a large majority

of current product forms, i.e., re-sealable hair care packages widely used for shampoos, rinse-off conditioners etc. Second, the nucleophilic thiol moiety has very little affinity for hair keratin and has very low aqueous solubility, both of which hinder its performance in generating durable cosmetic benefits, especially when attached to hydrophobic, insoluble cosmetic actives, i.e., hydrocarbon conditioners, in-soluble polymers etc.

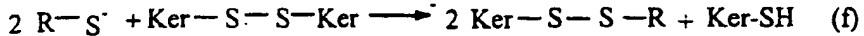
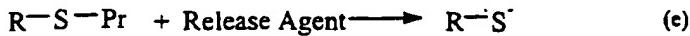
Despite major efforts, however, the art has not yet provided molecular "hooks" that provide durable cosmetic benefits to hair that last beyond twenty shampoos and which do not necessitate the damaging cold waving of hair, i.e. hair reduction, while being oxidatively stable in solution for long term storage in a variety of currently used product forms, e.g., rinse off conditioners, two-in-one shampoos, etc.

The present invention is concerned with topical compositions comprising classes of compounds containing at least one thiol in a protected form, which can be released to provide a -SH or -S⁻ group prior or simultaneous to use. These protected thiols are referred to herein as "hooks". It is understood that within the scope of this invention that functional thiols as represented herein include both the protonated thiol, R-SH, and unprotonated thiolate, R-S⁻.

It has now been discovered that, surprisingly, such "hooks", R-(S-Pr)_m, provide durable cosmetic benefits, when applied to amino-acid based substrates without a damaging cold-waving process, that last beyond twenty shampoos. It has also been discovered that the molecular "hooks" of the present invention provide improved oxidative stability versus conventional thiols by virtue of the appended protecting moiety to the thiol group that reduces the oxidative susceptibility of the sulfur atom(s). Furthermore, it has been found that these molecular "hooks" significantly outperform conventional nucleophilic thiol hooks in providing durable cosmetic benefits. While not being bound by theory, the latter observed effect is believed to be due to the unexpected high affinity for keratin provided by certain polarizable electrophilic groups which offer improved solubility and possibly even electrostatic interaction with the charged keratinaceous substrate. Presumably, such greater affinity affords enhanced diffusion and adsorption to the fiber by the cosmetic active enabling greater opportunity for binding.

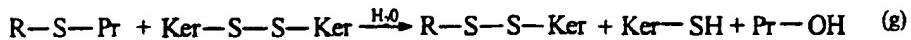
The 'hooks' of the present invention enable the achievement of durable cosmetic benefits that are resistant to cleansing or shampooing from essentially a non-damaging process that is void of cold waving. The binding of the cosmetic actives provided by these molecular 'hooks' is to such a degree of durability that the measured cosmetic benefits will remain in hair for multiple shampoo cycles, e.g. eight to twenty or more. While not being restricted by theory, it is believed that such a high degree of durability is due to the formation of covalent bonds between the cosmetic active and the keratinaceous substrate.

This bond formation may occur in either of two ways. First, the protected thiol compound can be mixed with a activating release agent to form the free functional thi l, reaction (e). The free thiol will then react with the substrate thereby attaching the functional group, reaction (f).



R represents the cosmetic active, Ker represents the keratin protein, S represents sulfur, -SH represents the thiol and Pr represents the protecting group. Based on theory, the above thiol-protecting group bond is broken via some form of activation yielding the reactive unprotected thiol which would then be capable of forming a mixed disulfide with keratin disulfides via nucleophilic displacement. Such activation could be accomplished via hydrolysis or by the action of a nucleophile other than water, either in the substrate itself or in a separate composition. Such hydrolysis or nucleophilic attack can itself be enhanced in several way such as by application of a source of energy or catalysis. This mixing may be done prior to use or simultaneously, during application to the substrate. Where the mixing occurs simultaneously to application, the release of the protecting group occurs in-situ on the substrate.

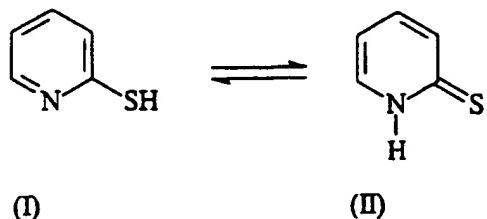
Surprisingly, it has been found that, alternatively, the formation of the covalent bonds may occur without mixing with a release agent. Direct reaction of certain protected thiol compounds with the hair occurs via the formation of a mixed disulfide with the existing disulfide bonds within keratin as is illustrated below, reaction (g):



While not being bound to theory, it is believed that the keratin itself could be activating the thiol protecting group bond to enable the observed durable benefits. The resulting free protecting group may or may not undergo decomposition reactions. The byproducts of the activation of the sulfur-heterocyclic bond will usually be removed from the substrate by washing.

The cosmetic agent, R, of the present invention may be monofunctionalized, i.e. the cosmetic active moiety, R, carries a single molecular "hook" connected to the cosmetic agent via a sulfur-sp³ carbon bond, or it may be bis- or multi- functionalized, i.e. the cosmetic active, R, may carry two or more sp³ electrophiles connected to the cosmetic agent via separate sulfur-sp³ carbon bonds. The latter may be useful for example in achieving a greater degree of chemical bonding of the cosmetic agent to the substrate or for generating bonds between adjacent features of the substrate, e.g. producing a cross-linking effect. The latter may be employed to improve the strength or tensile properties of keratinaceous fibers or for enhancing the degree of hair setting compared with prior art hair methods.

It is understood that within the scope of this invention, numerous potentially and actually tautomeric compounds are involved. Thus, for example, 2-mercaptopyridine (I) exists under known conditions in the pyridine-2-thione tautomer form (II). It is to be understood that when this development refers to a particular structure, all of the reasonable additional tautomeric structures are included. In the art, tautomeric structures are frequently represented by one single structure and the present invention follows this general practice.



Preferred embodiments of the present invention are related to functional silicone compositions. More specifically, these embodiments are related to functional silicone compositions which are used in the cosmetics industry.

Silicones are widely used in hair care products due to the conditioning benefit that they impart to hair. By modern day technology, the silicone is deposited on hair during the application process but is held only by weak physical forces, such as hydrogen bonding or van der Waals interactions. Because the forces are weak, the benefits of silicone by deposition are short lived. Beneficial conditioning effect can also be caused by treating hair with silanol capped amino-functionalized silicones. These can undergo condensation cure reactions on hair to form somewhat durable films. Generally, conditioning benefits are attributed to the deposition of high molecular weight, high viscosity fluids and gums which can weight down the hair.

It is widely known by those skilled in the art that covalent bonding is the key to "permanent" hair treatment. Processes which alter the structure of the hair, such as permanent wave and color treatment methods, do provide longer lasting effects. These processes include glycolate reduction and peroxide reoxidation. However, the processes are very damaging to hair and can only be carried out every eight to ten weeks.

Gough et al. in U.S. Patent Nos. 5,523,080 and 5,525,332 describe the synthesis of silicone-azlactone polymers which exhibit covalent bonding and "permanent" conditioning benefit. Gough et al. discuss incorporating an azlactone-functionalized copolymer which consists of vinylazlactone and methacryloyl polydimethylsiloxane monomers into a silicone-active group-hair structure. The hair treatment using the silicone-azlactone polymers did not consist of the steps of reduction with a glycolate or reoxidation with peroxide.

New compositions are constantly being sought which impart improved hair care benefits without a harsh, damaging chemical treatment.

SUMMARY OF THE INVENTION

This invention relates to a topical composition for treating amino acid based substrates comprising a protected thiol compound having the formula



where R is a mono or multivalent cosmetically active functional group, S is sulfur, and Pr is a protecting group, and m is an integer between 1 and 100. The invention further relates to systems which comprise this protected thiol compound and an activating mechanism. The protected thiol compounds of the present invention may be used in hair care compositions, textile care

compositions, cosmetic compositions, oral care compositions, skin care, nail care, laundry care, acne care and animal care compositions.

A preferred embodiment of the present invention provides a silicone composition and method for making. The composition comprises a polysiloxane or silicone resin, at least one linker, and at least one molecular hook.

DETAILED DESCRIPTION OF THE INVENTION

The present invention relates to topical compositions which provide attachment of functional groups to amino acid based substrates.

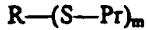
As used herein, "cystine containing, amino acid based substrates" are proteinaceous materials which contain the amino acid cystine in its amino acid sequence. The phrase "amino acid sequence" refers to a specific configuration of the amino acids comprising a protein. Cystine amino acid units are represented by Ker-S-S-Ker and cysteine amino acid units by Ker-SH. The compositions of the present invention can be used to attach functional groups to materials such as keratin, as found in human and animal hair, skin and nails; various animal body parts such as horns, hooves and feathers; and other naturally occurring protein containing materials, such as wool.

The topical compositions of the present invention can comprise, consist of, or consist essentially of the essential elements and limitations of the invention described herein, as well as any of the additional or optional ingredients, components, or limitations described herein.

All percentages, parts and ratios are by weight of the total composition, unless otherwise specified. All such weights as they pertain to listed ingredients are based on the specific ingredient level and, therefore, do not include solvents, carriers, by-products, filler or other minor ingredients that may be included in commercially available materials, unless otherwise specified.

PROTECTED THIOL COMPOUND

The compositions of the present invention comprise a protected thiol compound having the formula



where R is a mono or multivalent cosmetically active functional group, S is sulfur, Pr is a protecting group, and m is an integer ranging from about 1 to about 100, preferably from about 1 to about 50, more preferably equal to 1 to about 20, and most preferably equal to 1 to about 5.

Typically, the protected thiol compounds of the present invention are present in the compositions of the invention in an amount from about 0.000001% to about 30%, preferably

from about 0.0001% to about 25%, more preferably from 0.01 to about 20%, even more preferably from about 0.1% to about 10%, and most preferably from about 1% to about 5%, by weight of the composition. Suitable ranges of amounts will generally depend upon the functional group in question. For example, hair conditioners that are modified with the molecular 'hooks' of the present invention will normally be present from about 0.01% to 10% by weight of the composition, and hair styling agents that are modified such as cationic conditioning polymers or polyisobutylene will normally be present from about 0.01 to 10% by weight of the composition, perfluoropolyether materials that are modified may be present from about 0.000001 to 0.1% by weight of the composition, hair dye chromophoric materials may be present from 0.1% to 10% and other film forming polymers that are modified may be present from about 0.01 to 2% of the composition.

The protected thiol compound comprises from about 1 to about 100, preferably from about 1 to about 50, more preferably from about 1 to 20, and most preferably equal from 1 to about 5 sulfur atoms, each linked to one protective group.

Protecting Group

The protected thiol compounds of the present invention comprise 1 to about 100, preferably 1 to 50, more preferably 1 to 20 and most preferably 1 to 5 protecting groups. The protecting group may be selected from the range consisting of heterocyclic protecting groups, sp^2 aliphatic trigonal carbon protecting groups, sp^3 carbon protecting groups, metal based protecting groups, non-metal and metalloid based protecting groups, energy-sensitive protecting groups and mixtures thereof. The protecting group is preferably selected from the range consisting of heterocyclic protecting groups, sp^2 aliphatic trigonal carbon protecting groups, sp^3 carbon protecting groups and non-metal protecting groups. The protecting group is more preferably selected from heterocyclic protecting groups, sp^2 aliphatic trigonal carbon protecting groups and non-metal protecting groups.

Heterocyclic Protecting Groups - The cosmetic composition of the present invention comprises a protected thiol compound wherein the thiol protective group may be a heterocyclic ring or ring system. Heterocyclic groups that are suitable for use in the present invention include mono- or polyunsaturated or saturated heterocyclic rings, heterocyclic ring systems, fused heterocyclic ring systems, substituted heterocyclic rings, substituted heterocyclic ring systems or substituted fused heterocyclic ring systems. The heterocyclic rings contain from about three to about thirty members, and may contain electronegative heteroatoms including N, O, S, or P. The heterocyclic rings or ring systems also may contain exocyclic double bonds of the C=M type wherein M is O, S, NA^1A^2 , CA^1A^2 . A^1 and A^2 used here, and A^3 and A^4 used hereinafter, each represent,

independently from one another, a monovalent group which can be the cosmetic active group, R, or H or any of the following: a straight, branched or mono- or polycyclic aliphatic, mono or polyunsaturated alkyl, aryl, heteroalkyl, heteroaliphatic or heteroolefinic system including 1 to 30 carbon atoms together with 0-15 heteroatoms, especially O, N, S, P, Si, and can incorporate one or more substituents including, but not limited to, poly or perfluoro substitution.

Optional substituents on the heterocyclic ring or ring system, X¹, X², X³, X⁴, X⁵..., can be selected from electron withdrawing, electron neutral, or electron donating groups with Hammett sigma para values between -1.0 and +1.5 which can be non-ionic, zwitterionic, cationic or anionic comprising for example C-linked groups of the classes defined above as A¹, A², A³, and A⁴; S-linked groups including SA¹, SCN, SO₂A¹, SO₂A¹, SSA¹, SOA¹, SO₂NA¹A², SNA¹A², S(NA¹)A², S(O)(NA¹)A², SA¹(NA²), SONA¹A²; O-linked groups including OA¹, OOA¹, OCN, ONA¹A²; N-linked groups including NA¹A², NA¹A²A³, NC, NA¹OA², NA¹SA², NCO, NCS, NO₂, N=NA¹, N=NOA¹, NA¹CN, N=C=NA¹, NA¹NA²A³, NA¹NA²NA³A⁴, NA¹N=NA²; other miscellaneous groups including COHal, CON₃, CONA¹₂, CONA¹COA², C(=NA¹)NA¹A², CHO, CHS, CN, NC, Hal, and derived groups that connect one or more of X¹, X², X³, X⁴, X⁵ via a ring system;

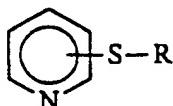
Ak is A¹, A², A³, and A⁴ or X¹, X², X³, X⁴, X⁵...

Hal is F, Cl, Br, or I.

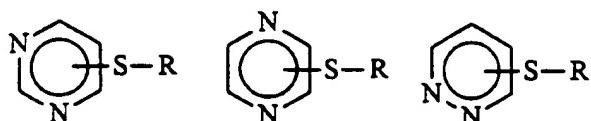
H is hydrogen, O is oxygen, N is nitrogen, C is carbon, S is sulfur, Cl is chlorine, Br is bromine, I is iodine, F is fluorine, R is any cosmetically active, functional group or benefit agent as described herein below.

The invention includes the following preferred non-limiting heterocyclic exemplary classes and their X¹, X², X³, X⁴, X⁵... substituted derivatives [Herein referred to as Class I]:

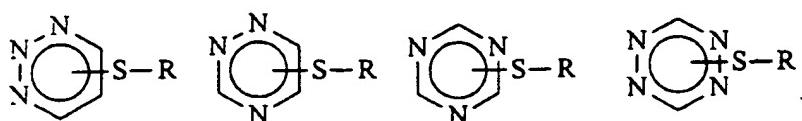
- Six membered heterocycles with a single heteroatom such as pyridine:



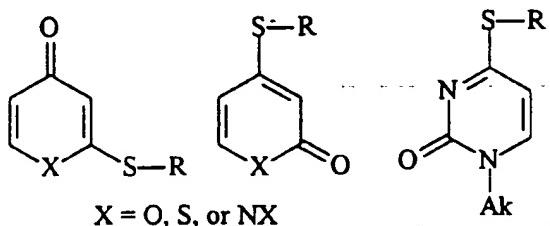
- Six membered heterocycles with two heteroatoms such as pyrimidines, pyrazines and pyridazines:



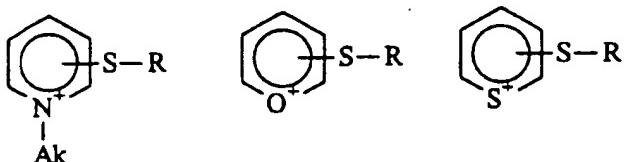
- Six membered heterocycles with three and four heteroatoms such as triazines and tetrazines:



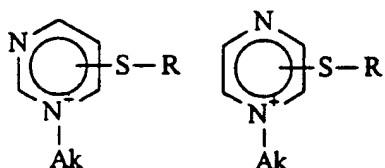
- Six membered O, N, and/or S containing heterocycles with C=O, C=S or C=C exocyclic groups:



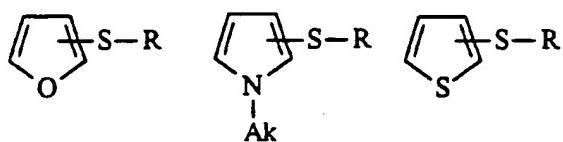
- Cationic six membered heterocycles with one heteroatom such as pyridinium, pyrylium, and thiopyrylium salt derivatives:



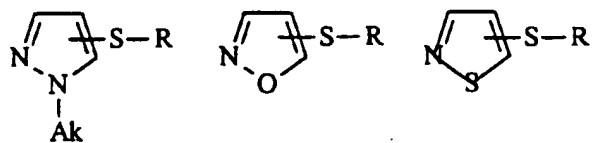
- Cationic six membered heterocyclics with two heteroatoms such as pyrimidinium and pyrazinium salt derivatives:



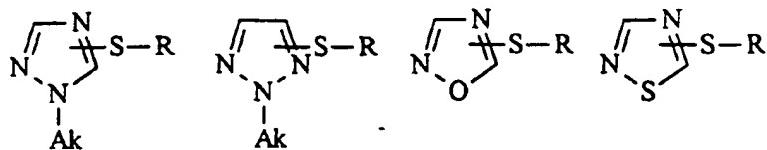
- Five membered heterocycles with one heteroatom such as furans, pyrroles, and thiophenes:



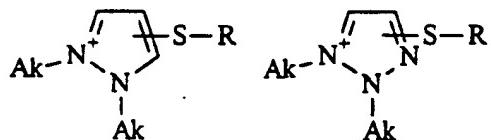
- Five membered heterocycles with two heteroatoms such as pyrazoles, isoxazoles, and isothiazoles:



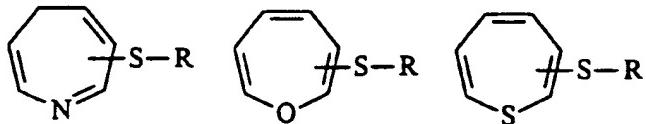
- Five membered heterocyclics with three heteroatoms such as 1,2,4-triazoles, 1,2,3-triazoles, 1,2,4-oxadiazoles, and 1,2,4-thiadiazoles:



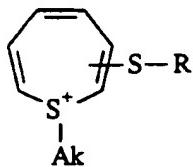
- Five membered cationic heterocycles with two or more heteroatoms such as pyrazolium and triazolium:



- Seven membered heterocycles such as azepines, oxepins and thiepins:

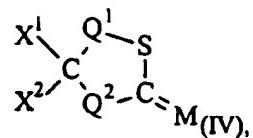
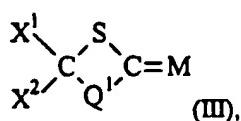
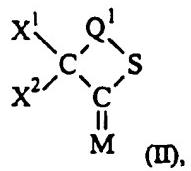


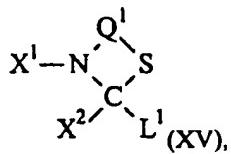
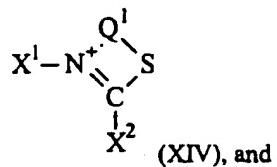
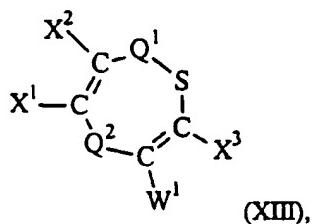
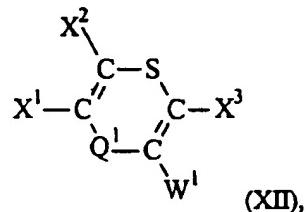
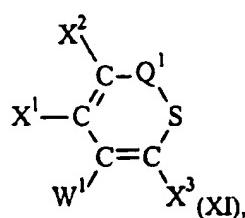
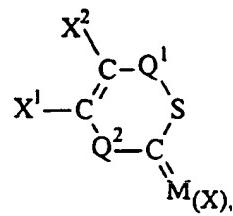
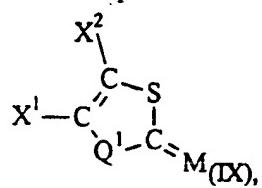
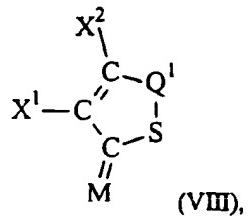
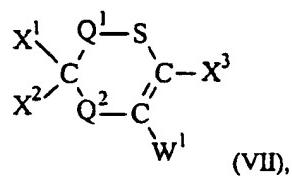
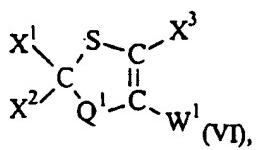
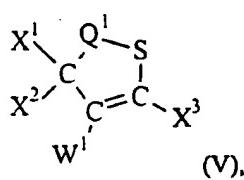
- Seven membered cationic heterocycles such as thiepinium salts:



and related variations including combinations of the above heterocycles in a ring system and fused systems both of which may include carbocyclic rings without heteroatoms. The cationic heterocycles will also incorporate a Cl⁻, Br⁻, I⁻ or other suitable negatively charged counterion.

The invention may also include heterocyclic compounds comprising the cosmetic active, R, that are capable of generating a thiol via a ring-opening mechanism. Such compounds are represented by the following structures:





wherein at least one cosmetic group, R, comprises or is attached to any of the X¹, X², X³ groups.

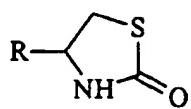
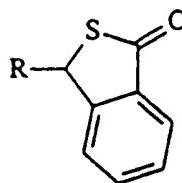
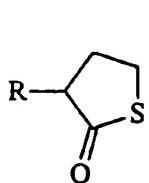
Q¹ and Q² represent, independently from one another, a divalent group comparable to A¹ but with the open valencies separated by 0 to 4 atoms.

W¹ represents an electron withdrawing group with a Hammett sigma para value more positive than 0.10 comprising C-linked groups of the classes defined above as A¹, A², A³; S-linked groups including SA¹, SCN, SO₂A¹, SO₂A¹, SSA¹, SOA¹, SONA¹A², SO₂NA¹A², SNA¹A², S(NA¹)A², S(O)(NA¹)A², SA¹(NA²); O-linked groups including OA¹, OOA¹, OCN, ONA¹A²; N-linked groups including NA¹A², NA¹A²A³⁺, NC, NA¹OA², NA¹SA², NCO, NCS, NO₂, N=NA¹, N=NOA¹, NA¹CN, N=C=NA¹, NA¹NA²A³, NA¹NA²NA³A⁴, NA¹N=NA²; other miscellaneous

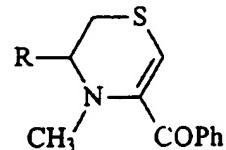
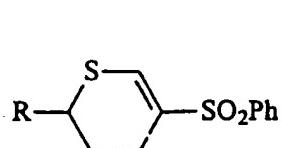
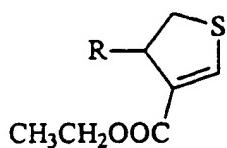
groups including COHal, CON₁, CONA¹₂, CONA¹'COA², C(=NA¹)NA¹A², CHO, CHS, CN, NC, Hal, and derived groups that connect one or more of X¹, X², X³, X⁴, X⁵ via a ring system; L¹ is a suitable leaving group including but not limited to SA¹, OA¹, or NA¹A².

Below are some non-limiting representative examples for each of the above heterocyclic structures (II through XV) that are capable of generating a thiol via a ring-opening mechanism:

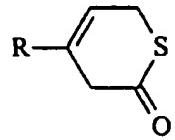
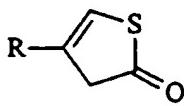
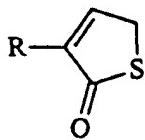
A thiolactone, thiophthalide, and thiazolidinone (classes II, III and IV),



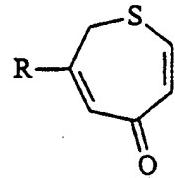
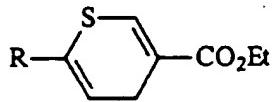
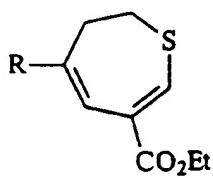
A dihydrothiophene, dihydrothiopyran, and dihydro-1,4-thiazine (classes V, VI and VII),



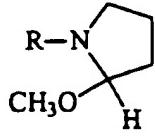
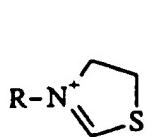
Unsaturated thiolactones and a dihydrothiapyrone (classes VIII, IX and X),



A dihydrothiepin, thiopyran and thiepinone (classes XI, XII and XIII),

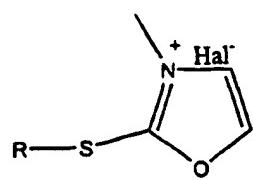
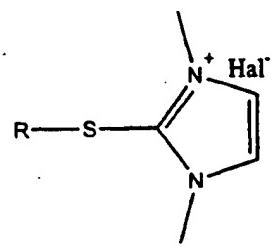
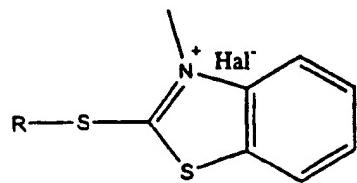
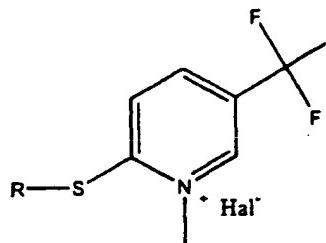
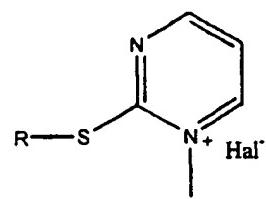


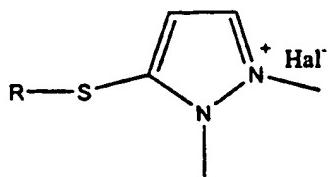
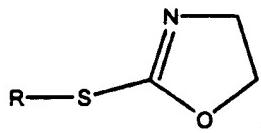
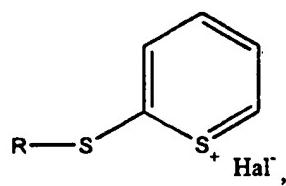
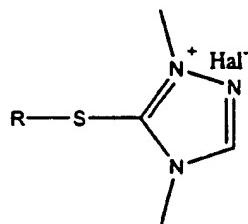
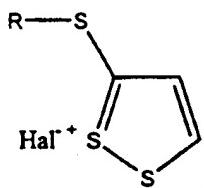
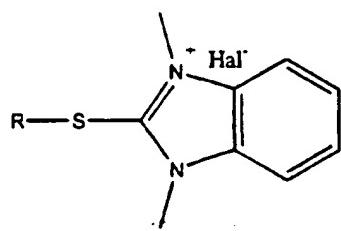
A dihydrothiazoline and 2-methoxythiazolidine (classes XIV and XV),

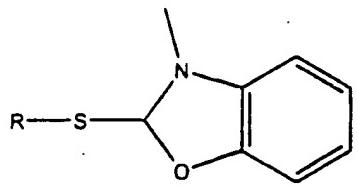
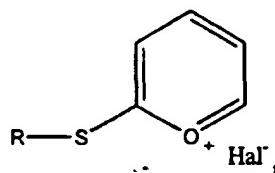


and other related derivatives.

Preferred protected thiol compounds of the heterocyclic thiol protective type include the following non-limiting examples:

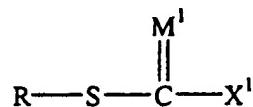






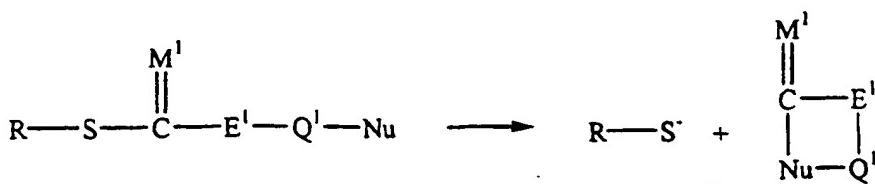
and mixtures thereof, wherein Hal^- is Cl^- , Br^- , Γ or any suitable negatively charged counterion.

sp^2 Aliphatic Trigonal Carbon Protecting Groups - The protecting groups of the present invention may comprise a sp^2 carbon moiety wherein the divalent sulfur atom is bonded on one side to the cosmetic active and on the other side to a sp^2 carbon atom. Protecting groups of the sp^2 aliphatic trigonal carbon type that are suitable for the present invention include (a) aliphatic trigonal carbon atoms double bonded to O, S, N, or C,



which includes derivatives of the following acids: thiocarboxylic ($\text{R}-\text{S}-\text{C}(\text{O})\text{CH}_2-\text{A}^1$), carbonodithioic ($\text{R}-\text{S}-\text{C}(\text{O})\text{S}-\text{A}^1$, $\text{R}-\text{S}-\text{C}(\text{S})\text{O}-\text{A}^1$), carbonothioic ($\text{R}-\text{S}-\text{C}(\text{O})\text{O}-\text{A}^1$), carbamothioic ($\text{R}-\text{S}-\text{C}(\text{O})\text{N}-\text{A}^1\text{A}^2$), dithiocarboxylic ($\text{R}-\text{S}-\text{C}(\text{S})\text{CH}_2-\text{A}^1$), carbonotrithioic ($\text{R}-\text{S}-\text{C}(\text{S})\text{S}-\text{A}^1$), carbamodithioic ($\text{R}-\text{S}-\text{C}(\text{S})\text{N}-\text{A}^1\text{A}^2$), carboximidothioic ($\text{R}-\text{S}-\text{C}(\text{NA}^1)\text{CH}_2-\text{A}^1$), carbonimidodithioic ($\text{R}-\text{S}-\text{C}(\text{NA}^1)\text{S}-\text{A}^1$), and carbonimidothioic ($\text{R}-\text{S}-\text{C}(\text{NA}^1)\text{O}-\text{A}^1$) acids. Suitable sp^2 aliphatic trigonal carbon type protecting groups for use in the topical compositions of the present invention do not include carbamimidothioic acids.

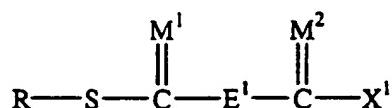
The invention also includes (b) related sp^2 carbon derivatives that are capable of releasing a cosmetic thiol via an intramolecular nucleophilic attack and release mechanism,



(c) sp^2 carbon derivatives that are capable of rearranging to produce a cosmetic containing thiol via an intramolecular nucleophilic attack and rearrangement mechanism,



as well as (d) trigonal carbon electrophiles of the anhydride, thioanhydride, and secondary/tertiary amide type,



and related aliphatic trigonal carbon variations. The cationic protecting groups will also incorporate a Cl^+ , Br^+ , I^- or other suitable negatively charged counterion.

M^1, M^2 are O, S, NA^1 , NOA^1 , NA^1A^{2+} , $\text{CA}^1=\text{CA}^2\text{Y}^1$, SA^+ , OA^+ .

E^1 is O, S, NA^1 , CA^1A^2 .

Nu is $\text{NHA}^1\text{A}^{2+}$, NA^1A^2 , OHA^{1+} , OA^1 .

X^1 represents an electron withdrawing or electron donating group with a Hammett sigma para value between -1.0 and +1.5 which can be non-ionic, zwitterionic, cationic or anionic comprising for example C-linked groups of the classes defined below as A^1 , A^2 , A^3 ; S-linked groups including SA^1 , SCN , SO_2A^1 , SO_3A^1 , SSA^1 , SOA^1 , SONA^1A^2 , $\text{SO}_2\text{NA}^1\text{A}^2$, SNA^1A^2 , $\text{S}(\text{NA}^1)\text{A}^2$, $\text{S}(\text{O})(\text{NA}^1)\text{A}^2$, $\text{SA}^1(\text{NA}^2)$; O-linked groups including OA^1 , OOA^1 , OCN , ONA^1A^2 ; N-linked groups including NA^1A^2 , $\text{NA}^1\text{A}^2\text{A}^{3+}$, NC , NA^1OA^2 , NA^1SA^2 , NCO , NCS , NO_2 , $\text{N}=\text{NA}^1$, $\text{N}=\text{NOA}^1$, NA^1CN , $\text{N}=\text{C}=\text{NA}^1$, $\text{NA}^1\text{NA}^2\text{A}^3$, $\text{NA}^1\text{NA}^2\text{NA}^3\text{A}^4$, $\text{NA}^1\text{N}=\text{NA}^2$; other miscellaneous groups including COHal , CON_3 , CONA^1_2 , $\text{CONA}^1\text{COA}^2$, $\text{C}=(\text{NA}^1)\text{NA}^1\text{A}^2$, CHO , CHS , CN , NC , Hal , and derived groups that connect one or more of $\text{X}^1, \text{X}^2, \text{X}^3, \text{X}^4, \text{X}^5$ via a ring system;

A^1, A^2 represent, independently from one another, a monovalent group which can be the cosmetic active group, R, or H or any of the following: a straight, branched or mono- or polycyclic aliphatic, mono or polyunsaturated alkyl, aryl, heteroalkyl, heteroaliphatic or heteroolefinic system including 1 to 30 carbon atoms together with 0-15 heteroatoms, especially O, N, S, P, Si, and can incorporate one or more substituents including, but not limited to, poly or per fluoro substitution.

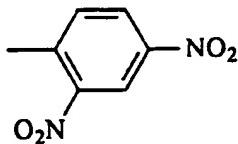
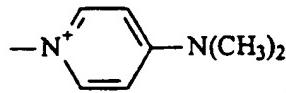
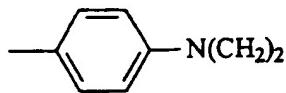
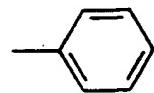
Q is a divalent group comparable to A¹ but with the open valencies separated by 2 to 7 atoms.

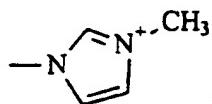
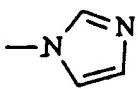
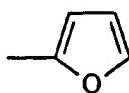
Hal is F, Cl, Br, or I.

Y¹ represents electron an withdrawing substituent with a Hammett sigma para value more positive than 0.10. Such electron withdrawing substituents which can be nonionic, zwitterionic, cationic or anionic include the following non-limiting examples: NO₂, CN, COOA¹, CONA¹A², C(O)A¹, SO₂A¹, SO₂OA¹, NO, COHal, CON₃, CONA¹A², CONA¹COA², C(=NA¹)NA²A³, C(S)A¹, NC, SCN, SO₂A¹, SOA¹, SO₂NA¹A², SNA¹A², S(NA¹)A², S(O)(NA¹)A², NA¹A²A³⁺, SA¹A²⁺.

H is hydrogen, O is oxygen, N is nitrogen, C is carbon, S is sulfur, Cl is chlorine, Br is bromine, I is iodine, F is fluorine, R is any cosmetically active functional group or benefit agent as described herein below.

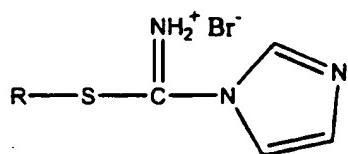
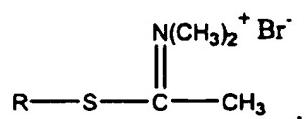
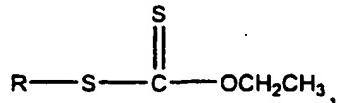
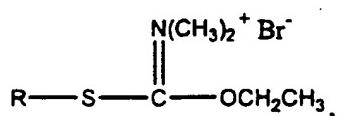
Non-limiting examples of suitable X¹ groups are as follows:

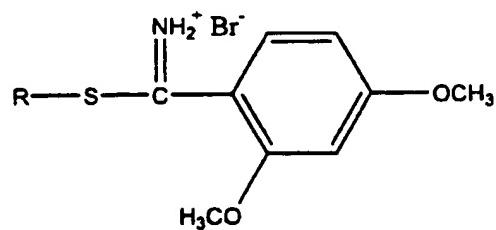
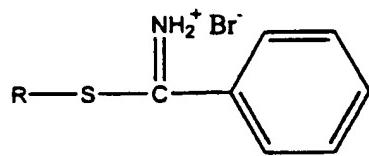
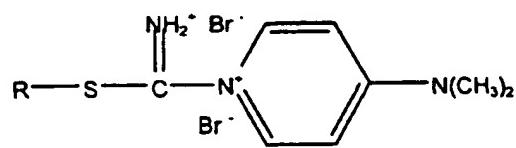
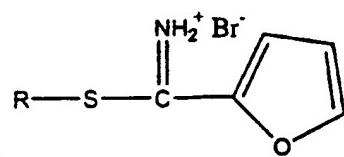
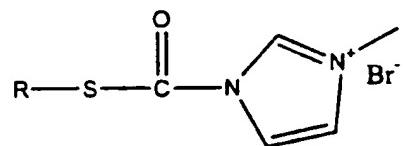
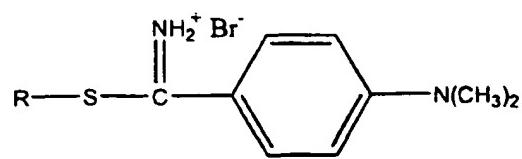


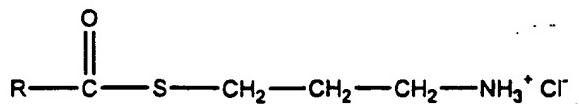
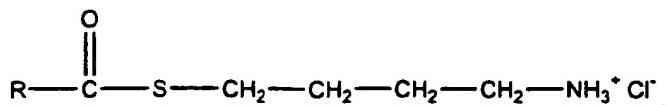
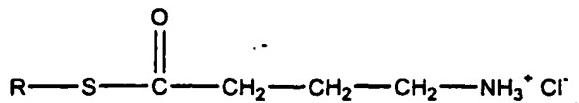
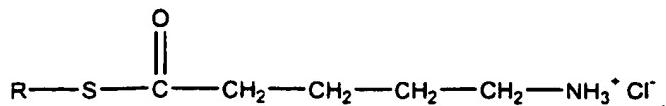


or related derivatives.

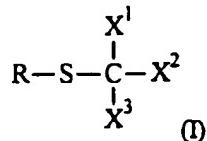
Preferred protected thiol compounds of the sp^3 carbon thiol protective type include the following non-limiting examples:



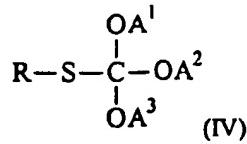
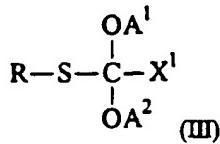
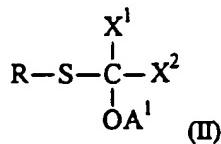




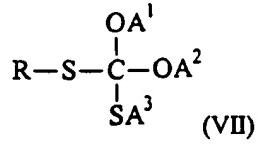
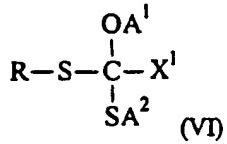
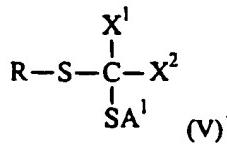
sp³ Carbon Protecting Groups The protecting groups of the present invention may comprise an sp³ carbon moiety wherein the divalent sulfur atom is bonded on one side to the cosmetic active and on the other side to a sp³ carbon atom. Protecting groups of the sp³ carbon type that are suitable for the present invention include those of the thioether type,



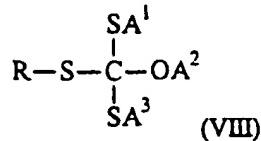
including the monothioacetal (II. X¹ = H), monothioketal (II. X¹, X² = H), monothioortho ester (III) and monothioortho-carbonate (IV) type,



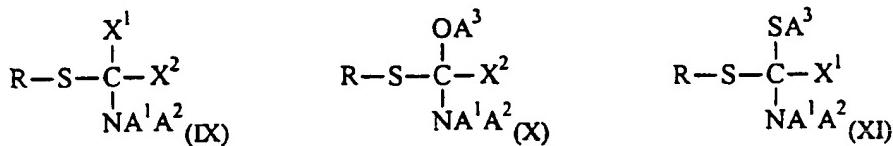
the dithioacetal (V. X¹ = H), dithioketal (V. X¹, X² = H), dithioorthoester (VI) and dithioortho-carbonate (VII) type,



the trithioorthoester type (VIII),



the thiohemiaminal (IX), monothioorthoamide (X) and dithioorthoamide (XI) type,



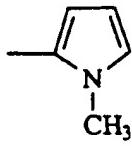
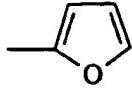
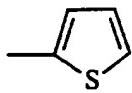
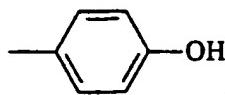
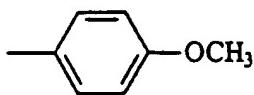
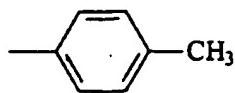
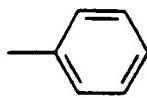
and related classes wherein X^1 , X^2 , X^3 represent, independently from one another, electron withdrawing, electron neutral, or electron donating groups with Hammett sigma para values between -1.0 and +1.5 which can be non-ionic, zwitterionic, cationic or anionic comprising for example C-linked groups of the classes defined below as A^1 , A^2 , A^3 ; S-linked groups including SA^1 , SCN , SO_2A^1 , SO_3A^1 , SSA^1 , SOA^1 , SONA^1A^2 , $\text{SO}_2\text{NA}^1\text{A}^2$, SNA^1A^2 , $\text{S}(\text{NA}^1)\text{A}^2$, $\text{S}(\text{O})(\text{NA}^1)\text{A}^2$, $\text{SA}^1(\text{NA}^3)$; O-linked groups including OA^1 , OOA^1 , OCN , ONA^1A^2 ; N-linked groups including NA^1A^2 , $\text{NA}^1\text{A}^2\text{A}^3$, NC , NA^1OA^2 , NA^1SA^2 , NCO , NCS , NO_2 , $\text{N}=\text{NA}^1$, $\text{N}=\text{NOA}^1$, NA^1CN , $\text{N}=\text{C}=\text{NA}^1$, $\text{NA}^1\text{NA}^2\text{A}^3$, $\text{NA}^1\text{NA}^2\text{NA}^3\text{A}^4$, $\text{NA}^1\text{N}=\text{NA}^2$; other miscellaneous groups including COHal , CON_3 , CONA^1_2 , $\text{CONA}^1\text{COA}^2$, $\text{C}(\text{=NA}^1)\text{NA}^1\text{A}^2$, CHO , CHS , CN , NC , Hal , and derived groups that connect one or more of X^1 , X^2 , X^3 , X^4 , X^5 via a ring system. Hal is F, Cl, Br, or I.

For the thioether class, as defined above, at least one of X^1 , X^2 , or X^3 groups is electron donating such that the sum of the Hammett sigma para values for X^1 , X^2 , X^3 is negative for this class.

A^1 , A^2 , A^3 , A^4 represent, independently from one another, a monovalent group which can be the cosmetic active group, R, or H or any of the following: a straight, branched or mono- or poly- cyclic aliphatic, mono or polyunsaturated alkyl, aryl, heteroalkyl, heteroaliphatic or heteroolefinic system including 1 to 30 carbon atoms together with 0-15 heteroatoms, especially O, N, S, P, Si, and can incorporate one or more substituents including, but not limited to, poly or per fluoro substitution.

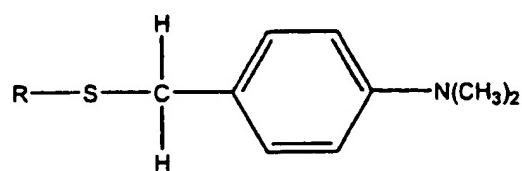
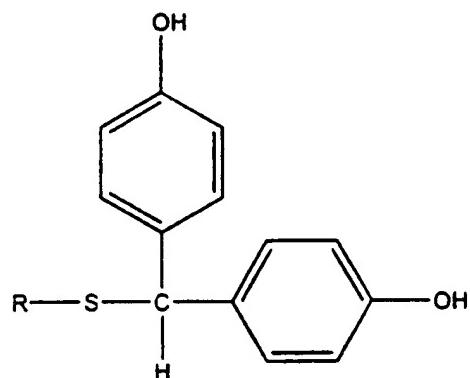
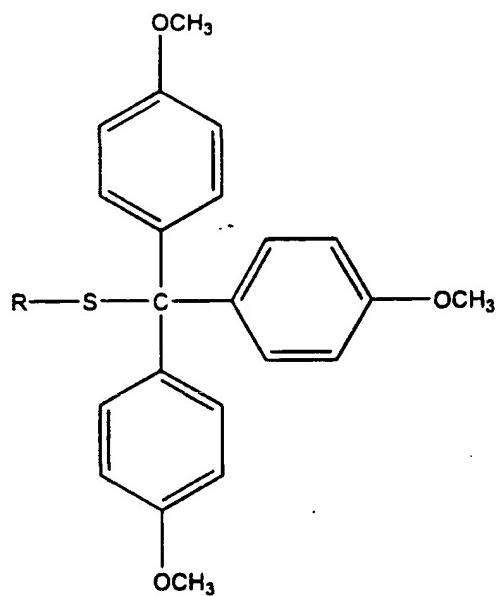
H is hydrogen, O is oxygen, N is nitrogen, C is carbon, S is sulfur, Cl is chlorine, Br is bromine, I is iodine, F is fluorine, R is any cosmetic active, functional group or benefit agent as described herein below.

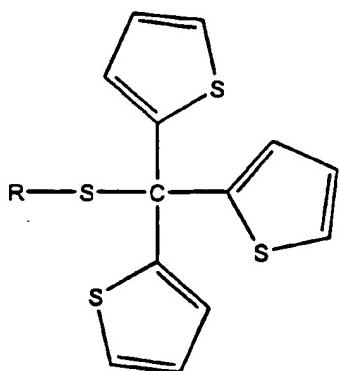
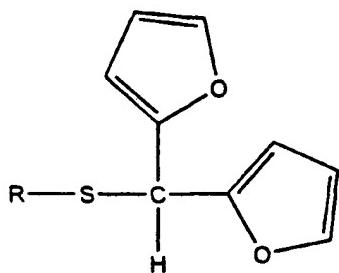
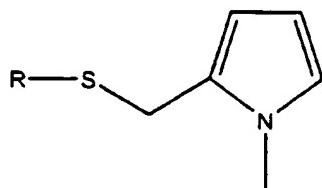
Preferred electron donating substituents for X^1 , X^2 , X^3 are aromatic or heteroaromatic derivatives which include the following non-limiting examples:



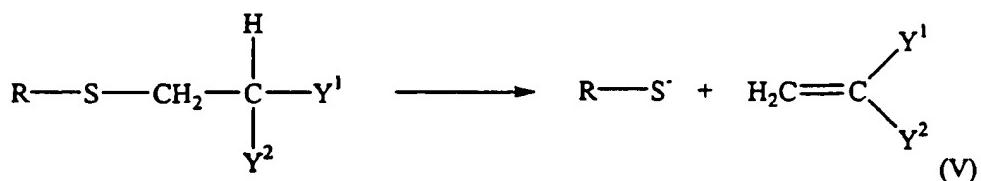
plus other related derivatives.

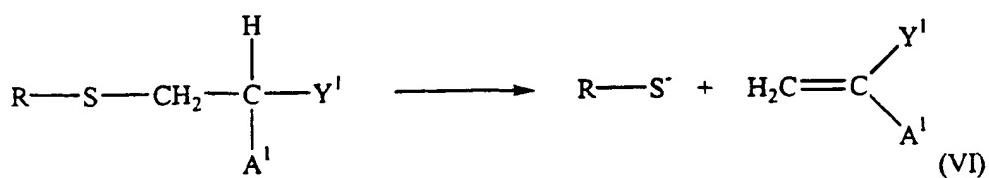
Preferred protected thiol compounds chosen from classes I through XI above include the following non-limiting examples:





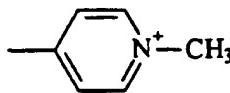
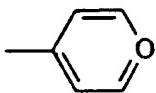
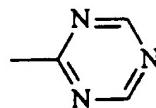
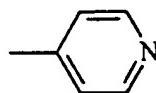
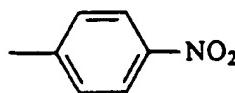
The present invention also includes organosulfur molecular "hooks" wherein the potential cosmetic thiol is bonded directly to an sp^3 carbon atom that is part of a group capable of undergoing heterolytic β -elimination, the reversal of Michael Addition reactions, to liberate a thiol. Suitable sp^3 carbon groups capable of undergoing heterolytic β -elimination are represented in the compounds,





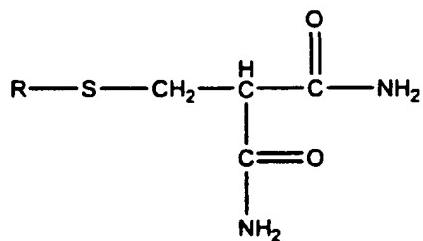
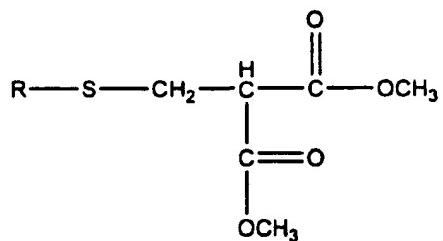
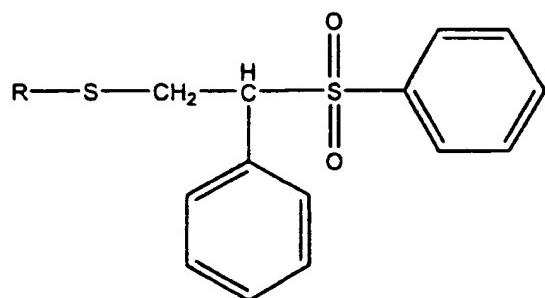
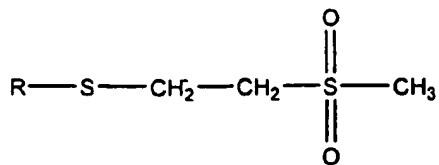
wherein Y^1 and Y^2 represent, independently from one another, electron withdrawing substituents with a combined Hammett sigma para value more positive than 0.10. Such electron withdrawing substituents include the following non-limiting examples: NO_2 , CN , COOA^1 , CONA^1A^2 , C(O)A^1 , SO_2A^1 , SO_2OA^1 , NO , COHal , CON_2 , CONA^1A^2 , $\text{CONA}^1\text{COA}^2$, $\text{C}(\text{=NA}^1)\text{NA}^2\text{A}^3$, C(S)A^1 , NC , SCN , SO_2A^1 , SOA^1 , SONA^1A^2 , $\text{SO}_2\text{NA}^1\text{A}^2$, SNA^1A^2 , $\text{S}(\text{NA}^1)\text{A}^2$, $\text{S(O)(NA}^1)\text{A}^2$, $\text{NA}^1\text{A}^2\text{A}^{3+}$, SA^1A^{2-} and aromatic and heteroaromatic derivatives.

Some non-limiting examples of aromatic and heteroaromatic electron withdrawing groups for Y^1 and Y^2 include the following:

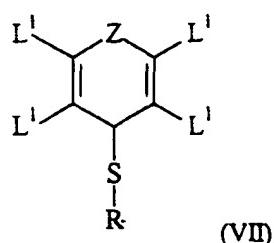


plus other related derivatives.

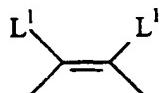
Preferred hook compounds that are capable of undergoing heterolytic β -elimination, the reversal of Michael Addition reactions, to liberate a thiol include the following non-limiting examples:



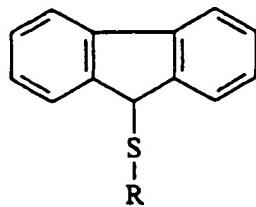
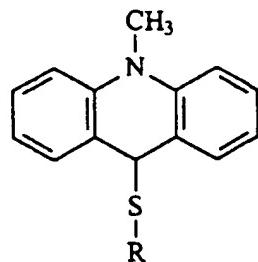
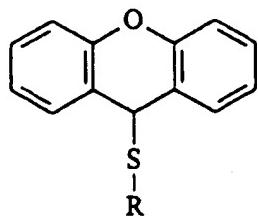
The present invention also includes cases wherein the cosmetic thiol is protected by being bonded directly to an sp^3 carbon atom that is incorporated within a ring structure. Suitable sp^3 carbon ring systems are represented by the following.

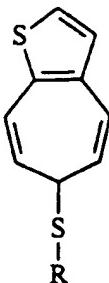
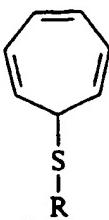


wherein Z is O, NAr, S, $(CH_2)_n$, or



L^1 is A^1 or part of a 5 to 7 membered fused ring system. The above ring system(s) can carry any substituents. Specific examples of sp^3 carbon ring compounds covered by the present invention include the following non-limiting examples:





and other related derivatives.

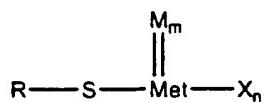
A^1 , A^2 , A^3 , represent, independently from one another, a monovalent group which can be the cosmetic active group, R, or H or any of the following: a straight, branched or mono- or polycyclic aliphatic, mono or polyunsaturated alkyl, aryl, heteroalkyl, heteroaliphatic or heteroolefinic system including 1 to 30 carbon atoms together with 0-15 heteroatoms, especially O, N, S, P, Si, and can incorporate one or more substituents including, but not limited to, poly or per fluoro substitution.

H is hydrogen, O is oxygen, N is nitrogen, C is carbon, S is sulfur, Cl is chlorine, Br is bromine, I is iodine, F is fluorine, R is any cosmetically active functional group or benefit agent as described herein below.

Metal Based Protecting Groups - The molecular "hooks" of the present invention comprise a divalent sulfur atom that is bonded on one side to the cosmetic active and on the other side to an alkaline earth metal, transition metal or a representative metal in groups II A, III A, IV A, V A, VI A, VII A, VIII, IB, IIB, IIIB, IVB, VB, VIB, and VIIIB of the periodic table of the elements including Mg, Ca, Sr, Ba, La, Ti, Zr, V, Cr, Mo, W, Mn, Fe, Co, Rh, Ni, Pd, Pt, Cu, Ag, Au, Zn, In, Sn, and Bi. Protected thiol compounds comprising such heavy metal mercaptides are represented by the following:



or



wherein Met is an alkaline earth metal, transition metal or a representative metal in groups IIA, IIIA, IVA, VA, VIA, VIIA, VIII, IB, IIB, IIIB, IVB, VB, VIB, and VIIIB of the periodic table of the elements including Mg, Ca, Sr, Ba, La, Ti, Zr, V, Cr, Mo, W, Mn, Fe, Co, Rh, Ni, Pd, Pt, Cu, Ag, Au, Zn, In, Sn, and Bi. Also, wherein n and m are zero or integers such that 1 + 2m + n equals the valency of Met.

X represents independent electron withdrawing, electron neutral or electron donating groups with Hammett sigma para values between -1.0 and +1.5 which can be non-ionic, zwitterionic, cationic or anionic comprising for example C-linked groups of the classes defined below as A¹, A², A³; S-linked groups including SA¹, SCN, SO₂A¹, SO₃A¹, SSA¹, SOA¹, SONA¹A², SO₂NA¹A², SNA¹A², S(NA¹)A², S(O)(NA¹)A², SA¹(NA²); O-linked groups including OA¹, OOA¹, OCN, ONA¹A²; N-linked groups including NA¹A², NA¹A²A³⁺, NC, NA¹OA², NA¹SA², NCO, NCS, NO₂, N=NA¹, N=NOA¹, NA¹CN, N=C=NA¹, NA¹NA²A³, NA¹NA²NA³A⁴, NA¹N=NA²; other miscellaneous groups including COHal, CON₃, CONA¹₂, CONA¹COA², C(=NA¹)NA¹A², CHO, CHS, CN, NC, Hal, and derived groups that connect one or more of X¹, X², X³, X⁴, X⁵ via a ring system. Hal is F, Cl, Br, or I.

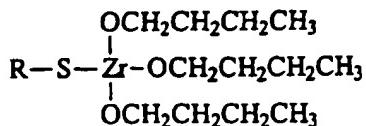
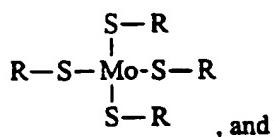
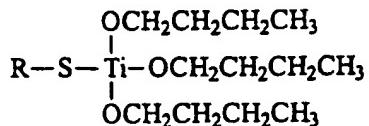
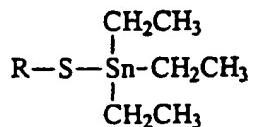
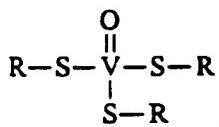
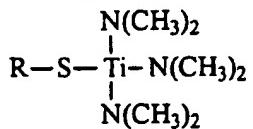
A¹, A², A³, A⁴ represent, independently from one another, a monovalent group which can be the cosmetic active group, R, or H or any of the following: a straight, branched or mono- or poly- cyclic aliphatic, mono or polyunsaturated alkyl, aryl, heteroalkyl, heteroaliphatic or heterolefinic system including 1 to 30 carbon atoms together with 0-15 heteroatoms, especially O, N, S, P, Si, and can incorporate one or more substituents including, but not limited to, poly or per fluoro substitution.

M is a divalent group such as O, S, NA¹ or CA¹A².

H is hydrogen, O is oxygen, N is nitrogen, C is carbon, S is sulfur, Cl is chlorine, Br is bromine, I is iodine, F is fluorine, B is boron, Al is aluminum, Si is silicon, N is nitrogen, Mg is magnesium, Ca is calcium, Sr is strontium, Ba is barium, La is lanthanum, Ti is titanium, Zr is zirconium, V is vanadium, Cr is chromium, Mo is molybdenum, W is tungsten, Mn is manganese, Fe is iron, Co is cobalt, Rh is rhodium, Ni is nickel, Pd is palladium, Pt is platinum, Cu is copper, Ag is silver, Au is gold, Zn is zinc, In is indium, Sn is tin, Bi is bismuth, and R is any cosmetic active, functional group or benefit agent as described herein below.

Also wherein at least one substituent, X, or the cosmetic active, R, contains salt forming or water solubilizing groups including, but not limited to, COO⁻, SO₃⁻, NH₃⁺, OH, COOA¹, (CH₂CH₂O)_nA¹, CONA¹A², OSO₃⁻, OPO₃H⁺, NA¹A²A³⁻, and the like.

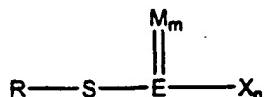
Preferred metal based protecting groups of the present invention include, but are not limited to, the following examples.



Non-metal and metalloid based Protecting Groups - The molecular "hooks" of the present invention comprise a divalent sulfur atom that is bonded on one side to the cosmetic active and on the other side to a representative non-metal or metalloid atom including boron, aluminum, silicon, germanium, nitrogen, phosphorus, sulfur, selenium, antimony, and tellurium. Molecular "hooks" whereby a divalent sulfur atom of a potential cosmetic thiol is bonded directly to these representative non-metals and metalloids are represented by the following:



or



wherein E is a representative non-metal or metalloid element including B, Al, Si, Ge, N, P, S, Se, Sb, and Te. Also, wherein n and m are zero or integers such that $1 + 2m + n$ equals the valency of E.

X represents independent electron withdrawing, electron neutral or electron donating groups with Hammett sigma para values between -1.0 and +1.5 which can be non-ionic, zwitterionic, cationic or anionic comprising for example C-linked groups of the classes defined below as A¹, A², A³; S-linked groups including SA¹, SCN, SO₂A¹, SO₃A¹, SSA¹, SOA¹, SONA¹A², SO₂NA¹A², SNA¹A², S(NA¹)A², S(O)(NA¹)A², SA¹(NA²); O-linked groups including OA¹, OOA¹, OCN, ONA¹A²; N-linked groups including NA¹A², NA¹A²A³⁺, NC, NA¹OA², NA¹SA², NCO, NCS, NO₂, N=NA¹, N=NOA¹, NA¹CN, N=C=NA¹, NA¹NA²A³, NA¹NA²NA³A⁴, NA¹N=NA²; other miscellaneous groups including COHal, CON₃, CONA¹₂, CONA¹COA², C(=NA¹)NA¹A², CHO, CHS, CN, NC, Hal, and derived groups that connect one or more of X¹, X², X³, X⁴, X⁵ via a ring system. Hal is F, Cl, Br, or I.

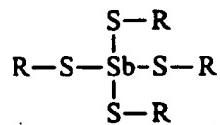
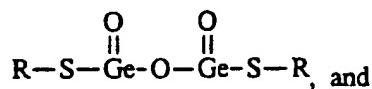
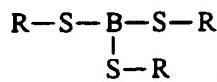
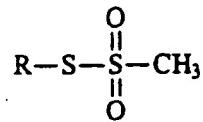
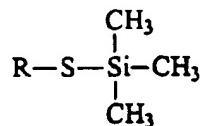
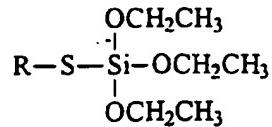
M is a divalent group such as O, S, NA¹ or CA¹A².

A¹, A², A³, A⁴ represent, independently from one another, a monovalent group which can be the cosmetic active group, R, or H or any of the following: a straight, branched or mono- or poly- cyclic aliphatic, mono or polyunsaturated alkyl, aryl, heteroalkyl, heteroaliphatic or heterolefinic system including 1 to 30 carbon atoms together with 0-15 heteroatoms, especially O, N, S, P, Si, and can incorporate one or more substituents including, but not limited to, poly or per fluoro substitution.

H is hydrogen, O is oxygen, N is nitrogen, C is carbon, S is sulfur, Cl is chlorine, Br is bromine, I is iodine, F is fluorine, B is boron, Al is aluminum, Si is silicon, Ge is germanium, N

is nitrogen, P is phosphorus, Te is tellurium, and R is any cosmetic active, functional group or benefit agent as described herein below.

Preferred thiol protective systems utilizing non-metals and metalloids of the present invention include, but are not limited to, the following examples,



Energy-sensitive Protecting Groups - The topical compositions of the present invention may also comprise a protected thiol compound wherein the protecting group is energy-sensitive. Protected thiol compounds comprising energy-sensitive protecting groups are chemically stable in solution. Such potential thiols are protected until a suitable source of energy is applied to the composition. Upon application of a suitable energy source, the energy-sensitive protecting groups become

labile, thereby releasing the reactive thiol. Typically, the energy source will be light. Once the thiols are released, they are capable of reacting with amino acid residues present in keratinaceous substrates to enable durable cosmetic benefits.

As mentioned above, the protected thiols are activated by applying a suitable energy source to the composition, i.e., irradiation, which converts the photoactivatable protected thiol compounds to fully reactive thiol compounds. The byproducts of the energy activation of the protecting group will usually be removed from the substrate by washing.

Many different energy-sensitive groups can be employed for protecting thiols used in the topical compositions of the present invention. Typically, the thiol groups are protected with a photoactivatable protecting group that is capable of liberating or releasing the reactive thiol by irradiation. The properties and uses of photoreactive compounds have been reviewed. See McCray et al, 1989, *Ann. Rev. Biophys. Chem.* 18:239-270, which is incorporated herein by reference. The photosensitive groups will preferably be activatable by low energy ultraviolet or visible light. Many, although not all, of the energy-sensitive protecting groups are aromatic compounds. Suitable photoremoveable protecting groups are also described in, for example, Patchornik, 1970, *J. Am. Chem. Soc.* 92:6333, and Amit et al, 1974, *J. Org. Chem.* 39:192, which are incorporated herein by reference. More preferably, the energy-sensitive protecting group will be a nitrobenzylic compound, such as o-nitrobenzyl or benzylsulfonyl groups. Suitable examples include 6-nitroveratryloxycarbonyl (NVOC); 6-nitropiperonyloxycarbonyl (NPOC); alpha, alpha-dimethylmethoxybenzyloxycarbonyl (DDZ), methyl 6-nitroveratryloxycarbonyl (MeNVOC), methyl-6-nitropiperonyloxycarbonyl (MeNPOC), or 1-pyrenylmethyl. The energy-sensitive protecting group may also be of the silyl type as described in Pirlung and Lee, 1993, *J. Org. Chem.* 58:6961-6963 and Pirlung and U.S. Patent Number 5,486,633, issued to Lee, both incorporated by reference herein. Suitable examples include (hydroxystyryl)dimethylsilyl (HSDMS) and (hydroxystyryl)diisopropylsilyl (HSDIS).

Clearly, many energy-sensitive protecting groups are suitable for use in the present method. Some examples of acceptable energy-sensitive protecting groups are presented in Table 1, below, together with their corresponding wavelengths for deprotection.

TABLE 1

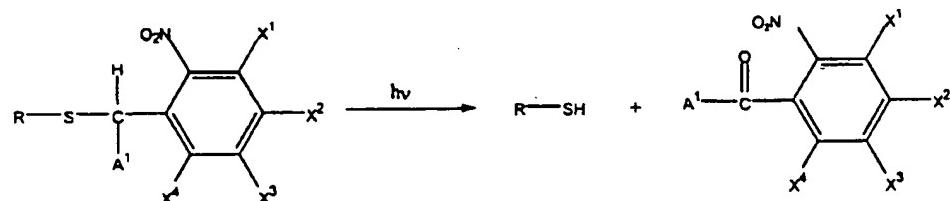
	<u>Energy-sensitive Protecting Groups</u>	Deprotection	Wavelength
Group			
6-nitroveratryloxycarbonyl (NVOC)		UV (300-350 nm)	

dimethyldimethoxybenzyloxycarbonyl (DDZ)	UV (280-300 nm)
nitrobenzyloxycarbonyl (NBOC)	UV (300-350 nm)
5-bromo-7-nitroindolinyl (BNI)	UV (420 nm)
O-hydroxy-alpha-methyl-cinnamoyl (HMC)	UV (300-350 nm)
2-oxymethylene anthraquinone (OMA)	UV (350 nm)

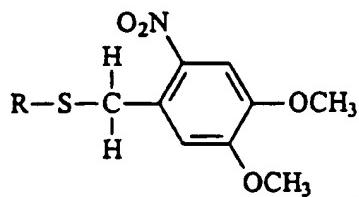
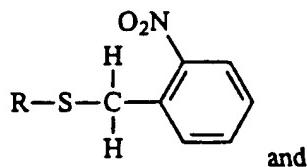
The composition containing the cosmetic active protected with the energy-sensitive group may be activated with energy both prior or during usage. For instance, the energy source may be applied to the composition for a sufficient time period to activate the energy sensitive protecting group either before, during or after the composition is applied to the substrate. The energy source may include various types of electromagnetic radiation including ultraviolet, visible, near infrared, infrared, far infrared or microwave. In a preferred embodiment, the radiation is UV, near IR or visible light.

Examples of suitable protecting groups that are capable of undergoing photochemical or thermal thiol deprotection include, but are not limited to, the following:

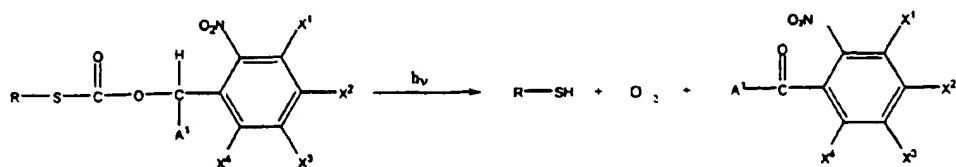
I. 2-Nitrobenzyl derivatives



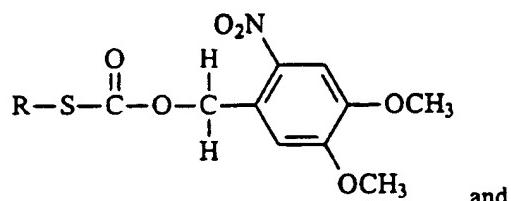
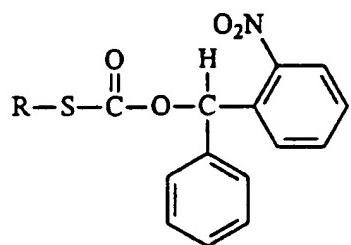
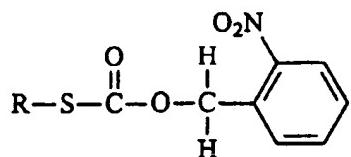
Examples:



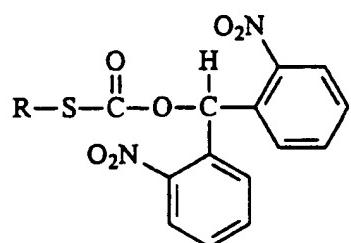
II. 2-Nitrobenzyloxycarbonyl Derivatives



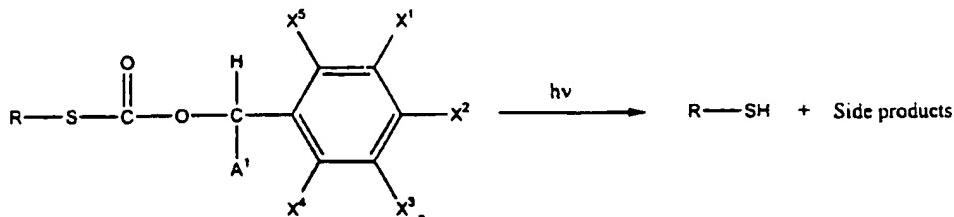
Examples:



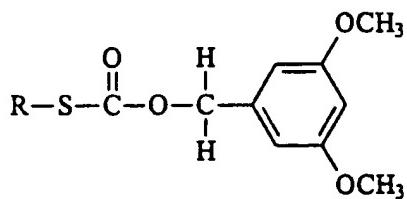
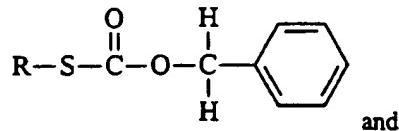
, and



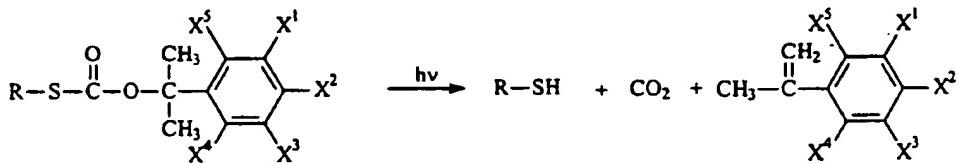
III. Benzyloxycarbonyl Derivatives



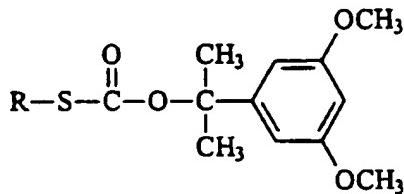
Examples:



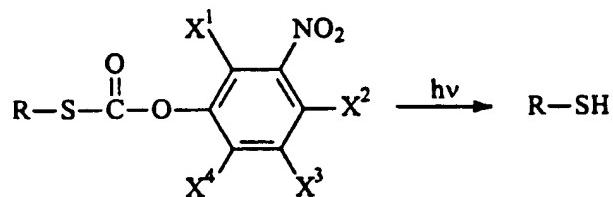
IV. α,α -Dimethylbenzyloxycarbonyl Derivatives



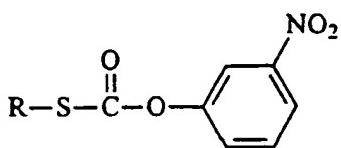
Example:



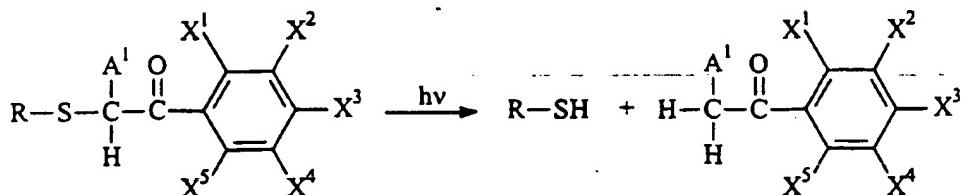
V. 3-Nitrophenyloxycarbonyl Derivatives



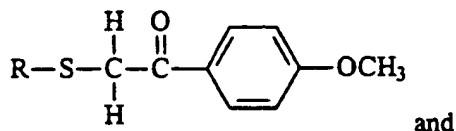
Example:



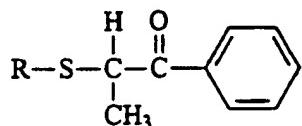
VI. Phenacyl Derivatives



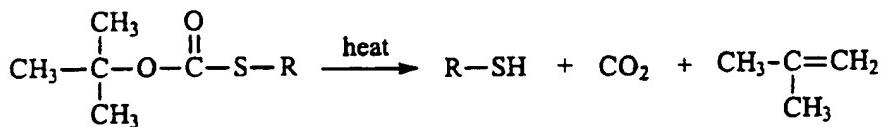
Examples:



and



VII. tert-Butyloxycarbonyl Derivatives



X^1 , X^2 , X^3 , X^4 , and X^5 can be selected from electron withdrawing, electron neutral, or electron donating groups with Hammett sigma para values between -1.0 and +1.5 which can be non-ionic, zwitterionic, cationic or anionic comprising for example C-linked groups of the classes defined below as A^1 , A^2 , A^3 ; S-linked groups including SA^1 , SCN , SO_2A^1 , SO_3A^1 , SSA^1 , SOA^1 , $SONA^1A^2$, $SO_2NA^1A^2$, SNA^1A^2 , $S(NA^1)A^2$, $S(O)(NA^1)A^2$, $SA^1(NA^2)$; O-linked groups including OA^1 , OOA^1 , OCN , ONA^1A^2 ; N-linked groups including NA^1A^2 , $NA^1A^2A^3$, NC , NA^1OA^2 , NA^1SA^2 , NCO , NCS , NO_2 , $N=NA^1$, $N=NOA^1$, NA^1CN , $N=C=NA^1$, $NA^1NA^2A^3$, $NA^1NA^2NA^3A^4$, $NA^1N=NA^2$; other miscellaneous groups including $COHal$, CON_3 , $CONA^1_2$, $CONA^1COA^2$, $C(=NA^1)NA^1A^2$, CHO , CHS , CN , NC , Hal , and derived groups that connect one or more of X^1 , X^2 , X^3 , X^4 , X^5 via a ring system;

A^1 , A^2 represent, independently from one another, a monovalent group which can be the cosmetic active group, R, or H or any of the following: a straight, branched or mono- or poly-

cyclic aliphatic, mono or polyunsaturated alkyl, aryl, heteroalkyl, heteroaliphatic or heteroolefinic system including 1 to 30 carbon atoms together with 0-15 heteroatoms, especially O, N, S, P, Si, and can incorporate one or more substituents including, but not limited to, poly or per fluoro substitution.

Mono or Multivalent Cosmetically Active Functional Group

The mono or multivalent cosmetically active functional, R, suitable for inclusion in the present invention may be any compound that imparts one or more visual, tactile or other cosmetic beneficial effects on proteinaceous materials such as keratin, i.e., hair, animal fur or wool. Any cosmetic compound may be included as a functional group in the compositions of the present invention as long as the compound can be modified to contain at least one divalent sulfur atom linked to a suitable protecting group as described herein.

Suitable functional groups that can be protected as thiol derivatives include but are not limited to antimicrobial compounds, UV-absorbing compounds, skin conditioning agents, hair conditioning agents, hair repair agents, hair styling agents, hair dyes, scalp treatment agents, anti-inflammatory compounds, antioxidants, dyes and coloring agents, perfumes, oral care actives, skin moisturizers, pharmaceutical agents, antidandruff agents, insect repellents, moisturizers, humectants, pearlescent and/or opacifying materials, fabric care actives, pet grooming actives, fabric anti-wrinkling agents, shrink-resistant actives, laundry care actives, hard surfaces actives, textile actives, textile dyes, water-proofing agents, cationic polymers, cationic surface modifiers, hydrophobic surface modifiers, anionic surface modifiers, absorbents, antifungal agents, insecticidal agents, textile color guards, nail actives such as enamel and polish, eyelash actives and mascara, antiperspirant and deodorant actives, anti-acne actives, odor control actives, fluorescent actives, bleaching agents, enzymes, antibodies, dispersing aids, emollients, stabilizers, anti-static agents, anti-seborrhea agents, optical brighteners, fluorescent dyes, softeners, cross-linking agents, photobleaches, bactericides, and mixtures thereof.

Examples of suitable antimicrobials which can be protected as thiol derivatives include but are not limited to derivatives of phenol, cresol, hydroxybenzoates, Triclosan®, Tricarban®, chlorhexidine, metal salts (e.g. zinc citrate, sodium zinc citrate, zinc pyridinethione, and stannous pyrophosphate) sanguinarine extract, metronidazole, quaternary ammonium compounds (chlorhexidine digluconate, hexetidine, octenidine, alexidine), halogenated bisphenolic compounds such as 2,2'-methylenebis-(4-chloro-6-bromophenol), and salicylanilide.

Examples of suitable UV-absorbing materials which can be protected as thiol derivatives include but are not limited to derivatives of benzoates, oxybenzones, cinnamic acid, PARASOL MCX esters, benzotriazoles, and benzophenones.

Examples of suitable skin conditioners or moisturizers which can be protected as thiol derivatives, include but are not limited to derivatives of alpha-hydroxy acids, polyols, hyaluronic acid, petrolatum, vegetable oils, esters of fatty acids, and mineral oil. Such skin conditioners or moisturizers are bound to the velus hairs present on the skin, and not the skin directly, to achieve the long lasting skin benefits.

Examples of suitable anti-inflammatory agents which can be protected as thiol derivatives include but are not limited to corticosteroids or salicylates.

Examples of suitable antioxidants which can be protected as thiol derivatives include but are not limited to ascorbates and gallates.

Examples of suitable hair conditioners which can be protected as thiol derivatives include but are not limited to intact or modified proteins, such as hydrolyzed keratin, collagen, elastin, hemoglobin, silk, rice, soy, wheat protein, corn, fibronectin, reticulum, serum protein, wheat gluten, peptides and peptide derivatives; amino acids; hydroxylated fats; glycinate; silicone polymers, such as siloxane gums and resins, volatile or non-volatile silicone oils, amino- (or other) functional silicones, and other silicone-containing polymers; hydrocarbon based conditioners including C₈-C₃₀ alkyl, alkenyl, modified alkyl or modified alkenyl, branched alkyl and branched alkenyl groups as well as long chain alkyl groups that are ethoxylated or substituted with various non-ionic, cationic or anionic functional groups including quats, amines, amides, esters, hydroxyls, carboxylates, and the like; polysaccharides or monosaccharides, and alkyl cationic conditioning polymers such as cationic derivatives of guar gum and cellulose ether derivatives; poly(ethyleneoxides) and alkyl capped poly(ethyleneoxides) of molecular weights ranging from 100 to 10,000,000; and herb or other plant extracts, essential oils etc.

Examples of suitable hair styling agents which can be protected as thiol derivatives include but are not limited to film-forming polymers such as polyvinylpyrrolidone/vinyl acetate copolymer; styling copolymers comprising silicone macromonomers, U.S. Patent Nos. 5,618,524 and 5,658,557, cationic polymers, such as those disclosed in GB-A-2161172 (Beecham), GB-A-2122214 (Unilever) and GB-A-2050166 (L'Oreal); and hydrocarbon polymers, such as polyisobutylene; perfluoro-aliphatic and perfluoro-aromatic compounds.

Examples of suitable dyes and coloring agents which can be protected as thiol derivatives include but are not limited to phenol, naphthols, acid dyes, azo derivatives; vegetable dyes, metallized dyes, nitrobenzene dyes, quinone-imine dyes, basic dyes, quaternary dyes, and oxidation dyes.

Examples of suitable fragrances that can be protected as thiol derivatives include but are not limited to phenols such as menthol salicylate, thymol, and vanillin.

Examples of suitable cationic polymers that can be protected as thiol derivatives include but are not limited to derivatives of quaternary ammonium salts of hydroxyethylcellulose, cationic copolymers of acrylic acid and acrylamide, cationic guar polymers, copolymers of vinylimidazolium methochloride and vinylpyrrolidone, polyethylenimines, and other cationic polymers and resins known to those skilled in the art.

Examples of suitable oral care active agents that can be protected as thiol derivatives include but are not limited to anti-caries agents such as amine fluorides, monosodium fluorophosphate, casein; plaque buffers such as urea, calcium lactate, calcium glycerophosphate; anti-plaque agents; agents for alleviating sensitive teeth, e.g. potassium and strontium salts, particularly those of carboxylic acids; materials that form films and block pores; oral pharmaceutical actives, (e.g. ibuprofen, flurbiprofen, aspirin and indomethacin); biomolecules such as peptides, antibodies and enzymes; anti-tartar agents; agents for treating bad breath such as zinc salts; and anti-calculus agents (e.g. alkali metal pyrophosphates, hypophosphite-containing polymers, organic phosphonates, and phosphocitrates).

Examples of suitable pharmaceutical agents that can be protected as thiol derivatives include but are not limited to medicinal agents, metabolic agents and other therapeutic agents of benefit in treating the human body.

Examples of antidandruff agents that can be protected as thiol derivatives include but are not limited to zinc pyridinethione, Octopirox®, climbazole and itroconazole.

An example of odor control actives that can be protected as thiol derivatives include the class of cyclodextrins. In addition to trapping odors on the substrate, the cyclodextrins can plausibly be utilized to deliver cosmetic actives molecules to the substrate such as perfumes that can be liberated slowly.

Other non-limiting classes of beneficial cosmetic actives include sealants, binders, resins, adhesives, waxes, drying oils, varnishes, and latex finishes which comprise urethanes, polysulfides, acrylics, butyl polymers, maleated oils, cellulosics, starches etc.

The mono or multivalent cosmetically active functional preferably used in the present compositions is dependent on the product form desired. Hair care compositions preferably use hair conditioners, hair styling agents, dyes and coloring agents, sunscreens, fragrances, antidandruff agents, or mixtures thereof as the functional group. Preferable functional groups in textile care compositions include dyes and coloring agents, odor control actives, sealants, fragrances, and mixtures thereof. Cosmetic compositions preferably comprise dyes and coloring agents, sealants, resins, varnishes, latex finishes, and mixtures thereof. Oral care compositions preferably comprise anti-caries agents, plaque buffers, anti-plaque agents, agents for alleviating

sensitive teeth, materials that form films and block pores, oral pharmaceutical actives, biomolecules, anti-tartar agents, agents for treating bad breath, anti-calculus agents, and mixtures thereof as functional groups. Pharmaceutical composition preferably select mono or multivalent cosmetically active functional groups from the group consisting of medicinal agents, metabolic agents, therapeutic agents, anti-inflammatory compounds, and mixtures thereof. Animal care composition preferably comprise antimicrobial agents, insect repellents, grooming actives, and mixtures thereof as functional groups.

OPTIONAL ACTIVATING MECHANISMS

As explained above, the molecular 'hooks' of the present invention may be activated via a number of mechanisms either before, during or after the application of the topical compositions containing the protected thiol to the substrate. Various embodiments of the present invention are systems which comprise both the topical composition herein with an activating mechanism.

Such activation could be achieved via hydrolysis by the use of a mechanism to manipulate the pH of the environment surrounding the compound. Such pH adjusting mechanisms may include acidic or alkaline solutions. Whether acidic or alkaline mechanisms are required is dependent on the protecting group used. Hydrolysis may also be achieved via simply mixing the compound, delivered in its purified form or from a non-aqueous solution, with water.

Furthermore, the molecular 'hook' could be activated by coming in contact with a suitable nucleophile. Such nucleophiles include, but are not limited to, nitrogen-containing functional groups, for example amines, oxygen-containing functional groups, for example hydroxyl groups, phosphorus-containing functional groups, for example phosphines, and sulfur-containing functional groups, for example thiol groups and sulfites. For instance, the solution containing the 'hook' compound could be inter-mixed with a separate solution containing a nucleophile including reducing agents such as ammonium thioglycolate or sodium bisulfite, either before, during or after application of the compound to the substrate.

Conversely, the 'hook' compound could be activated by nucleophilic groups present in the substrate itself as in the case of hair that has been reduced or cold waved, i.e. hair that has been treated with a reducing agent either prior to or simultaneous to the application of the 'hook' compound. The resulting activated thiol 'hook' could then react directly as a nucleophile with keratinaceous disulfides or oxidatively with the nucleophilic groups present in the substrate, e.g. with free thiol groups that were formed during cold waving or reduction. Of course, the latter process could be accelerated or enhanced via the addition of oxidation reagents, i.e. peroxide as in the neutralization step of cold waving of hair.

The activation could also be accented via heat or a suitable energy source. For instance, the energy source could be applied to the composition for a sufficient time period to activate the protecting group either before, during or after the composition is applied to the substrate. The energy source may include various types of electromagnetic radiation including ultraviolet, visible, near infrared, infrared, far infrared or microwave radiation.

Other various adjuncts that could possibly influence the activation and/or the performance of the "hook" compounds of the present invention include, but are not limited to, (i) Lewis acids such as zinc acetate, tin chloride, zinc chloride, zinc stearate, titanium ethoxide, and aluminum tosylate, metal salts such as zinc sulfate, and magnesium sulfate, (ii) chelators such as tetrasodium EDTA, disodium EDTA, (iii) ionic species capable of ion-pairing including anions, cations, quats, amphoteric zwitterions etc, (iv) dispersing aids such as anionic surfactants, non-ionic surfactants, anionic surfactants, amphoteric surfactants, and zwitterionic surfactants, (v) keratin swelling aids such as ammonia, amines, urea, phosphoric acid, acetic acid and other swelling aids known to those skilled in the art, and (vi) solvent systems wherein the individual solvent molecules are nucleophiles themselves as defined above.

Another embodiment of the present invention comprises a kit comprising the system comprising the topical compositions of the present invention and either a pH manipulating mechanism or a nucleophile mechanism, and a package comprising a first and second chamber; wherein the topical composition is packaged in and delivered out of one chamber and the activation mechanism is packaged in and delivered out of the second chamber.

OTHER OPTIONAL INGREDIENTS

The topical composition according to the invention can also typically include an acceptable vehicle to act as a dilutant, dispersant, or carrier for the protected thiol compounds in the composition, so as to facilitate the distribution of the protected thiol compounds when the composition is applied to the keratinaceous substrate, i.e., hair, nails, wool, skin etc.

Vehicles other than water can include liquid or solid emollients, solvents, humectants, thickeners and powders. Examples of each of these types of vehicle, which can be used singly or as a mixture of one or more vehicles, are as follows:

Emollients, such as stearyl alcohol, glyceryl monoricinoleate, glyceryl monostearate, mink oil, cetyl alcohol, isopropyl isostearate, stearic acid, isobutyl palmitate, isocetyl stearate, oleyl alcohol, isopropyl laurate, hexyl laurate, decyl oleate, octadecan-2-ol, isododecane, isocetyl alcohol, eicosanyl alcohol, behenyl alcohol, cetyl palmitate, silicone oils such as polydimethylsiloxane, cyclomethicone, di-n-butyl sebacate, isopropyl myristate, isopropyl palmitate, isopropyl stearate, butyl stearate, dimethyl malonate, polyethylene glycol, triethylene

glycol, lanolin, c coa butter, corn oil, cott n seed oil, tallow lard, olive oil, palm kernel oil, rapeseed oil, safflower seed oil, evening primrose oil, soybean oil, sunflower seed oil, avocado oil, olive oil, sesame seed oil, coconut oil, arachis oil, castor oil, acetylated lanolin alcohols, petroleum jelly, mineral oil, butyl myristate, isostearic acid, palmitic acid, isopropyl linoleate, lauryl lactate, myristyl lactate, decyl oleate, myristyl myristate;

Propellants, such as trichlorofluoromethane, dichlorodifluoromethane, dichlorotetrafluoroethane, monochlorodifluoromethane, trichlorotrifluoroethane, propane, butane, isobutane, dimethyl ether, carbon dioxide, nitrous oxide;

Solvents include, but are not limited to, ethyl alcohol, n-propanol, n-butanol, tert-butanol, ethylene glycol dimethyl ether, hexane, tetramethylurea, sulfolane, low molecular weight poly(ethylene oxide), glycerol, propylene glycol, 2-butoxyethanol, amyl alcohol, n-octanol, n-decanol, acetone, acetic acid, butyl acetate, methylene chloride, isopropanol, acetone, ethylene glycol monoethyl ether, diethylene glycol monobutyl ether, diethylene glycol monoethyl ether, dimethyl sulphoxide, dimethylformamide, tetrahydrofuran;

Powders, such as chalk, talc, fullers earth, kaolin, starch, gums, colloidal silica, sodium polyacrylate, tetraalkyl- and/or trialkyl-arylammonium smectites, chemically modified magnesium aluminum silicate, organically modified montmorillonite clay, aluminum silicate, fumed silica, carboxyvinyl polymer, sodium carboxymethylcellulose, ethylene glycol monostearate.

The cosmetically acceptable vehicle will usually form from 10 to 99.9%, preferably from 50 to 99% by weight of the composition and can, in the absence of other cosmetic adjuncts, form the balance of the composition.

The topical compositions according to the invention may be provided in any suitable physical form, for example as low to moderate viscosity liquids, lotions, milks, mousses, dispersions, sprays, gels, foams, aerosols, and creams. These compositions may be produced by procedures well known to the skilled artisan. The cosmetic compositions can be used in various manners as other known compositions in the art including but not limited to various rinse-off and leave-on applications such as hair shampoos, skin cleansers, skin lotions, hair conditioners, styling sprays, hair mousses, two-in-one shampoos, fabric softeners, lotions, nail polishes, hair serums, hair dyes, hair waving, etc. The contact time between the cosmetic composition of the present invention and the substrate varies between 10 seconds and about 1 hour, preferably between 20 seconds and 30 minutes, more preferably between 30 seconds and 15 minutes.

The cosmetic composition of the present invention can be formulated as a fluid, lotion, fluid cream or cream having a viscosity from 500 to 100,000 mPas or above. The composition

can be packaged in a suitable container to suit its viscosity and intended use by the consumer. For example, a lotion or fluid cream can be packaged in a bottle or a roll-ball applicator or a propellant-driven aerosol device or a container fitted with a pump suitable for hand or finger operation. When the composition is a cream, it can simply be stored in a non-deformable bottle or squeeze container, such as a tube or a lidded jar.

The topical product or composition of the present invention may include an activator as described above. In such a case, the inventive composition must be designed to prevent premature activation of the protected thiol compound prior to use. For instance, the protected thiol compound and the activator may be placed in separate chambers in a dual chamber package, or either of the 'hook' compound or the activator can be placed within shear sensitive (or other induced release) capsules which rupture prior or during use. Alternatively, the protected thiol compound and the activator can be placed in separate packages to enable pre-mixing or sequential application by the consumer. For examples of typical dual chamber packages see PCT Application WO 96/02230, by Unilever PLC, published February 1, 1996. (Herein incorporated by reference.)

Conversely, the cosmetic active of the present invention can be supplied in the purified form, i.e., as a powder, crystal, wax, gum or liquid. The purified cosmetic active could be intermixed with any of the above suitable carriers either prior to or simultaneous to the usage by the consumer. For instance, the purified cosmetic active could be placed within a compartment that is separated from the carrier by a barrier wall. Upon usage, the barrier wall could be broken, disrupted or even removed to enable the purified cosmetic active to come in contact with and inter-mix with the carrier.

The topical composition of the present invention comprises at least one of the above described protected thiol compounds, together with any additional ingredients which are normally to be found in cosmetic treatment compositions for use on hair, skin, or other substrates such as other fibers, textiles, fabrics, or the like. One or more of the protected thiol compounds may be used, the use of two or more being beneficial for example where a combination of cosmetic benefits is wanted, each derivable from a different cosmetic agent species.

While aqueous or aqueous/alcoholic solution based compositions, or possibly organic-based compositions, in which one or more protected thiol compounds are dissolved by solution are preferred, the compositions if desired or appropriate may comprise stable emulsions or dispersions of the one or more functionalized cosmetic agents which are designed to be water insoluble. In both of these cases, conventional means for achieving successful deposition and activation of the active(s) may be required. for instance, an emulsion or a dispersion could be

intermixed with a separate solvent solution via a dual phase package to enable solubilization and subsequent activation during usage.

The topical composition according to the invention may include optional benefit materials and cosmetic adjuncts, as long as the benefit materials or the adjuncts do not eliminate or substantially reduce the performance of the organosulfur functionalized cosmetic agent. The additional ingredients may include, for example dyes and coloring agents, fragrances; anionic, cationic, non-ionic, amphoteric or zwitterionic surfactants; buffers, masking fragrances, dispersing agents, stabilizers, cationic polymers, perfumes, non-ionic polymers, anionic polymers, complex coacervates, complex coacervate capsules, metal salts, Lewis acids, buffering agents, particulate thickeners, polymeric thickeners, wax thickeners, oils, emollients, humectants, moisturizers, dyes, dyes and coloring agents, enzymes, antibodies, preservatives, viscosity enhancers, gelling agents, chelators, silicones or other emulsifying agents, and other common adjuvants well known to those skilled in the art.

Nonlimiting examples of anionic lathering surfactants useful in the compositions of the present invention are disclosed in McCutcheon's, Detergents and Emulsifiers, North American edition (1990), published by The Manufacturing Confectioner Publishing Co.; McCutcheon's, Functional Materials, North American Edition (1992); and U.S. Patent No. 3,929,678, to Laughlin et al., issued December 30, 1975, all of which are incorporated by reference.

A wide variety of anionic surfactants are potentially useful herein. Nonlimiting examples of anionic lathering surfactants include those selected from the group consisting of alkyl and alkyl ether sulfates, sulfated monoglycerides, sulfonated olefins, alkylaryl sulfonates, primary or secondary alkanesulfonates, alkyl sulfosuccinates, acyltaurates, acylsethionates, alkyl glyceryl ether sulfonates, sulfonated methyl esters, sulfonated fatty acids, alkyl phosphates, acylglutamates, acylsarcosinates, alkyl sulfoacetates, acylated peptides, alkyl ether carboxylates, acylactylates, anionic fluorosurfactants, and mixtures thereof. Mixtures of anionic surfactants can be used effectively in the present invention.

Suitable nonionic surfactants include polyoxyalkylene alcohol surfactants, especially alkyl polyethyleneglycol ethers, alkyl polypropyleneglycol ethers, alkyl polyethyleneglycol esters, and alkyl polypropyleneglycol esters and mixtures thereof.

Suitable amphoteric surfactant components for use in the shampoo composition herein include those which are known for use in shampoo compositions or other personal care cleansing composition, and which contain a group that is anionic at the pH of the shampoo composition. Concentration of such surfactant components in the shampoo composition preferably ranges from about 0.5 % to about 20%, preferably from about 1% to about 10%, more preferably from about

2% to about 5% by weight of the composition. Examples of amphoteric surfactants suitable for use in the shampoo composition herein are described in U.S. Patents 5,104,646 (Bolich Jr. et al.), U.S. Patent 5,106,609 (Bolich Jr. et al.), which descriptions are incorporated herein by reference. Examples of amphoteric detergents which can be used in the compositions of the present invention are those which are broadly described as derivatives of aliphatic secondary and tertiary amines in which the aliphatic radical can be straight or branched chain and wherein one of the aliphatic substituents contains from about 8 to about 18 carbon atoms and one contains an anionic water solubilizing group, e.g., carboxy, sulfonate, sulfate, phosphate, or phosphonate. Examples of compounds falling within this definition are sodium 3-dodecylaminopropionate, sodium 3-dodecylaminopropanesulfonate, sodium laurylsarcosinate, N-alkyltaurines such as the one prepared by reacting dodecylamine with sodium isethionate according to the teaching of U.S. Patent 2,658,072, N-higher alkyl aspartic acids such as those produced according to the teaching of U.S. Patent 2,438,091, and the products sold under the trade name "MIRANOL™" and described in U.S. Patent 2,528,378.

Other amphoteric surfactants, sometimes classified as zwitterionic surfactants, such as betaines can also be useful in the present invention. Such zwitterionics are considered as amphoteric in the present invention where the zwitterionic has an attached group that is anionic at the pH of the composition. Examples of betaines useful herein include the high alkylbetaines, such as cocodimethylcarboxymethylbetaine, cocoamidopropylbetaine, cocobetaine, laurylamidopropylbetaine, oleylbetaine, lauryldimethylcarboxymethylbetaine, lauryldimethyl-alpha-carboxyethylbetaine, cetyltrimethylcarboxymethylbetaine, lauryl-bis-(2-hydroxyethyl)carboxymethylbetaine, stearyl-bis-(2-hydroxypropyl)carboxymethyl betaine, oleyldimethyl-gamma-carboxypropylbetaine, and lauryl-bis-(2-hydroxypropyl)-alpha-carboxyethylbetaine. The sulfobetaines may be represented by cocodimethyl sulfopropylbetaine, stearyltrimethylsulfopropylbetaine, lauryldimethylsulfopropylbetaine, lauryl-bis-(2-hydroxyethyl)sulfopropylbetaine and the like; amidobetaines and amidosulfobetaines, wherein the RCON(CH₂)₃ radical is attached to the nitrogen atom of the betaine are also useful in this invention. Most preferred for use herein is cocoamidopropylbetaine.

If desired or as necessary, one or more additional benefit agents may also be included in the compositions of the invention, for example to modify the overall cosmetic benefit or combination of benefits imparted to the substrate treated with the composition. Suitable additional cosmetic benefit agents include the following:

- (i) conditioning agents, i.e., materials which impart one or more visual or tactile benefits such as softness, smoothness, shine, non-flyaway, anti-static, ease of dry and/or wet combing, e.g.,

- cationic surfactants, cationic polymers, volatile and/or non-volatile silicones or derivatives thereof, quaternary ammonium salts having at least one long chain alkyl or alkenyl group, protein hydrolysates, quaternized protein hydrolysates, perfluoropolyether materials, fatty alcohols, and mixtures thereof;
- (ii) styling/setting/bodying agents, i.e., materials which give enhanced body and fell to the hair or other fibers or enable them to hold a given shape or style, e.g., various polymers, gums and resins, for example adhesive and/or resinous hydrocarbon materials such as per-alk(en)ylhydrocarbon materials, silicone/siloxane gums or resins, waxes, chitosan and derivatives, salts and complexes thereof, and mixtures thereof;
- (iii) fiber straightening agents;
- (iv) colourants and dyeing agents;
- (v) antidandruff agents, e.g., zinc pyridinethione, Octopirox®, climbazole;
- (vi) sun-protective materials, e.g. sunscreens, especially UV absorbers;
- (vii) hair growth promoters or regulators, e.g. diacylglycerols, glucarolactams, glucarolactones, Minoxidol®;
- (viii) moisturizers, e.g. 2-hydroxyalkanoic acids, acid soap and complexes thereof, and other emollients, occlusives, humectants;
- (ix) pearlescent and/or opacifying materials;
- (x) oils, e.g. silicone oils, oleic acid, hydrocarbons, isopropyl myristate, oleyl alcohol, oleates, squalene, sunflower seed oil, rapeseed oil, other plant derived oils, mineral oil;
- (xi) proteins, vitamins, nutrients, stimulants, antiradicals, astringents;
- (xii) herb or other plant extracts, essential oils etc.
- (xiii) antimicrobial agents, e.g. antibacterial or anti-infestive agents;
- (xiv) other adjunct materials commonly used in cosmetic compositions, e.g., buffering and/or pH adjusting agents, perfumes, colorings, preservatives, proteins etc.
- (xv) anti-malodor agents as those disclosed to treat post-perm odors in US 5,554,364 and EP 0610892.
- (xvi) highly substantive polymers and other moieties including polyethylenimines (PEI's) such as those included within the Polymim® series supplied by BASF.
- (xvii) metal salts comprising alkaline earth metals such as magnesium and calcium, transition metals such as zinc, manganese and copper, and the group IIIA metals such as Al. The use of these metal salts for hair treatment is disclosed in WO9609030 and WO9703640 where they are claimed to form metal-sulfur bonds with the hair for use in hair styling and restyling. Such metal salts could conceivably be employed to complex and interact with the cosmetic active of the

present invention. Such interactions should not interfere too greatly with the performance of the cosmetic actives and could potentially positively influence the performance, i.e., metals could complex with the sulfur atom within cosmetic active and facilitate or induce activation in the form of thiol release.

(xviii) chelating agents including disodium EDTA and tetrasodium EDTA. Chelators could enhance the diffusion and adsorption by binding to and removing metals present in hard water such as calcium and magnesium. Such hard water ions could conceivably complex with certain ionized "hooks" of the present invention electrostatically and inhibit their solubility.

(xix) hydrotropes such as ammonium xylene sulfate. For instance, if the "hooks" of the present invention are incorporated within a surfactant matrix, hydrotropes could improve performance by freeing up the "hook" compounds during dilution to facilitate improved binding to the substrate.

(xx) dispersing aids which may encompass, but are not limited to, non-ionic surfactants, amphoteric surfactants, and ionic surfactants. If the "hooks" of the present invention are incorporated within a non-aqueous matrix or as an insoluble dispersion, dispersing aids could be utilized to enhance solubilization and subsequent activation.

(xxi) Ion-pair ingredients. For certain ionic "hooks" of the present invention, compounds could be employed that ion-pair with the "hooks" including, but not limited to cations, anions, quaternized ammonium compounds, amphoteric compounds, and metals. Such charged species could be utilized to manipulate the diffusion, adsorption and the binding of the "hook" compounds of the present invention.

(xxii) Drying agents designed to minimize residual levels of water in non-aqueous solvent, including, but not limited to molecular sieves.

The pH of the compositions of the present invention is frequently important in achieving optimized chemisorption of the protected thiol compound. The most suitable pH for a given composition may depend principally on the type and structure of the protecting group as it pertains to activation. For instance, many of the protecting group can be activated for improved performance via pH catalyzed hydrolysis. In these cases, the pH of the composition would need to be such that the molecular 'hook' is not activated prior to usage. As described above, during usage the pH of the composition containing the molecular 'hook' can be manipulated, i.e., via inter-mixing with separate pH activating composition, such that the molecular 'hook' is activated during or immediately prior to usage.

The protecting groups of the present invention are to be used within a pH range from about 1 to about 12, preferably from about 3 to about 11, more preferably from about 4 to about 10. In the cases wherein the protecting group are activated at any of the above pH's, the composition

would need to be non-aqueous and essentially free of water or moisture to such a degree that prohibits significant hydrolysis induced activation prior to usage. As such, the water imparted to the composition during usage from the shower, bath or from the wetted substrate could provide the activation required to optimize the resulting chemisorption.

As mentioned above, it has surprisingly been found that certain protecting groups are not activated hydrolytically at pH's within the above ascribed relevant range while still providing durable benefits on hair. For these compounds, the pH of the composition is irrelevant in as much as the composition pH suits the cosmetically active group, R.

Many of the embodiments of the present invention comprise a silicone composition which includes at least one polysiloxane or silicone resin, at least one linker, and at least one molecular hook. For example, said silicone composition typically imparts improved hair care benefits when added to hair care compositions.

The at least one linker is bound to both a molecular hook and to an atom of a polysiloxane or silicone resin. Preferably the at least one linker is bound to a polysiloxane or silicone resin through a silicon, carbon, oxygen, nitrogen, or sulfur atom, and most preferably to a silicon atom. When more than one linker is present, it is also contemplated that linkers may be bound to a polysiloxane or silicone resin through more than one type of atom, for example through both silicon and carbon atoms.

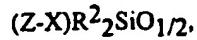
Therefore, in one embodiment the present invention comprises at least one polysiloxane or silicone resin having the formula:



where the subscripts a, c, d, e, f and g are zero or a positive integer, subject to the limitation that the sum of the subscripts b, d and f is one or greater; where M has the formula:



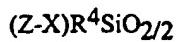
M' has the formula:



D has the formula:



D' has the formula:



T has the formula:



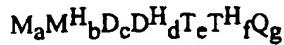
T' has the formula:



and Q has the formula SiO_{4/2}, where each R¹, R², R³, R⁴, R⁵ is independently at each occurrence a hydrogen atom, C₁₋₂₂ alkyl, C₁₋₂₂ alkoxy, C₂₋₂₂ alkenyl, C₆₋₁₄ aryl, and C₆₋₂₂ alkyl-substituted aryl, and C₆₋₂₂ aralkyl which groups may be halogenated, for example, fluorinated to contain fluorocarbons such as C₁₋₂₂ fluoroalkyl; Z, independently at each occurrence, represents the molecular hook; and X, independently at each occurrence, represents the linker. The term "alkyl" as used in various embodiments of the present invention is intended to designate both normal alkyl, branched alkyl, aralkyl, and cycloalkyl radicals. Normal and branched alkyl radicals are preferably those containing from 1 to about 12 carbon atoms, and include as illustrative non-limiting examples methyl, ethyl, propyl, isopropyl, butyl, tertiary-butyl, pentyl, neopentyl, and hexyl. Cycloalkyl radicals represented are preferably those containing from 4 to about 12 ring carbon atoms. Some illustrative non-limiting examples of these cycloalkyl radicals include cyclobutyl, cyclopentyl, cyclohexyl, methylcyclohexyl, and cycloheptyl. Preferred aralkyl radicals are those containing from 7 to about 14 carbon atoms; these include, but are not limited to, benzyl, phenylbutyl, phenylpropyl, and phenylethyl. Aryl radicals used in the various embodiments of the present invention are preferably those containing from 6 to 14 ring carbon atoms. Some illustrative non-limiting examples of these aryl radicals include phenyl, biphenyl, and naphthyl. An illustrative non-limiting example of a halogenated moiety suitable for R¹⁻⁵ groups is trifluoropropyl.

The polysiloxanes or silicone resins of the present invention are typically prepared by the

hydrosilylation of an organohydrogen silicone having the formula:



where the subscripts a, c, d, e, f and g are zero or a positive integer, subject to the limitation that the sum of the subscripts b, d and f is one or greater; where M has the formula:



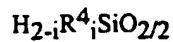
M^H has the formula:



D has the formula:



D^H has the formula:



T has the formula:



T^H has the formula:



and Q has the formula $SiO_{4/2}$, where each R^1, R^2, R^3, R^4, R^5 is independently as defined above.

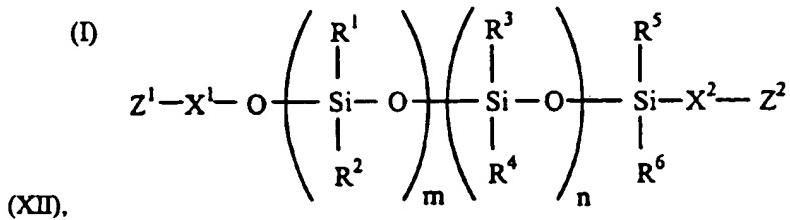
Hydrosilylation is typically accomplished in the presence of a suitable hydrosilylation catalyst. The catalyst preferred for use with these compositions are described in U.S. Pat. Nos. 3,715,334; 3,775,452; and 3,814,730 to Karstedt. Additional background concerning the art may

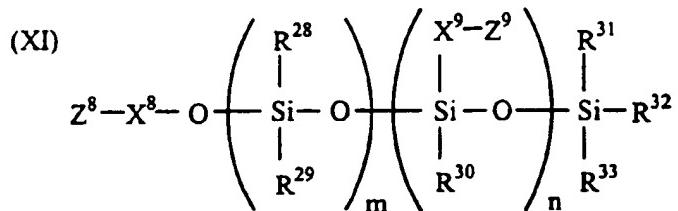
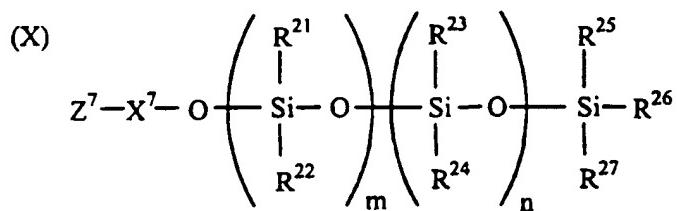
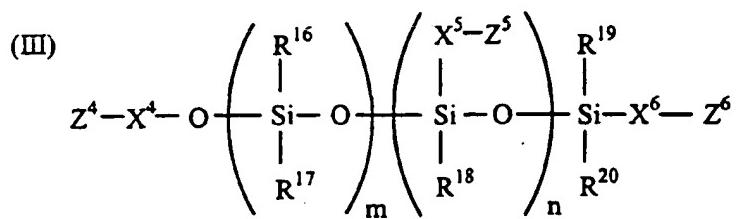
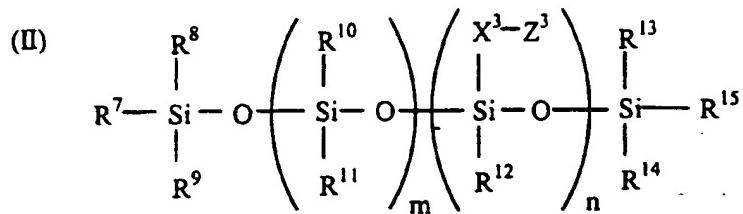
be found at J. L. Spier, "Homogeneous Catalysis of Hydrosilation by Transition Metals, in *Advances in Organometallic Chemistry*, volume 17, pages 407 through 447, F. G. A. Stone and R. West editors, published by the Academic Press (New York, 1979). Persons skilled in the art can easily determine an effective amount of platinum catalyst. Generally, an effective amount ranges from about 0.1 to 50 parts per million of the total organopolysiloxane composition.

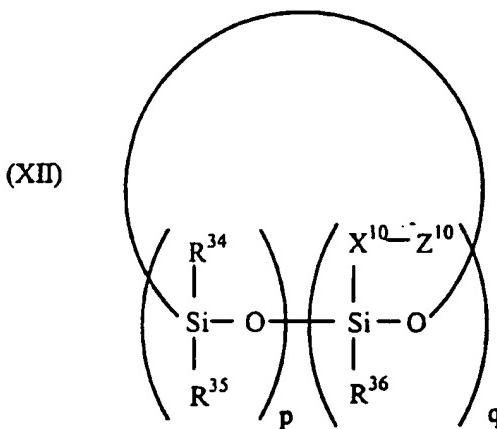
The organohydrogen silicone compounds that are the precursors to the compounds of the present invention may be prepared by the process disclosed in U.S. Pat. No. 5,698,654 herewith specifically incorporated by reference. The '654 patent discloses a sequential catalysis of the ring opening polymerization of cyclic organosiloxanes using a base catalyst that can be neutralized by a subsequent redistribution and condensation catalyst such as a Lewis acid catalyst, preferably a phosphonitrilic compound, that permits the rapid synthesis of functionalized and poly-functionalized silicone copolymers.

It is to be noted that as pure compounds the subscripts describing the organohydrogen siloxane precursor and the hydrosilylation adduct of the present invention are integers as required by the various rules of chemical stoichiometry. As mixtures of compounds that are described by these formulas the subscripts will assume non-integral values, for the mixtures. The restrictions on the subscripts heretofore described for the stoichiometric subscripts of these compounds are for the pure compounds, not the mixtures.

In specific embodiments of the present invention, the silicone composition typically comprises at least one compound of the following formulas, (I), (II), (III), (X), (XI), and



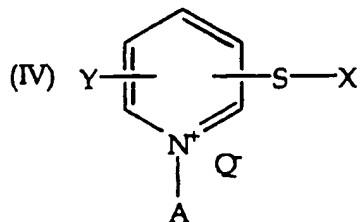




where each R¹, R², R³, R⁴, R⁵, R⁶, R⁷, R⁸, R⁹, R¹⁰, R¹¹, R¹², R¹³, R¹⁴, R¹⁵, R¹⁶, R¹⁷, R¹⁸, R¹⁹, R²⁰, R²¹, R²², R²³, R²⁴, R²⁵, R²⁶, R²⁷, R²⁸, R²⁹, R³⁰, R³¹, R³², R³³, R³⁴, R³⁵, and R³⁶ is independently at each occurrence a hydrogen atom, C₁₋₂₂ alkyl, C₁₋₂₂ alkoxy, C₂₋₂₂ alkenyl, C₆₋₁₄ aryl, and C₆₋₂₂ alkyl-substituted aryl, and C₆₋₂₂ aralkyl which groups may be halogenated, for example, fluorinated to contain fluorocarbons; Z, independently at each occurrence, represents a molecular hook; and X, independently at each occurrence, represents a linker; wherein "m" in each formula has a value in a range between about 0 and about 13,000, preferably about 0 and about 1000, more preferably between about 1 and about 250, still more preferably between about 5 and about 150, even more preferably between about 10 and about 100, and most preferably between about 20 and about 50; "n" in each formula has a value in a range between about 0 and about 13,000, more preferably between about 0 and about 50, more preferably between about 1 and about 20, still more preferably between about 2 and about 10, and most preferably between about 2 and about 5; "m+n" in each formula has a value in a range between about 1 and about 13,000, preferably between about 3 and about 70, more preferably between about 5 to about 50, and most preferably between about 15 and about 50; "q" has a value of at least one and "p+q" has a value of at least 3, preferably in the range of 3-20, more preferably in the range of 3-10, and most preferably in the range of 3-6. The polysiloxane or silicone resin typically has a molecular weight ranging from about 100 to about 1,000,000, preferably from about 250 to about 50,000, more preferably from about 500 to about 25,000, and most preferably from about 500 to about 7,000. The at least one polysiloxane or silicone resin typically has a viscosity in a range between about 20 centipoise and about 2,500,000 centipoise (about 0.02 to about 2500 Pas).

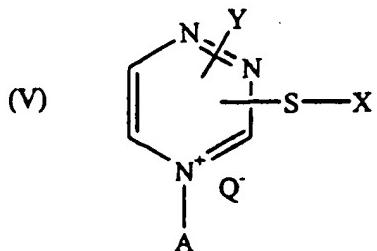
The number of X-Z moieties on a polysiloxane or silicone resin in the composition is at least one. In preferred embodiments the average number of X-Z moieties on a polysiloxane or silicone resin is between about 1 and about 100, more preferably between about 1 and about 20, still more preferably between about 1 and about 6, and most preferably between about 3 and about 6.

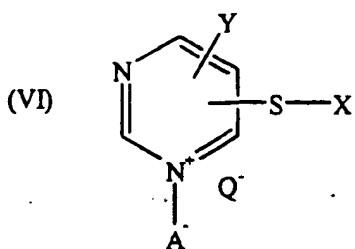
In one embodiment of the present invention a polysiloxane- or silicone resin-containing composition comprises a preponderance of a specific linear, branched, cross-linked, or cyclic polysiloxane or silicone resin. In other embodiments a polysiloxane- or silicone resin-containing composition comprises a mixture of polysiloxanes and/or silicone resins which may include linear, branched, cross-linked, and cyclic species. Also, suitable compositions may comprise one or more polysiloxanes and/or silicone resins which may contain adventitious amounts of other species, for example arising during the synthesis process for said polysiloxanes and/or silicone resins, for example at a level of about 0.0001 wt.% to about 5 wt.% based on total silicon-containing species. In illustrative examples suitable compositions may contain adventitious amounts of D₄, or species containing Si-H, Si-OH, and/or Si-O-alkyl bonds.



The molecular hook may be a heterocyclic pyridinium compound (IV), a heterocyclic triazinium (V), or a heterocyclic pyrimidinium compound (VI) :

wherein Y represents optional substituents on the heterocyclic ring or ring system, X represents the linker, Q represents a counterion, and A is defined below.





Optional substituents, Y, which can be present on the heterocyclic ring or ring system can be selected from hydrogen or electron withdrawing, electron neutral, or electron donating groups with Hammett sigma para values between -1.0 and +1.5 comprising carbon-linked groups of the classes defined as A¹, A², A³, and A⁴; S-linked groups including SA¹, SCN, SO₂A¹, SO₃A¹, SSA¹, SOA¹, SO₂NA¹A², SNA¹A², S(NA¹)A², SA¹(NA²), SONA¹A²; O-linked groups including OA¹, OCN, ONA¹A²; N-linked groups including NA¹A², NA¹A²A³⁺, NA¹OA², NA¹SA², NCO, NCS, NO₂, N=NA¹, N=NOA¹, NA¹CN, N=C=NA¹, NA¹NA²A³, NA¹NA²NA³A⁴, NA¹N=NA²; other miscellaneous groups including CONA¹, CONA¹COA², C(=NA¹)NA¹A², CHO, CHS, CN, NC, Hal, and derived groups that connect one or more of the optional substituents via a ring system; Hal is fluorine, chlorine, bromine, or iodine.

A, A¹, A², A³, and A⁴ each represent, independently from one another, a monovalent group which can be the cosmetic active group, R, or H or any of the following: a straight, branched or mono- or polycyclic aliphatic, mono- or polyunsaturated alkyl, aryl, heteroalkyl, heteroaliphatic or heteroolefinic system including 1 to 30 carbon atoms together with 0 to 15 heteroatoms, especially oxygen (O), nitrogen (N), sulfur (S), phosphorus (P), silicon (Si) and can incorporate one or more substituents including, but not limited to, poly or perfluoro substitution.

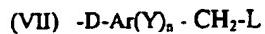
The counterion, Q⁻, can include halides, borates, phosphates, tosylates, mesylates, triflates, and other counterions known to those skilled in the art.

The linker comprises a C₁-C₅₀ alkyl, aryl, or alkylaryl group, or C₁-C₅₀ heteroaryl group containing one or more heteroatoms, and is optionally functionalized. Optional functionalization on the linker includes ketones, alkoxy, esters, amides, trifluoromethyl, halogens, nitriles and other polar functional groups known to those skilled in the art. The linker is typically derived from a linker precursor which comprises a linker bound to a leaving group (L). Illustrative leaving groups include halides such as chloride, bromide and iodide; tosylate, mesylate, phosphate; cyclic leaving groups (that is, those in which the leaving group remains bound in the linker) such as epoxy or other cyclic leaving group containing at least one heteroatom; and other

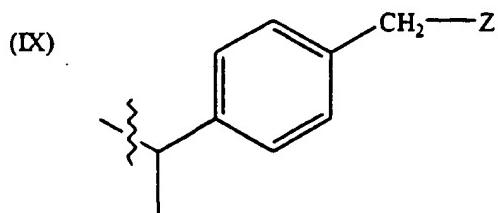
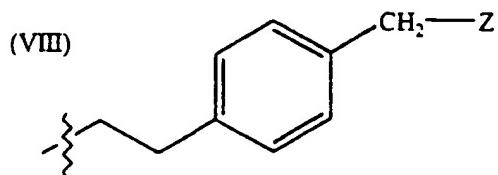
leaving groups known to those skilled in the art. Preferred leaving groups are bromide and iodide, with iodide being particularly preferred.

In synthesis, the leaving group is replaced by a molecular hook, so that the linker becomes bound to a molecular hook. In one embodiment the at least one linker precursor may be combined with the at least one molecular hook before combining with a polysiloxane or silicone resin. In a particularly preferred embodiment the at least one linker precursor may be combined with a polysiloxane or silicone resin before combining with the at least one molecular hook.

Typically, the linker precursor has the formula (VII)



wherein D comprises a group bound to a polysiloxane or a silicone resin; "Ar" is an aromatic or heteroaromatic group, optionally substituted with one or more substituents; "Y" is a substituent; "L" is as defined above; and "n" has a value between zero and the number of free valence sites on the aromatic or heteroaromatic ring. Non-limiting examples of suitable aromatic and heteroaromatic groups in linkers include phenyl, biphenyl, toluyl, naphthyl, pyridyl, quinolyl, triazinyl, pyrimidyl, pyridazinyl, furyl, furoyl, and thienyl. Illustrative examples of substituents (Y) which may be bound to said aromatic or heteroaromatic group include C₁₋₂₂ straight chain, branched, cycloaliphatic, or aralkyl; C₆₋₁₄ aryl; fluoro, chloro, bromo, iodo, nitro, nitroso, nitrile, trifluoromethyl, trifluoropropyl, alkyloxycarbonyl, alkylcarbonyl, alkylamido, alkyl-ether, aryl-ether, and similar electron-withdrawing, electron-donating, and electron-neutral groups. The "D" group may comprise a straight chain, branched, cycloaliphatic, or aralkyl group which optionally may contain a functional group, said functional group being bound to D in a pendent position or separating D from the aromatic or heteroaromatic group, or separating D from a polysiloxane or a silicone resin, or in more than one of these positions. Illustrative examples of D groups include C₁₋₂₂ alkyl and preferably C₂₋₃ alkyl. Illustrative examples of functional groups which may be present with D include carbonyl, alkylcarbonyl, oxycarbonyl, alkyloxycarbonyl, nitrile, amido, alkylamido, trifluoromethyl, and halogen, such as chloro, bromo, and/or fluoro. Preferred examples of linkers are shown in formulas (VIII) and (IX) :



Silicone-containing compositions comprising at least one polysiloxane or silicone resin, at least one linker, and at least one molecular hook typically impart cosmetic and other benefits in applications such as hair care (for example durable hair care benefit), textile care, cosmetics, oral care, and animal care.

In order that those skilled in the art will be better able to practice the invention, the following examples are given by way of illustration and not by way of limitation.

CHARACTERISTICS

The protected thiol compounds of the present invention, when applied to a amino acid based substrate, have improved uptake levels and reduced levels of fade or removal. That is the thiol functional groups demonstrate improved attachment of the functional group, R, to the amino acid based substrate and longer lasting attachment than alternative reactive technologies. These benefits are demonstrated without requiring addition steps of reducing or oxidizing the substrate which typically are required in the art to achieve durable cosmetic benefits.

Reduction as defined herein comprises chemical compositions and treatments that induce the nucleophilic cleavage of disulfide bonds in keratin substrates resulting in the formation of free thiol groups in the form of cysteinyl amino acid residues. Reduction is employed in several commercial products and processes including the permanent-waving of human hair, human hair straightening, human hair depilation, and in the dyeing of wool with fiber reactive dyes. Several compounds and processes known to induce keratin reduction include (i) low molecular weight thiols such as thioglycolic acid, thiolactic acid, cysteine, thioglycerol, thioglycolic hydrazide, thioglycolamide, and glycerol monothioglycolate, (ii) sulfides such as salts of hydrogen sulfide,

(iii) high temperature and alkali wherein the keratin is heated to around 100°C or above by a heating source or steam and wherein the keratin can be contacted with an alkaline solution, (iv) cyanide such as the salts of hydrogen cyanide, (v) phosphines such as trihydroxymethyl phosphine or its precursor, tetrahydroxymethyl phosphonium chloride, (vi) other miscellaneous reducing agents such as borohydride, dithionite, hydrosulfite, and sulfoxylate and (vii) combinations thereof. Reduction as defined herein generally refers to the above processes and compositions which reduce greater than 10% of the disulfide bonds in the keratinaceous substrate. The relative quantities of reduced versus unreduced keratin fiber depend on the type of reducing agent, its concentration (or degree of application in the case of heat), the solution-to-hair ratio, pH of the reaction medium, time of reaction, fiber diameter, and the condition of the hair. A more detailed discussion on disulfide reduction can be found in the article by Gershon et al. (Gershon, S. D.; Goldberg, M. A.; Rieger, M. In Cosmetics Science and Technology, Sagarin, E., eds., pp. 583-627. Interscience, New York (1963)).

Oxidation as defined herein comprises chemical compositions and treatments that induce the oxidative cleavage of disulfide bonds in keratin substrates resulting in the formation of sulfonic acid groups in the form of cysteic acid amino acid residues. Oxidation is employed in several commercial products and processes including the bleaching of human hair, permanent dyeing of human hair with oxidation dyes, and in the dyeing of wool with fiber reactive dyes. Hydrogen peroxide is the principle oxidizing agent used in most oxidizing compositions and is delivered liberally to the substrate as a 3 to 12% solution which may be alkaline. Persulfates, in the form of their sodium potassium and ammonium salts, may also be used to be mixed with the hydrogen peroxide just before use. Other ingredients that may be additionally included in the composition include sodium percarbonate, sodium perborate, magnesium perborate, magnesium dioxide and barium binoxide. Oxidation as defined herein generally refers to the above processes and compositions which degrade greater than 10% of the disulfide bonds in the keratinaceous substrate. A more detailed discussion on disulfide oxidation can be found in the articles by Zahn and Robbins (Zahn, H. J. Soc. Cosmet. Chem. 17:687 (1966); Robbins, C.; Kelly, C. J. Soc. Cosmet. Chem. 20:555 (1969)).

Both reduction and oxidation of amino acid based substrates lead to irreparable damage to the substrate by virtue of their destructive chemical reactions. For instance, both reduction and oxidation result in disulfide bond cleavage which has been shown to significantly reduce the wet tensile properties of human hair through 30% extension (Clarence Robbins book: Chemical and Physical Behaviour of Human Hair). Also, reduced hair has been shown to be less rigid in the wet state than unreduced hair (Bogaty, H. J. Soc. Cosmet. Chem. 18:575 (1967)) and the wet

bending stiffness and wet stretching stiffness were demonstrated to decrease on oxidized hair (Robbins Book). Furthermore, reduced hair has been shown to exhibit increased frictional resistance (Schwartz, A.; Knowles, D. J. Soc. Cosmet. Chem. 14:455 (1963)) which is evidence of imparted damage to the hair. These demonstrated destructive chemical interactions with keratin have been shown to translate into keratin that is drier, more brittle to the touch, more porous, weaker and which tangles more easily (The Science of Hair Care, by Charles Zviak).

PROCESSES FOR PREPARING THE PROTECTED THIOL COMPOUNDS

The compounds of the invention can be prepared by any of a number of procedures known to those skilled in the art. Several nonlimiting examples are described herein below.

HETEROCYCLIC PROTECTING GROUPS

Alkylthio substituted pyridines can be prepared by reaction of halopyridines with a variety of thiols in the form of metal salts [Takahashi, Saikachi, Akai, *J. Pharm. Soc. Japan.*, 1943, 63, 153; Adams, Ferretti, *J. Am. Chem. Soc.*, 1959, 81, 4927]. Another method of preparation involves alkylation of pyridinethiols [Marckwald, Klemm, Trabert, *Ber.*, 1900, B33, 1156; Forrest, Walker, *J. Chem. Soc.*, 1948, 1939].

Alkylthio substituted pyrimidines can be prepared by alkylation of mercaptopyrimidines [Southon, Pfeiderer, *Chem. Ber.*, 1978, 111, 982; A. G. Geigy, *Chem. Abstr.*, 1969, 70, 68418] or directly from halogenopyrimidines [Semga, Ichiba, Kanazawa, Nishigaki, *J. Heterocyclic. Chem.*, 1982, 30, 610].

Alkylthio substituted pyrazines can be prepared from halogenopyrazines and appropriate sodium (or potassium) alkyl thiolate at elevated temperatures [Konakahara, Y. Takagi, *Bull. Chem. Soc. Japan*, 1960, 80, 349]. The alternative method is alkylation of mercaptopyrazines [A. Albert, G.B. Barlin, *J. Chem. Soc.*, 1962, 3129].

Alkylthio substituted pyridazines can be prepared by treatment of halopyridazines with a thiol in the form of its alkali salt or with a thiol in the presence of base [Druey, K. Meier, K. Eichenberger, *Helv. Chim. Acta*, 1954, 37, 121; M. Fujisaka, Y. Neno, H. Shinobara, E. Imoto, *Bull. Chem. Soc. Japan*, 1964, 37, 1107; T. Horie, K. Kinjo, T. Ueda, *Chem. Pharm. Bull.*, 1962, 10, 580]. Alkylation of pyridazinethiones and pyridazinethiols as well as some other methodologies are also published. [M. Tisler and B. Stanovnik "Pyridazines and their Benzo Derivatives", in "Comprehensive Heterocyclic Chemistry", 1984, Pergamon Press, Ltd.; M. Tisler and B. Stanovnik "Sulfur Compounds of Pyridazines", in "The Chemistry of Heterocyclic Compounds", 1973, John Wiley&Sons, Inc.]

For the alkylthiol substituted triazines and tetrazines, a comprehensive review on the synthesis of these compounds is found in the literature. [M. Tisler and B. Stanovník, *J. Het. Chem.*, 1971, 785; Reissert and Grube, *Chem. Ber.*, 42, 1909, 3720; Gompper and Schoenafinger, *Chem. Ber.*, 112, 1979, 1529; Arndt, Eistert, *Chem. Ber.*, 60, 2602, 1927; Grundmann et al, *J. Org. Chem.*, 23, 1958, 1522; Cristescu, Panaiteescu, *Pharmazie*, 17, 1962, 209; H. Neunhoeffer, H. Hammann, *Tet. Lett.*, 24, 1983, 1767; J. L. Johnson, B. Whitney, L.M. Leslie, *J. Het. Chem.*, 17, 1980, 501; S. C. Fields, M. H. Parker, W. R. Erickson, *J. Org. Chem.*, 1994, 8284.]

The six membered O, N, and/or S containing heterocyclics with C=O, C=S or C=C exocyclic groups can be prepared from halogen derivatives of corresponding heterocycles and thiols. [Tominaga, A. Ushiroguchi, Y. Matsuda, *J. Het. Chem.*, 24, 1987, 1557; Y. Tominaga, et al, *Chem Pharm Bull.*, 32, 3384, 1981; L. Adelfang, *J. Org. Chem.*, 31, 2389, 1966; L. W. Singh, H. Junjappa, *Synthesis*, 5, 531, 1985; W. D. Rudorf, R. Schawtz, *Tet. Lett.*, 28, 4267, 1987; B. Deb, H. Ila, et al, *Synthesis*, 10, 893, 1987.]

Alkylthio substituted pyridinium derivatives can be prepared by quaternization of the corresponding pyridine alkyl thioethers and other methods. [Yamada, et al, *J. Org. Chem.*, 42, 2180, 1977; M. Yamada, et al, *J. Chem. Soc., Chem. Comm.*, 179, 1979; T. Sakakibara, Y. Watabe, M. Yamada, R. Sudoh, *Bull. Chem. Soc. Jpn.*, 61, 247, 1988.]

Alkylthio substituted xanthenes can be prepared from thiols and xanthene with a suitable leaving group [K. J. Divakar, C.B. Reese, et. al., *J. Chem. Soc., Perkin Trans. 1*, 1990 (6), 1753]

Alkylthio substituted pyrimidinium derivatives can be prepared by quaternization of the corresponding pyrimidine alkyl thioethers and other methods. [Deichmeister, Platoshkiin, *Khim. Geterosicl. Soedin.*, 1, 1961, 333; Brown, England, *J. Chem. Soc. C*, 1971, 2507; Ueda, Ohtsuka, *Chem. Pharm. Bull.*, 21, 1973, 1451.]

Alkylthio substituted pyrazinium derivatives can be prepared by quaternization of the corresponding pyrimidine alkyl thioethers and other methods. [Barlin, Benbow, *J. Chem. Soc., Perkin Trans. 2*, 1975, 1385; Honz, et al, *Tetrahedron*, 26, 1970, 2305; B. Geutzen et al, *Tetrahedron*, 1989, 6519; S. Batori, A. Messmer, *J. Het. Chem.*, 1990, 1673.]

Alkylthio substituted furans can be prepared from the corresponding furan thiols and alkyl halides. [Gorzynski, D. Rewicki, *Liebigs Ann. Chem.*, 1986, 625; P.G. McDougal, Y-I Oh, *Tet. Lett.*, 27, 139, 1986; R. Tanikaga, et al, *J. Chem. Soc., Chem. Com.*, 1106, 1981; H. Gotthatdt, C.M. Weissuhn, K. Dorhofer, *Chem. Ber.*, 111, 3336, 1978; R. Adams, A. Ferretti, *J. Am. Chem. Soc.*, 81, 4927, 1959; A. Ferretti, G. Tesi, *Chem Ind.*, p. 1987, 1964; L. M. Yagupolskii, N.V. Kondratenko, V.P. Sambur, *Synthesis*, 721, 1975; B.L. Feringa, et al, *Synthesis*, 316, 1988; S.P. Tanis, D.B. Head, *Tet. Lett.*, 25, 4451, 1984.]

Alkylthio substituted pyrroles can be prepared by S-alkylation of 2- and 3-pyrrolethiols under standard base-catalyzed conditions. [K. Olsen, H.R. Snyder, *J. Org. Chem.*, 30, 184, 1965; S. Apparao; H. Ila, H. Junjappa, *Synthesis*, 65, 1981; M. Cardellini et al, *Synthesis*, 1980, 886; A. K. Gupta, H. Ila, et al, *Synthesis*, 141, 1989; S. Gronowitz, R. Kada, *J. Het. Chem.*, 1041, 1984; M. Colonna, M. Polni, *Gazz. Chim. Ital.*, 116, 449, 1986; H. Kojima, H. Inoue, et al, *Chem. Lett.*, 1499, 1989; Y. Tominaga, et al, *J. Het. Chem.*, 26, 477, 1989.]

Alkylthio substituted thiophenes can be prepared by reacting the alkali salts of thiophene thiols with aliphatic halogen compounds. [Thomas, G. Singh, H. Ila, H. Junjappa, *Tet. Lett.*, 30, 3093, 1989; W.-D. Rudorf, A. Schierhorn, M. Augustin, *J. Prakt. Chem.*, 321, 1021, 1979; J. Cymerman-Craig, J. W. Loder, *Org. Synth.* 667, 1963; J. Cymerman-Craig, J. W. Loder, *J. Chem. Soc.*, 237, 1954; E.J. Smutny, *J. Am. Chem. Soc.*, 91, 208, 1969.]

Alkylthio substituted pyrazoles, the 3- and 5- derivatives, can be prepared by the alkylation of the corresponding pyrazolethiones [Michaelis, Lachwitz, *Chem. Ber.*, 1910, 43, 2106; Michaelis, *Ann.*, 1908, 283].

Alkylthio substituted isoxazoles can be prepared by alkylating the thio group at the 3 position of isoxazoles [A.Thuiller and J.Vialle, *Bull.Soc. Chim. Fr.*, 1959, 1398; W. D. Rudorf and M. Augustin, *J. Prakt. Chem.*, 1978, 320, 585; : K. Tomita, S. Sugai and M.Saito, *Chem. Pharm. Bull.*, 1979, 27, 2415; S. Sugai and K. Tomita, *Chem. Pharm. Bull.*, 1980, 28, 552].

Alkylthio substituted isothiazoles can be prepared by alkylating both 3- and 5- mercaptoisothiazoles [K. R. H. Wooldridge, *Adv. Heterocycl. Chem.*, 1972, 14, 1; B. Torretta, G. Ronsivalle, E. Bousquet, F. Guerrera and M. A. Siracusa, *Gazz. Chim. Ital.*, 1980, 133; : K. Gewald, W. Radke and U. Hain, *J. Prakt. Chem.*, 1980, 322, 1021].

Alkylthio substituted triazoles can be prepared from the corresponding thiotriazoles by S- alkylation with various alkyl bromides [M.A. Weaver, R.R. Giles, *Ger. Pat.*, 1970, 1,919,045; J. Heindl, E. Schroeder, H.W. Kelm, *Eur. J. Med. Chem. - Chim. Ther.*, 1975, 10, 121.].

Alkylthio substituted 1,2,4-oxadiazoles can be prepared from the corresponding halogen oxadiazoles and thiols. [M. Paton, D.G. Hamilton, *Tet. Lett.*, 24, 5141, 1983; D.J. Greig, et al, *J. Chem. Soc., Perkin Trans.*, 607, 1987; Sumitomo Chem Ind KK, *Japan Patent*, 1005072 (J6-1005072), 86-05143, 1986.]

Alkylthio substituted 1,2,4-thiadiazoles can be prepared via dipotassium cyanodithioiminocabonate followed by alkylation [W. A. Thaler and J. R. McDivitt, *J. Org.*

Chem., 1971, 36, 10; : Badische Anilin und Soda-Fabrik A.-G., Br. Pat. 1 116198 (1968), (Chem. Abstr., 1968, 69, 86995)].

Alkylthio substituted pyrazolium derivatives can be prepared by reaction of the corresponding alkylthiopyrazoles with alkyl halides. [Michaelis, *Justus Lieb. Ann. Chem.*, 331, 1904, 230; v. Auwers, Bergmann, *Justus Lieb. Ann. Chem.*, 472, 1929, 310; Michaelis, *Justus Lieb. Ann. Chem.*, 361, 1908, 270; K. Hartke, X.-P. Popp, *Arch. Pharm.*, 1994, 385.]

Alkylthio substituted triazolium derivatives can be prepared from halogen derivatives of the corresponding triazoles and lithium thiolates [M. Begtnup, *Bull. Soc. Chim. Belg.*, 1988, 573].

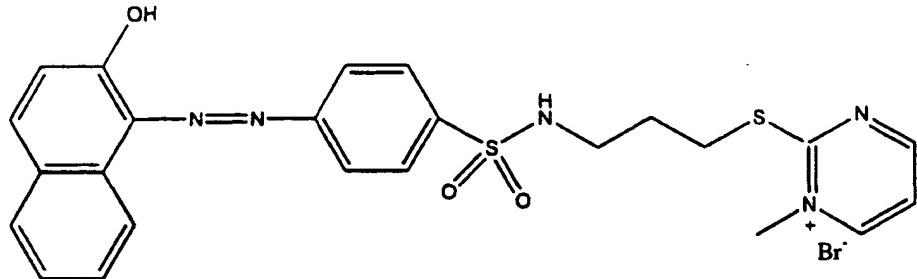
Alkylthio substituted azepines can be obtained from the corresponding halogen derivatives [W. Steglich, H. Bauek, B.M. Grosse, R. Leschke, T. Josten, J. Klein, *J. Heterocycl. Chem.*, 1990, 107].

Alkylthio substituted thiepinium derivatives can be prepared from the corresponding thiepins and an alkylation agent [H. Hofmann, A. Molnar, *Tetrahedron Lett.*, 1977, 1985; H. Hofmann, A. Molnar, C. Gottfert, *Liebigs Ann. Chem.*, 1983, 425; H. Hofmann, H. Fisher, M. De Vries, *Z. Naturforsch. Teil B*, 1990, 1573].

Synthesis routes for heterocyclic protected thiol compounds are exemplified by the following non-limiting examples:

EXAMPLE 1

Pirimidinium, 2-[{[3-[[4-[(2-hydroxy-1-naphthalenyl)-azo]phenyl]sulfonyl]amino]propyl}thio]-1-methyl-, bromide



3-(4-Acetamidophenoxy)sulfonamido)propyl bromide

To a stirred solution of N-acetylsulfanilyl chloride (57.15 g, 0.244 mol) in acetone (500 mL) and H₂O (187.5 mL) at 0°C was added 3-bromopropylamine hydrobromide (25.0 g, 0.114 mol). When a clear solution was obtained, a solution of sodium hydrogencarbonate (44.15 g, 0.526 mol) in H₂O (550 mL) was added dropwise, maintaining the internal temperature at 0-5°C. When the addition was completed, the reaction mixture was heated at 50°C for 5 h, then cooled to room temperature and poured into ice H₂O with stirring. After stirring at 5°C for 4 h, the

suspension was filtered and the filter cake was washed with H₂O and dried in vacuo to give 34.6 g (90%). An additional reaction was performed to give an additional 63.7 g of similar material.

3-(4-Aminophenylsulfonamido)propyl bromide

A mixture of 3-(4-acetamidophenylsulfonamido)propyl bromide (34.5 g, 0.103 mol), conc. HCl (43 mL) and EtOH (86 mL) was heated at reflux for 0.5 h, and the suspension was poured into a solution of H₂O (200 mL) and EtOH (150 mL). The suspension was neutralized with 30% NaHCO₃ (aq) to pH 7-8, then filtered. The filter cake was washed with H₂O and dried in vacuo to give 27.2 g (90%). An additional reaction was performed to give an additional 48.8 g of similar material.

2-Hydroxynaphthalene, 1-[4-[[[[3-(bromopropyl)]amino]-sulfonyl]phenyl]azo]-

A solution of 3-(4-aminophenylsulfonamido)propyl bromide (25.0 g, 0.085 mol) in H₂O (300 mL) and conc. HCl (35.5 mL, 0.426 mol) was cooled to 5-10°C then a solution of sodium nitrite (6.70 g, 0.094 mol) in H₂O (50 mL) was added portionwise, maintaining the internal temperature below 10°C. When the addition was completed, the solution was stirred for 5 min at 5-10°C, and then the solution was added in three portions (maintaining the internal temperature below 10°C) to a solution of 2-naphthol (12.3 g, 0.085 mol) and sodium hydroxide (22.2 g, 0.554 mol) in H₂O (150 mL). Additional sodium hydroxide was added during the addition of the diazonium salt to maintain the pH above pH 7. When the addition was completed, the red-orange suspension was stirred at 5-10°C for 10 min then allowed to stand at room temperature for 20 h. The suspension was acidified with conc. HCl (45 mL) (pH <5), stirred for 2 h and filtered. The filter cake was triturated with H₂O (4 x 500 mL), then filtered and dried in vacuo at 60°C to give 37.1 g (97%).

2(1H)-Pyrimidinethione, 1-methyl-

To a stirred mixture of 1-methyl-2-thiourea (76.6 g, 0.85 mol) and malonaldehyde bis(dimethyl acetal) (126.8 g, 0.77 mol) in EtOH (1.5 L) was added 10M HCl (76.6 mL, 0.77 mol) in one portion. The resulting mixture was stirred at 25°C for 18 h, then spin-evaporated in vacuo. The residue was dissolved in H₂O (1.25 L). The solution was made alkaline by the portionwise addition of K₂CO₃, and extracted with CH₂Cl₂ (4 x 500 mL). The combined extracts were dried over MgSO₄ and spin-evaporated in vacuo to a solid. The crude product was recrystallized from EtOH (600 mL) then dried to constant weight in vacuo at room temperature to give 22.9 g (23%) of product; mp 186-188°C (uncorrected). An additional reaction was performed to give a total of 40.7 g.

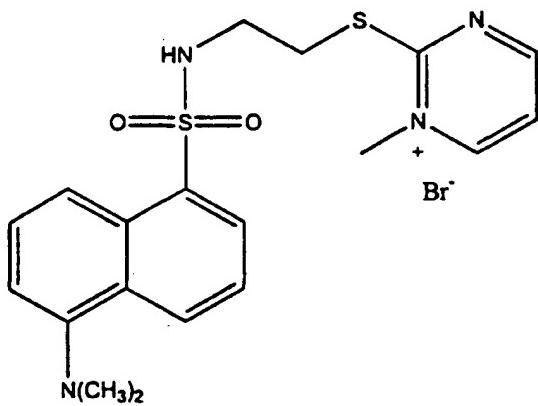
Pyrimidinium, 2-[3-[4-[[(2-hydroxy-1-naphthalenyl)azol-phenyl]sulfonyl]amino]propyl]thio]-1-methyl-, bromide

A solution of 2-hydroxynaphthalene, 1-[4-[[[[3-(bromo-propyl)]amino]sulfonyl]phenyl]azo]- (22.4 g, 0.05 mol) and 2(1H)-pyrimidinethione, 1-methyl- (6.30 g, 0.05 mol) in N,N-dimethylformamide (100 mL) was heated at 80°C for 4 h. The reaction mixture was cooled to room temperature and diluted with Et₂O (400 mL) to give a gummy red suspension. The solvent was decanted, and the residue was dissolved in MeOH:acetone (1:1, 300 mL). The solution was concentrated to dryness to a foam. The foam was triturated with acetone (2.5 L) for 5 h at room temperature. The resulting suspension was filtered and the filter cake was washed with acetone and dried in vacuo at 45°C to constant weight to give 16.1 g (56%) of solid; mp (uncorrected) 169-172°C. The proton NMR spectrum was consistent with the proposed structure.

Elemental analysis:	C	H	N	S	Br
Calc.	50.44	4.21	12.19	11.16	13.91
Obs.	50.27	4.47	12.02	11.13	13.97

EXAMPLE 2

Pyrimidinium, 1-methyl-2-[2-[[[[5-(dimethylamino)-1-naphthalenyl]sulfonyl]amino]ethyl]thio]-, bromide



Pyrimidine, 1,2-dihydro-1-methyl-2-thio-

To a stirred mixture of 1-methyl-2-thiourea (76.6 g, 0.850 mol) and malonaldehyde bis(dimethyl acetal) (126.8 g, 0.7722 mol) in EtOH (1.5 L) was added 10M HCl (76.6 mL, 0.766 mol) in one portion. The resulting mixture was stirred at 25°C for 18 h, then spin-evaporated in vacuo. The residue was dissolved in H₂O (1.5 L). The solution was made alkaline by the portionwise addition of K₂CO₃ (60 g), then extracted with CH₂Cl₂ (3 x 1.0 L). The combined extracts were dried over MgSO₄ (20 g) and spin-evaporated in vacuo to give 100.6 g (103.3%) of crude product as a solid. This was combined with 24.5 g of previously obtained material and

dissolved in refluxing EtOH (900 mL). The solution was stored at 3°C for 18 h. The resulting precipitate was collected by filtration and dried to constant weight in vacuo to give 30.0 g (24.0% recovery) of purified product.

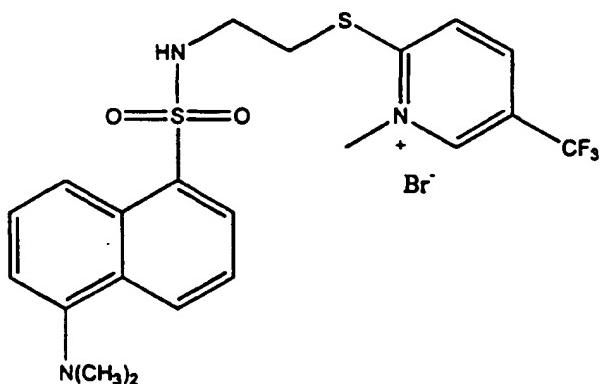
Pyrimidinium, 1-methyl-2-[2-[2-[5-(dimethylamino)-1-naphthalenyl]sulfonyl]amino]ethyl]-, bromide

A stirred mixture of the preceding intermediate (10.0 g, 79.3 mmol) and naphthalenesulfonamide, 5-(dimethylamino)-N-(2-bromoethyl)- (28.3 g, 79.3 mmol) in 1-propanol (150 mL) was heated at reflux for 2 h. The mixture was spin-evaporated in vacuo to a solid residue. The residue was triturated with acetone (200 mL), then collected by filtration and dried to constant weight in vacuo at 25°C to give 32.0 g (83.6%) of the target compound, mp 196-198°C (d) (uncorrected). Proton NMR and IR spectra were consistent with the proposed structure.

Elemental analysis:	C	H	N	S	Br
Calc.	47.20	4.79	11.59	13.27	16.53
Obs.	47.25	4.73	11.60	13.19	16.68

EXAMPLE 3

Pyridinium, 1-methyl-5-(trifluoromethyl)-2-[2-[5-(dimethylamino)-1-naphthalenyl]sulfonyl]amino]ethyl]-, bromide



N-Methyl-5-trifluoromethylpyridone

A stirred mixture of 5-(trifluoromethyl)-2-pyridinol (34.8 g, 0.213 mmol), potassium carbonate (101 g, 0.730 mol) and iodomethane (48.7 mL, 0.783 mol) in dry acetone (750 mL) in a sealed bottle was heated at 59°C for 7 h then cooled to ambient temperature. The reaction mixture was filtered and concentrated to dryness to give a yellow solid. The crude product was purified by column chromatography (1 kg silica gel) eluted with hexanes:EtOAc (1:1) to give a

white solid. The solid was dried in vacuo at room temperature for 2 h to give 34.3 g (90% yield). Additional reactions were performed to give a total of 86.9 g of similar product.

2(1H)-Pyridinethione, 1-methyl-5-(trifluoromethyl)-

A stirred mixture of the preceding intermediate (34.3 g, 0.194 mol) and Lawesson's Reagent (39.2 g, 0.097 mol) in dry toluene (195 mL) was heated at reflux for 10 min, then the toluene was removed by evaporation. The residue was distilled in vacuo (Kugelrohr apparatus) at 120-140°C/3 mm Hg to give pure product as a yellow solid (36.2 g, 96%). Additional reactions were performed to give a total of 89.9 g of similar material.

Pyridinium, 1-methyl-5-(trifluoromethyl)-2-[2-[[[[5-(dimethylamino)-1-naphthalenyl]sulfonyl]aminoethyl]-thio]-, bromide.

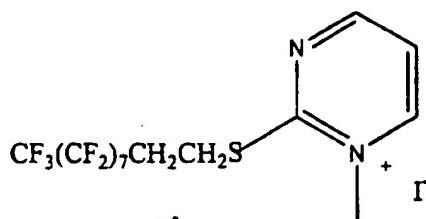
A stirred mixture of the preceding intermediate (46.7 g, 0.242 mol) and naphthalenylsulfonamide, 5-(dimethylamino)-N-(2-bromoethyl)- (86.3 g, 0.242 mol) in dry 1-propanol (270 mL) was refluxed for 4.5 h. The reaction mixture was concentrated to give the crude product as a yellow foam. This foam was dissolved in acetone (450 mL) and slowly added to a stirring solution of hexanes:isopropyl ether (2:1, 12 L) to give a yellow precipitate. The precipitate was collected by filtration, washed with hexanes (500 mL) and dried in vacuo at 40°C. This solid was reprecipitated twice more in a similar fashion to give 92.4 g (69%) of pure target. An additional reaction was performed to give a total of 119.9 g of the target compound; m.p. 125-129 degrees C (uncorrected). Proton NMR and IR spectra were consistent with the proposed structure.

Elemental analysis:	C	H	N	S	Br
Calc.	45.82	4.21	7.63	11.65	14.52
Calc.*	45.87	4.61	7.23	11.03	13.75
Obs.	45.91	4.62	7.01	10.78	14.15

*Calc. for $C_{21}H_{22}BrF_3N_2O_2S_2 \cdot 0.1 i\text{-Pr}_2O \cdot 0.2$ acetone $\cdot 0.5 H_2O$

EXAMPLE 4

Pyrimidinium, 2-[{3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10,10-heptadecafluorodecyl}thio]-1-methyl-, iodide

2(1H)-Pyrimidinethione, 1-methyl

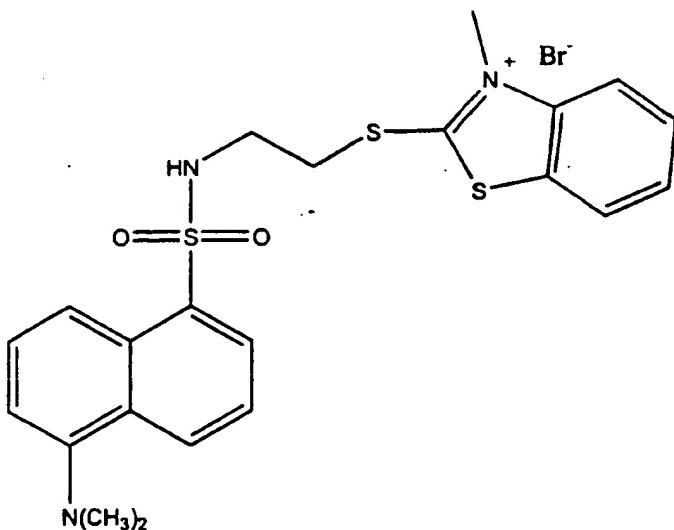
To a stirred mixture of 1-methyl-2-thiourea (76.6 g, 0.85 mol) and malonaldehyde bis(dimethyl acetal) (126.8 g, 0.77 mol) in EtOH (1.5 L) was added 10M HCl (76.6 mL, 0.77 mol) in one portion. The resulting mixture was stirred at 25°C for 18 h, then spin-evaporated in vacuo. The residue was dissolved in H₂O (1.25 L). The solution was made alkaline by the portionwise addition of K₂CO₃ and extracted with CH₂Cl₂ (4 x 500 mL). The combined extracts were dried over MgSO₄ and spin-evaporated in vacuo to a solid. The crude product was recrystallized from EtOH (600 mL) then dried to constant weight in vacuo at room temperature to give 22.9 g (23%) of product; mp 186-188°C (uncorrected). An additional reaction was performed to give a total of 40.7 g.

Pyrimidinium, 2-[{(3,3,4,4,5,5,6,6,7,7,8,8,9,9,10,10-heptadecafluorodecy)thio]-1-methyl-iodide}

A solution of the preceding intermediate (22.9 g, 0.181 mol) and 1-iodo-1H,1H,2H,2H-perfluorodecane (100.5 g, 0.175 mol) in acetone (1.2 L) was heated at reflux for 20 h, cooled to 15°C and filtered. The filter cake was washed with hexanes (500 mL) and dried in vacuo at room temperature to give 48.6 g (40% yield); mp 196-196.5°C (uncorrected). A second reaction was performed to give 11.1 g (38% yield); mp 206-206.5°C (uncorrected). The proton NMR spectrum was consistent with the proposed structure.

Elemental analysis:	C	H	N	S
Calc.	25.73	1.44	4.00	4.58
Obs.	25.68	1.47	4.05	4.56

EXAMPLE 5Benzothiazolium, 2-[[2-[[[5-(dimethylamino)-1-naphthalenyl]-sulfonv]amino] ethyl]thio]-3-methyl-, bromide



Naphthalenesulfonamide, 5-(dimethylamino)-N-(2-bromoethyl)-.

A suspension of 5-dimethylaminonaphthalene-1-sulfonyl chloride (52.5 g, 0.194 mol) and 2-bromoethylamine hydro-bromide (42.3 g, 0.206 mol) in THF (550 mL) was cooled to 2°C. A solution of triethylamine (40.3 g, 0.398 mol) in THF (230 mL) was added dropwise over a 2 h period while maintaining the internal temperature below 6°C. After complete addition the mixture was stirred at ambient temperature for 72 h. The mixture was clarified then concentrated to an orange oil which was chromatographed over silica (2.2 kg) packed and eluted with hexanes-EtOAc (3:1). Fractions (500 mL) containing the purified product were combined, clarified then concentrated to a damp solid. This material was triturated in hexanes (250 mL), collected on a filter, washed with hexanes (50 mL) then dried to constant weight in vacuo at room temperature to give 61.7 g (89% yield) of product as off-white crystalline solid.

Benzothiazolium, 2-[2-[2-[5-(dimethylamino)-1-naphthalenyl]sulfonyl]amino]ethyl]thio]-3-methyl-, bromide

A solution of naphthalenesulfonamide, 5-(dimethylamino)-N-(2-bromoethyl)- (15.0 g, 42.0 mmol) and 3-methyl-benzothiazole-2-thione (11.0 g, 60.7 mmol) in acetone (25 mL) was heated at reflux for 4 days (Note 1). After cooling to 5°C, the mixture was diluted with Et_2O (150 mL) and suction filtered. The filter cake was washed with Et_2O (200 mL) and sucked dry to give the crude product. The crude product was dissolved in a mixture of CH_2Cl_2 (140 mL) and MeOH (30 mL) then diluted with EtOAc:hexanes (1:2, 750 mL). The suspension was suction filtered and the filter cake was washed with Et_2O (200 mL), then dried in vacuo at room temperature for 4 h to give the target compound (9.0 g, 40%) as a yellow solid. An additional

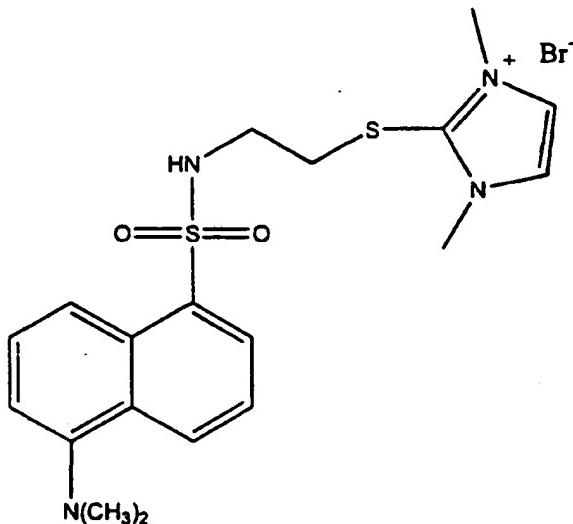
reaction was performed to give a total of 22.9 g of target compound, mp(uncorrected) 156-159°C.

Proton NMR and IR spectra were consistent with the proposed structure.

Elemental analysis:	C	H	N	S	Br
Calc.	49.06	4.49	7.80	17.86	14.84
Obs.	49.01	4.33	7.69	17.68	15.02

EXAMPLE 6

1*H*-Imidazolium, 1,3-dimethyl-2-[2-[[[S-(dimethylamino)-1-naphthalenyl]sulfonyl]amino]ethyl]thio]-, iodide



Naphthalenesulfonamide, 5-(dimethylamino)-N-(2-bromo-ethyl)-

A suspension of 5-dimethylaminonaphthalene-1-sulfonyl chloride (50.0 g, 0.185 mol) and 2-bromoethylamine hydro-bromide (40.4 g, 0.197 mol) in THF (500 mL) was cooled to 2°C. A solution of triethylamine (38.5 g, 0.380 mol) in THF (250 mL) was added dropwise over a 2 h period while maintaining the internal temperature below 6°C. After complete addition the mixture was stirred at ambient temperature for 17 h. The mixture was clarified, and the filter cake rinsed with THF to remove all of the product. The combined filtrates were concentrated to an orange oil which was chromatographed over silica (2.2 kg) packed and eluted with hexanes-EtOAc (3:1). Fractions (500 mL) containing the purified product were combined, clarified, then concentrated to a damp solid. This material was triturated in hexanes (250 mL), collected on a filter, washed with hexanes (50 mL) then dried to constant weight in vacuo at 40°C to give 56.9 g (86.1% yield) of product as an off-white crystalline solid.

1*H*-Imidazole, 1-methyl-2-[2-[[[5-(dimethylamino)-1-naphthalenyl]sulfonyl]amino]ethyl] thio]-

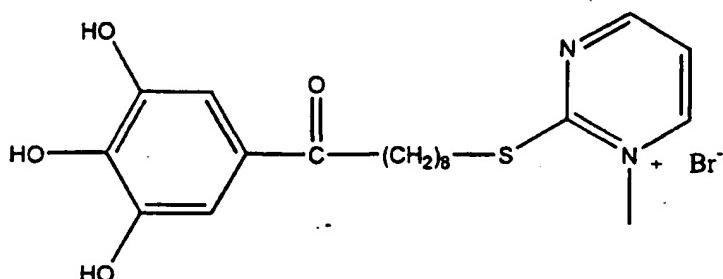
A suspension of sodium hydride (2.1 g of 60%, 52 mmol) in DMF (25 mL) was cooled to 10°C. A solution of 2-mercaptop-1-methylimidazole (6.0 g, 52 mmol) in DMF (50 mL) was added dropwise over a 30 min period while maintaining the internal temperature below 15°C. After complete addition, the reaction mixture was stirred at ambient temperature for 1.5 h. A solution of the preceding intermediate (18.7 g, 52.3 mmol) in DMF (75 mL) was added in one portion and the resulting solution was stirred at 50°C for 1.5 h then cooled to ambient temperature. The reaction solution was poured over cold H₂O (3 L) then extracted with CH₂Cl₂ (1 x 1 L and 1 x 500 mL). The combined extracts were washed with H₂O (750 mL) and saturated brine (750 mL), dried over Na₂SO₄, clarified, then concentrated in vacuo to a green oil. This material was combined with similar material from a smaller reaction and passed through a pad of silica (750 g) packed with EtOAc-hexanes (1:1) then eluted with 1:1, 6 L; 2:1, 3 L; 3:1, 4 L and finally EtOAc, 3 L. Fractions containing the purified product were combined, clarified then concentrated to a green glass which was triturated in THF (50 mL). The resulting solid was dried to constant weight in vacuo to give 23.6 g (93% yield) of material as a light green solid.

1*H*-Imidazolium, 1,3-dimethyl-2-[2-[[[5-(dimethylamino)-1-naphthalenyl]sulfonyl]amino]ethyl]thio]-, iodide

A solution of the preceding intermediate (23.6 g, 60.4 mmol), DMF (51 mL) and iodomethane (3.76 mL, 60.4 mmol) was stirred in a flask sealed with a rubber septum for 18 h at ambient temperature. The reaction solution was diluted with Et₂O (1.5 L) and vigorously stirred for 30 min. The resulting solid was collected on a filter, washed with Et₂O (2 x 50 mL) then dried in situ. This material was dissolved in CH₂Cl₂ (300 mL) and MeOH (15 mL), clarified, diluted with EtOAc (300 mL), then concentrated to a thick slurry. The resulting solid was collected on a filter, washed with EtOAc (2 x 75 mL), then dried to constant weight in vacuo to give 27.0 g (71% yield) of product, mp(uncorrected) 184-186 degrees C. Proton NMR and IR spectra were consistent with the proposed structure.

Elemental analysis:	C	H	N	S
Calc.	42.86	4.73	10.52	12.04
Obs.	42.89	4.73	10.54	12.20

EXAMPLE 7Pyrimidinium, 1-methyl-2-[[8-[(3,4,5-trihydroxybenzoyl)-oxy]octyl]thio]-, bromide



8-Bromo-octyl gallate

A suspension of gallic acid (23.5 g, 0.138 mol), 8-bromo-1-octanol (90.0 g, 0.430 mol), and conc. sulfuric acid (3.0 mL) was stirred and heated at 120-130°C for 0.5 h, then cooled to 100°C and stirred at 100°C for 1 h. Cooled to room temperature, diluted with EtOAc (300 mL), and washed with H₂O (2 x 200 mL) and brine (200 mL). The organic layer was dried (MgSO₄), filtered, and concentrated to give the crude product (111 g). The crude material was purified by column chromatography (2.2 kg silica gel eluted with EtOAc:hexanes (2:3)) to give 33.3 g (67%) as a white pasty solid.

2(1H)-Pyrimidinethione, 1-methyl-

To a stirred mixture of 1-methyl-2-thiourea (76.6 g, 0.85 mol) and malonaldehyde bis(dimethyl acetal) (126.8 g, 0.77 mol) in EtOH (1.5 L) was added 10M HCl (76.6 mL, 0.77 mol) in one portion. The resulting mixture was stirred at 25°C for 18 h, then spin-evaporated in vacuo. The residue was dissolved in H₂O (1.25 L). The solution was made alkaline by the portionwise addition of K₂CO₃ and extracted with CH₂Cl₂ (4 x 500 mL). The combined extracts were dried over MgSO₄ and spin-evaporated in vacuo to a solid. The crude product was recrystallized from EtOH (600 mL) then dried to constant weight in vacuo at room temperature to give 22.9 g (23%) of product; mp 186-188°C (uncorrected). An additional reaction was performed to give a total of 40.7 g.

Pyrimidinium, 1-methyl-2-[[8-[(3,4,5-trihydroxybenzoyl)-oxy]octyl]thio]-, bromide

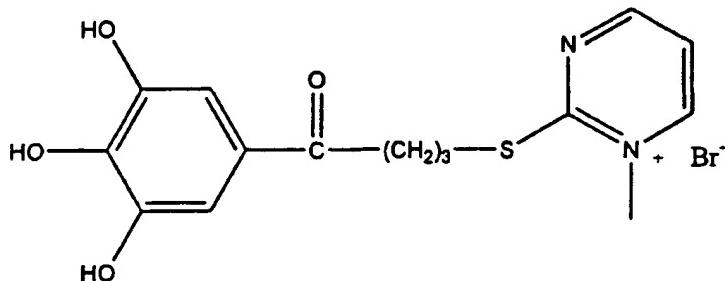
To a solution of 8-bromo-octyl gallate (33.3 g, 0.092 mol) in 1-propanol (170 mL) was added the above intermediate (11.7 g, 0.093 mol), and the resulting suspension was heated at reflux (97°C) for 1.5 h (a solution was obtained at 90°C). The hot solution was cooled to 20°C to give a suspension. The suspension was diluted with EtOAc (1.0 L) and suction filtered. The filter cake was washed with EtOAc (400 mL) and air dried. The crude product (42.4 g of yellow solid) was triturated in acetone (3.0 L) at room temperature for 20 h. The suspension was suction filtered; the filter cake was washed with acetone (50 mL) and dried to constant weight in vacuo at

35°C to give 25.4 g (57%) as a light yell w solid; mp 141-143°C (dec) (uncorrected). The proton NMR spectrum was consistent with the proposed structure.

Elemental analysis:	C	H	N	S	Br
Calc.	49.28	5.58	5.75	6.58	16.39
Obs.	49.21	5.53	5.79	6.50	16.32

EXAMPLE 8

Pyrimidinium, 1-methyl-2-[{[3-(3,4,5-trihydroxybenzoyl)-oxy]propyl}thio]-, bromide



3-Bromopropyl gallate

A suspension of gallic acid (40.0 g, 0.235 mol), 3-bromo-1-propanol (100 g, 0.719 mol), and conc. sulfuric acid (3.0 mL) was stirred and heated at 115-120°C until a solution was obtained (10-20 min), then cooled to 100°C and stirred at 100°C for 3 h. Cooled to room temperature, diluted with EtOAc (500 mL), and washed with H₂O (250 mL), 20% NaHCO₃ (2 x 250 mL), and brine (250 mL). The organic layer was dried (MgSO₄), filtered, and concentrated to give the crude product (137 g). The crude material was purified by column chromatography (2.2 kg silica gel eluted with EtOAc:hexanes (1:1)) to give 65.1 g (95%) as a cream-colored pasty solid.

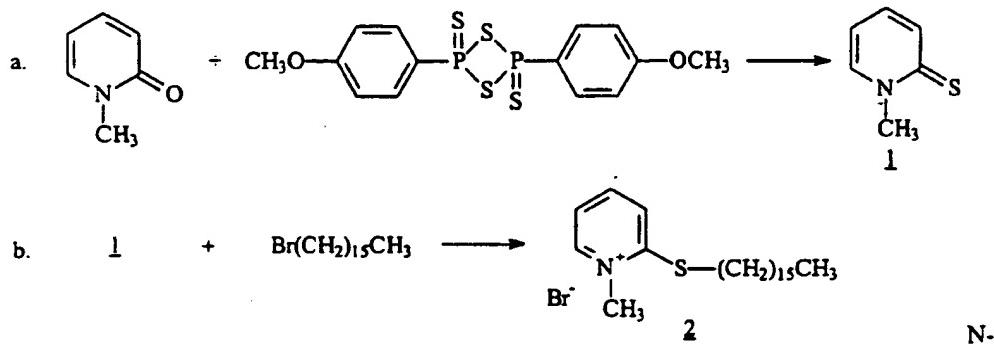
2(1*H*)-Pyrimidinethione, 1-methyl-

To a stirred mixture of 1-methyl-2-thiourea (573.8 g, 6.365 mol) and malonaldehyde bis(dimethylacetal) (949.6 g, 5.783 mol) in EtOH (11.3 L) was added 10M HCl (575 mL, 5.75 mol) in one portion. The resulting mixture was stirred at 25°C for 18 h then concentrated in vacuo. The residue was dissolved in H₂O (11.1 L) and the solution was made alkaline by portionwise addition of K₂CO₃ (448 g). The alkaline solution was extracted with CH₂Cl₂ (3 x 7.2 L) and the combined extracts were dried (MgSO₄), filtered, and concentrated to give the crude product. The crude product was dissolved in refluxing EtOH (4.0 L) and stored at 3°C for 18 h. The resulting precipitate was collected by suction filtration and dried to constant weight in vacuo at 40°C to give 94.1 g (12.9%) as a yellow solid.

Pyrimidinium, 1-methyl-2-[{3-{[(3,4,5-trihydroxybenzoyl)-oxy]propyl}thio]-, bromide}

To a solution of 3-br mopropyl gallate (54.9 g, 0.19 mol) in 1-propanol (350 mL) was added the preceding intermediate (23.8 g, 0.19 mol), and the resulting suspension was heated at reflux (97°C) for 0.5 h (a solution was obtained at 90°C, then after a few minutes at reflux a precipitate began to fall out of solution). The hot suspension was suction filtered, and the filter cake was washed with 1-propanol (4 x 75 mL) and dried to constant weight in vacuo at 35°C to give 33.5 g (42%) as a light yellow solid; mp 223-225°C (dec) (uncorrected). The proton NMR spectrum was consistent with the proposed structure.

Elemental analysis:	C	H	N	S	Br
Calc.	43.18	4.11	6.71	7.68	19.15
Obs.	42.91	4.14	6.68	7.63	19.15

EXAMPLE 9Pyridinium, 1-methyl-2-[{(hexadecyl)thio]-, bromide}Methyl-2-thiopyridone (1)

A stirred mixture of 1-methyl-2-pyridone (20.0 g, 183 mmol) and Lawesson's Reagent (37.0 g, 91.5 mmol) in dry toluene (100 mL) was heated at reflux for 15 min. then the toluene was removed by evaporation in vacuo at 60°C. The residue was distilled in vacuo to give crude product; bp, 175-177°C (13 torr). This yellow liquid was dissolved in MeOH (15 mL), and the solution was cooled to 0°C with stirring. The precipitated solid was collected by filtration, rinsed with hexanes (2 x 40 mL) and dried to constant weight in vacuo to give 14.0 g (61%) of material suitable for further transformation. One additional reaction was performed to furnish another 27.7 g lot of similarly pure intermediate.

Pyridinium, 1-methyl-2-[{(hexadecyl)thio]-, bromide (2)}

A stirred mixture of the preceding intermediate (11.1 g, 88.7 mmol) and 1-bromohexadecane (27.1 g, 88.8 mmol) in 1-PrOH (100 mL) was heated at reflux for 3.5 h then

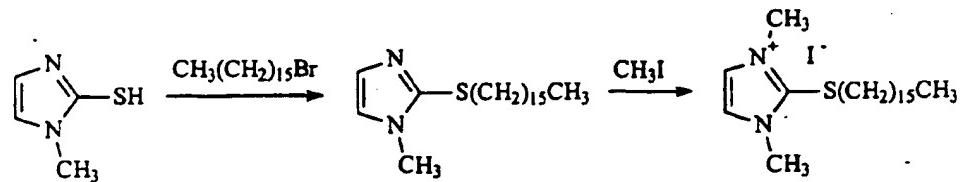
clarified by filtration and stored at 3°C for 18 h. The resulting crystalline precipitate was collected by filtration, rinsed with EtOH (3 x 15 mL) followed by Et₂O (2 x 50 mL), then dried to constant weight in vacuo at 60°C to give 31.1 g (81%) of purified product. One additional reaction was performed to give another 66.7 g lot of purified material. The two lots were thoroughly blended to give a total of 97.8 g of product as a white solid; mp(uncorrected) 111-114 degrees C. Proton NMR and IR spectra were consistent with the proposed structure.

Elemental analysis:	C	H	N	S	Br
Calc.	61.37	9.37	3.25	7.45	18.56
Obs.	61.46	9.32	3.23	7.40	18.65

EXAMPLE 10

1*H*-Imidazolium, 1,3-dimethyl-2-(hexadecylthio)-, iodide

Reaction sequence:



To a stirred solution of 2-mercaptop-1-methylimidazole (36.3 g, 318 mmol) in dry DMF (250 ml) was added NaH (12.7 g, 60% in mineral oil, 318 mmol) in portions over 0.5 h. The resulting solution was stirred for an additional 1 h, then hexadecyl bromide (100g, 97%, 318 mmol) was added in one portion. The reaction mixture was heated for 1 h with stirring at 50°C, then cooled and added to stirred ice-H₂O (1.5 L). The resulting biphasic mixture was extracted with hexanes (2 x 500 mL). The combined hexane extracts were dried over Na₂SO₄ (25 g), then clarified and treated, in one portion, with MeI (100g, 705 mmol). The stirred mixture was heated at reflux for 1.0 h then cooled to room temperature. The precipitated solid was collected by filtration and dissolved in CHCl₃ (1.0 L). The resulting solution was clarified, diluted with hexanes (1.0 L) then concentrated in vacuo at 40°C to a volume of approximately 1.0 L. The resulting precipitate was collected by filtration and dried to constant weight in vacuo at 40°C to give 80.9 g (53%) of purified product; mp, 124-126°C (corrected).

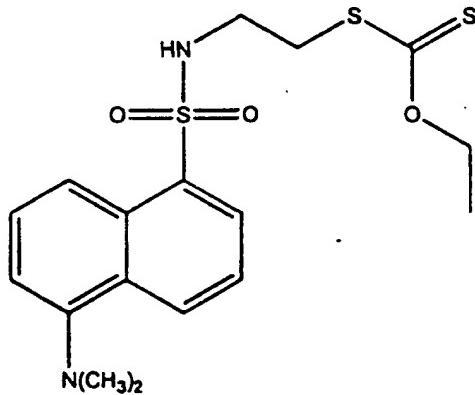
Elemental analysis:	C	H	N	S	I
Calc.	52.49	8.60	5.83	6.67	26.41
Obs.	52.63	8.60	5.75	6.59	26.28

sp² CARBON PROTECTING GROUPS

The sp² protected thiol compounds of the present invention can be prepared by any of a number of procedures known to those skilled in the art.

For example, the thiocarboxylic acid derivatives can be prepared by reacting acyl chlorides with H₂S or alkylthiols. The carbamothioic acid derivatives can be prepared via hydrolysis of thiocyanates. The dithiocarboxylic acid derivatives can be prepared by treating carboxylic acids with P₄S₁₀ and a primary alcohol. The carbonodithioic acid derivatives can be prepared by the addition of alcohols to carbon disulfide in the presence of base to form a salt of the acid and by imparting an alkyl halide to the reaction mixture to form the ester. The carbamodithioic acid derivatives can be prepared by the addition of primary or secondary amines to carbon disulfide.

The following non-limiting examples illustrate exemplary methods of preparing a few compounds of the invention.

EXAMPLE 11**1-Naphthalenesulfonamide, 5-(dimethylamino)-N-[2-[[2-(ethoxy)thioxomethyl]thio] ethyl]-****Naphthalenesulfonamide, 5-(dimethylamino)-N-(2-bromoethyl))**

A suspension of 5-dimethylaminonaphthalene-1-sulfonyl chloride (50.0 g, 0.185 mol) and 2-bromoethylamine hydro-bromide (40.4 g, 0.197 mol) in THF (500 mL) was cooled to 2°C. A solution of triethylamine (38.5 g, 0.380 mol) in THF (250 mL) was added dropwise over a 2 h period while maintaining the internal temperature below 6°C. After complete addition the mixture was stirred at ambient temperature for 17 h. The mixture was clarified then concentrated to an orange oil which was chromatographed over silica (2.2 kg) packed and eluted with hexanes-EtOAc (3:1). Fractions (500 mL) containing the purified product were combined, clarified, then concentrated to a damp solid. This material was triturated in hexanes (250 mL), collected on a

filter, washed with hexanes (50 mL) then dried to constant weight in vacuo at 40°C to give 56.9 g (86.1% yield) of product as a off-white crystalline solid.

1-Naphthalenesulfonamide, 5-(dimethylamino)-N-[2-[(ethoxy)-thioxomethyl]thio]ethyl]-

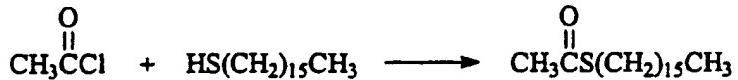
A mixture of the preceding intermediate (43.3 g, 121 mmol) and O-ethylxanthic acid, potassium salt (19.7 g, 123 mmol) in anhydrous acetone (430 mL) was heated at reflux for 18 h. The mixture was cooled to ambient temperature, clarified, and the filtrate was concentrated in vacuo to an oil. This material was chromatographed over silica gel (1 kg) packed and eluted with hexanes-EtOAc (3:1). Fractions containing the purified product were combined, clarified, then concentrated to a thick slurry which was diluted with hexanes (200 mL). The resulting solid was collected on a filter, rinsed with hexanes (2 x 75 mL), then dried to constant weight in vacuo to give 19.1 g of product. The mixed fractions from this column were combined, concentrated, then rechromatographed over silica gel (2.0 kg) packed and eluted with hexanes-EtOAc (3:1). Fractions containing the purified product were combined, clarified, then concentrated in vacuo to a thick oil. This was dissolved in CH₂Cl₂ (50 mL), diluted with hexanes (200 mL), then cold evaporated to a thick slurry. The resulting solid was collected on a filter, washed with hexanes (100 mL), then dried to constant weight in vacuo to give 18.9 g of product. A second crop of material was obtained by cold evaporating the two combined filtrates to give 0.5 g of product (total yield 38.5 g, 82%), mp(uncorrected) 85-86 degrees C. Proton NMR and IR spectra were consistent with the proposed structure.

	C	H	N	S
Calc.	51.23	5.56	7.03	24.13
Obs.	51.19	5.56	6.99	24.14

EXAMPLE 12

S-hexadecyl ethanethioate

Reaction sequence:



A mixture of acetyl chloride (1.0 L, 1.1. kg, 14 mol) and 1-hexadecanethiol (95%, 168 g, 0.62 mol) was stirred at reflux for 3 h, then volatile components were removed by evaporation in vacuo (60°C, 5 torr). The residue was recrystallized from warm (35°C) hexanes (500 mL) by cooling at 4°C for 18 h. The weight in vacuo to give 174.5 g (94%) of purified product; mp, 29-31°C (corrected).

Elemental analysis: C H S

Calc. 71.93 12.07 10.67;

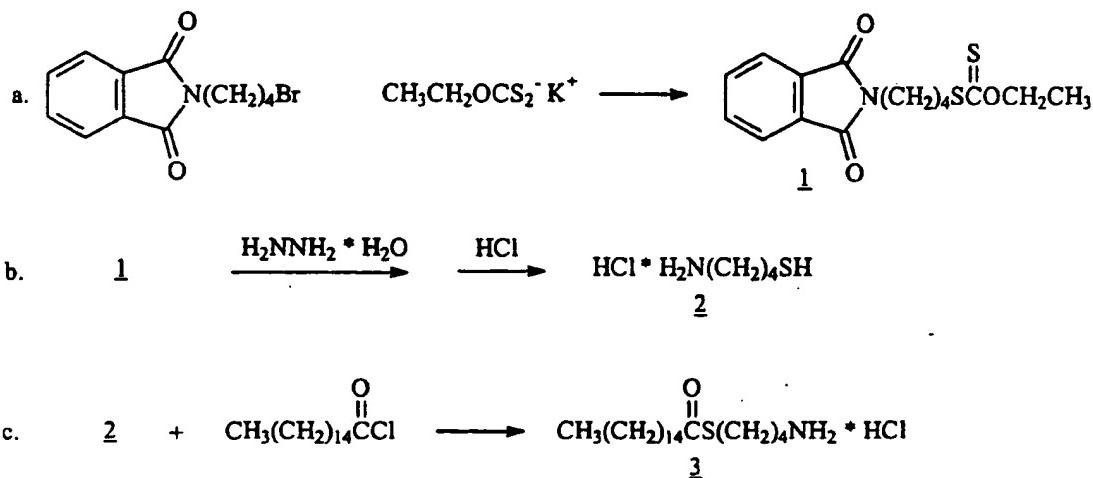
Found 72.17 12.12 10.84.

The NMR (500 MHz) and IR agreed with the proposed structure.

EXAMPLE 13

S-(4-Aminobutyl) hexadecanethioate hydrochloride

Reaction sequence:



a. (4-Phthalimidobutyl)xanthic acid, O-ethyl ester (1)

A mixture of N-(4-bromobutyl)phthalimide (138 g, 489 mmol) and O-ethylxanthic acid, potassium salt (97.7 g, 609 mmol) in DMF (400 mL) was stirred for 1 h then blended into stirred ice-H₂O (2 kg). The precipitated solid was collected by filtration, air-dried and doubly recrystallized from boiling EtOH (2 x 700 mL). The recovered solid was dried to constant weight in vacuo at 50°C to give 114.8 g (73%) of material suitable for further transformation.

b. 4-Amino-1-butanethiol hydrochloride (2)

To a solution of (1) (105.8 g, 327.4 mmol) in CH₃CN (400 mL) was added H₂NNH₂ * H₂O (47.6 mL, 49.2 g, 980 mmol). The mixture was stirred for 0.5 h at 60°C then evaporated in vacuo at 40°C to a solid residue. This material was dissolved in H₂O (450 mL) and the pH of the solution was adjusted to 2-3 with concentrated HCl. The resulting suspension was stored for 1.0 h at 0°C, then the precipitate was removed by filtration. Additional concentrated HCl (200 mL) was added to the filtrate and the yellow solution was heated at reflux for 6.0 h, during which time the evolution of COS gradually slowed to a stop. The resulting solution was evaporated in vacuo

at 60°C to a semi-solid residue. This residue was dried by azeotropic distillation with toluene (3 x 100 mL) and then extracted into CH₂Cl₂ (900 mL). Evaporation of the clarified CH₂Cl₂ extract yielded 31.4 g (68%) of the hydrochloride salt as a very pale yellow semi-solid suitable for further transformation.

c. S-(4-Aminobutyl) hexadecanethioate hydrochloride (3)

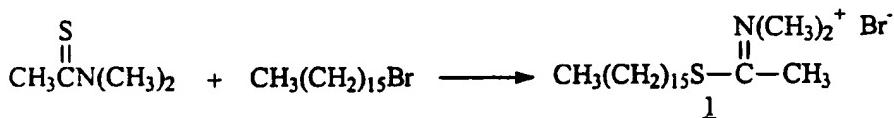
A solution of (II) (31.4 g, 222 mmol) and palmitoyl chloride (60.9 g, 222 mmol) in dry CH₃CN (400 mL) was stirred at 70°C for 2.0 h and then at 10°C for 1.0 h. The precipitated solid was collected by filtration and air-dried. This material was recrystallized from boiling EtOH (400 mL) to give a white crystalline solid which was collected by filtration, washed with Et₂O (3 x 100 mL) and dried to constant weight in vacuo at 60°C to give 52.0 g (62%) of purified product; mp, 138-141°C (corrected).

Elemental analysis: C H Cl N S
 Calc. 63.20 11.14, 9.33 3.69 8.44;
 Found 63.32 11.16 9.22 3.71 8.37.

The NMR (500 MHz) and IR agreed with the proposed structure.

EXAMPLE 14

Methanaminium, N-methyl-N-[1-(hexadecylthio)ethylidene]-, bromide



To a stirring solution of N,N-dimethylthioacetamide (33.8 g, 0.33 mol) in acetonitrile (300 mL) was added 97% 1-bromohexadecane (103.1 g, 0.33 mol) and tetrahydrofuran (200 mL), to give a complete solution. The mixture was heated at reflux for 72 h. After cooling to 10°C, the suspension was suction filtered, and the filter cake was washed with Et₂O (500 mL). The white solid was dried in vacuo at room temperature for 6 h to give 68.2 g (51%) of target compound as a white solid; mp 80-92°C (uncorrected). Proton NMR and IR spectra were consistent with the proposed structure.

Elemental analysis: C H N S Br
 Calc. 58.80 10.36 3.43 7.85 19.56
 Obs. 58.56 10.43 3.41 7.76 19.60

sp³ Carbon Protecting Groups

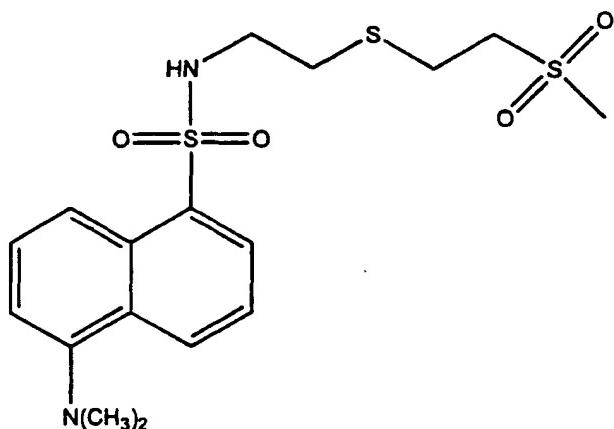
The compounds of the invention can be prepared by any of a number of procedures known to those skilled in the art.

For example, the thioether compounds can be prepared by the treatment of a suitable alkyl halide with a thiol. The thioacetal and dithioacetal compounds can be prepared by the treatment of suitable aldehydes and ketones with a thiol. The compounds capable of undergoing heterolytic β -elimination can be prepared via nucleophilic addition of a thiol onto a suitable activated olefin in a Michael-type addition reaction.

The following non-limiting examples illustrate exemplary methods of preparing a few compounds of the invention.

EXAMPLE 15

1-Naphthalenesulfonamide, 5-(dimethylamino)-N-[2-[[2-(methylsulfonyl)ethyl]thio]ethyl]-



To a stirred suspension of 2-(methylsulfonyl)ethanethiol (17.5 g, 0.12 mol) and 5-(dimethylamino)-N-(2-bromoethyl)-1-naphthalenesulfonamide (43.8 g, 0.12 mol) in acetone (1.8 L) was added anhydrous potassium carbonate (19.6 g, 0.142 mol) at room temperature under argon. The reaction mixture was refluxed for 1 h, then additional potassium carbonate (58.5 g, 0.42 mol) and acetone (50 mL) were added followed by continued reflux for 1.5 h. The reaction mixture was cooled to room temperature, then poured into stirred water (8 L) and extracted with EtOAc (2 x 4 L). The combined EtOAc extracts were washed with water (1 x 4 L) then washed with brine (1 x 4 L) and dried over magnesium sulfate. The clear EtOAc extract was concentrated to give crude product. The crude product was chromatographed on silica gel (2.2 kg) with EtOAc:hexanes 1:1 (12 L) and 4:1 (8L). Appropriate fractions were combined, filtered and concentrated to give 47.6 g (93.7 % yield) of product as a viscous oil. Proton NMR and IR spectra were consistent with the proposed structure.

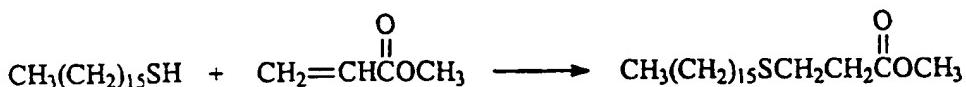
Elemental analysis:	C	H	N	S
Calc.	49.01	5.81	6.72	23.09
Calc.*	49.34	6.01	6.32	21.71
Obs.	49.52	5.98	6.41	21.96

*Calc. for C₁₇H₂₄N₂O₄S, . 0.3 EtOAc

EXAMPLE 16

Methyl 3-(Hexadecylthio)propanoate

Reaction Sequence:



Hexadecyl mercaptan (95%, 180 g, 661 mmol) was added, dropwise over 0.5 h, to a stirred mixture of methyl acrylate (60.0 g, 697 mmol) and benzyltrimethylammonium hydroxide (40 wt.% in methanol, 400 mg, 1.0 mmol). The resulting warm (~60°C) solution was stirred for one additional hour then volatiles were removed in vacuo at 90°C. The resulting oil was recrystallized from warm (~40°C) hexanes (500 ml), cooled to -30°C, collected by filtration and dried to constant weight in vacuo at room temperature to give 222.3 g (98%) of purified product; mp, 38-39°C (corrected).

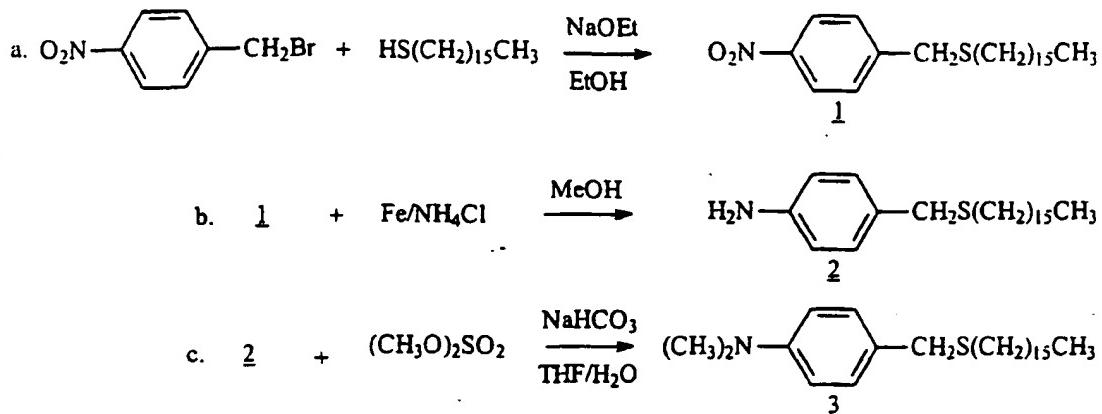
Elemental analysis:	C	H	S
Calc.	69.71	11.70	9.30;
Found	69.78	11.54	9.26.

The ¹H NMR and IR agree with the proposed structure.

EXAMPLE 17

4-[(Hexadecylthio)methyl]-N,N-dimethylbenzenamine

Reaction Sequence:



a. 4-[Hexadecylthio)methyl]-1-nitrobenzene (1):

A solution of 4-nitrobenzyl bromide in ethanol (150.0 g, 0.694 mol in 1.5 L) was brought to reflux. Separately, a solution of 1-hexadecanethiol in ethanol (231 mL, 0.691 mol in 1.5 L) was treated with sodium ethoxide in ethanol (258 mL, 0.691 mol of a 21% solution) over ten minutes, stirred at room temperature for 15 minutes, then warmed to dissolve the precipitate. This was then added to the benzyl bromide solution over twenty minutes, stirred at room temperature for two hours, then allowed to sit undisturbed overnight. The crystallized thioether was collected and combined with the product from a 230 mmol run. This light yellow solid was dissolved in CH₂Cl₂ (3 L), washed with water (1 L), then dried (Na₂SO₄), filtered, and spin-evaporated to give 324.5 g of 1 (89.5% yield). The material was a single spot by TLC (19:1 hexanes/EtOAc), and was suitable for further transformation.

b. 4-[Hexadecylthio)methyl]benzeneamine (2):

Ammonium chloride (152.9 g, 2.858 mol), 1 (225.0 g, 0.572 mol), water (2.8 L), methanol (3.8 L) were combined and mechanically stirred at 50°C, then powdered iron (95.9 g, 1.715 mol) was added portionwise over ten minutes. The suspension was vigorously stirred at reflux for 2.5 hours, then hot filtered through a celite pad. The pad was rinsed with water (3 x 700 mL) and CH₂Cl₂ (5 x 700 mL). The aqueous layer was extracted with CH₂Cl₂ (3 x 1 L), then concentrated to remove methanol and again extracted with CH₂Cl₂ (3 x 500 mL). The combined organics were washed with water (2 x 3L), dried (Na₂SO₄), filtered, and spin-evaporated to give 198.1 g (95.3% yield) of 2 as a pale yellow solid. TLC (7:1 hexanes/EtOAc) indicated a single spot. This lot was combined with that of a 100 mmol run to give a total of 231 g of 2 (94.3% yield) which was suitable for further transformation.

c. 4-[Hexadecylthio)methyl]-N,N-dimethylbenzeneamine (3):

A solution of sodium bicarbonate in water (168 g, 2.0 mol in 1.3 L) was added to a vigorously stirred solution of 2 in THF (181 g, 0.5 mol in 1.5 L), under argon, at 0°C. Dimethyl sulfate (165 mL, 1.75 mol) was added dropwise over 30 minutes, and stirring was continued for a total of 20 h. The ice bath was removed after the first hour. The reaction was followed by TLC (9:1 hexanes/EtOAc), and initially showed mono-methylated material at $R_f = 0.56$. After 20 h, concentrated NH₄OH (300 mL) was added and stirred for 15 minutes, then EtOAc and brine (1 L each) were added and the layers were separated. The aqueous portion was saturated with solid NaCl, extracted with EtOAc (5 x 500 mL), and discarded. The combined organics were washed with brine (500 mL), dried (Na₂SO₄), and spin-evaporated to a yellow oil. A similar reaction was done previously on 137.7 mmol of 2. The combined lots were dissolved in CH₂Cl₂, then eluted from a silica gel pad with CH₂Cl₂. The eluent was spin-evaporated to give 160.1 g of 3 as an oil, which was purified by chromatography (1.8 kg SiO₂ eluted with 39:1 hexanes/EtOAc) to give 91.1 g of 3. This material was recrystallized from ethanol containing 1% water, then dried in vacuo at room temperature to give 57.9 g (23.3% yield) of pure 3; m.p. 41–43°C.

Elemental analysis: C H N S

Calc. 76.66 11.58 3.57, 8.19;

Found 76.37 11.63 3.61 8.43.

The ¹H NMR, ¹³C NMR, and IR agree with the proposed structure.

EXAMPLE 18

1,3,5-Cycloheptatriene, 7-(hexadecylthio)-

Tropylium tetrafluoroborate (10.0 g, 0.056 mol) was ground and placed in a reaction flask with MeOH (100.0 mL). This suspension was stirred under argon for 10 min at room temperature, and then n-hexadecanethiol, (90%) (15.0 g, 0.052 mol) was added over 5 min. The reaction mixture (suspension) was stirred for 2 h. At this point, TLC showed only a small amount of unreacted thiol. To the reaction mixture was added NaHCO₃ (8 g, 0.095 mol) followed by stirring for 15 min. and filtration through a small pad of silica gel (~20 g) with elution by hexanes (200 mL). The solution was evaporated (bath temp ~30°C) to give an oil which was purified by column chromatography with silica gel (100 g) eluting with hexanes to give 17.2 g (95%) as a colorless oil. Additional reactions were performed to give a total of 58.1 g of target compound. Proton NMR and IR spectra were consistent with the proposed structure.

Elemental analysis: C H S

Calc. 79.24 11.56 9.20

Obs. 78.63 11.85 9.43

Metal Based Protecting Groups

The metal mercaptides of the present invention can be prepared by a number of methods known to those who are skilled in the art.

R-S-Met-X_n can be made by reactions of the type:



e.g., for Ti and Zr.

R-S-Met(M)_mX_n can be made by reactions of the type:

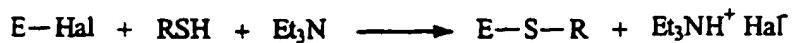


e.g., for V and Bi.

Furthermore, metal mercaptides of the present invention can be made via the addition of the cosmetic thiol to a solution of salts of heavy metals. This can be accomplished by adding the thiol to an aqueous, hydroalcoholic or alcoholic solution of a salt of the metal. The formed mercaptides of the heavy metals may then precipitate. The precipitated mercaptide can then be filtered and washed with an aqueous, hydro-alcoholic or alcoholic solution containing some of the thiol to prevent hydrolysis [E. Reid, Organic Chemistry of Bivalent Sulfur, Volume I, 1958].

Non-metal and metalloid based Protecting Groups

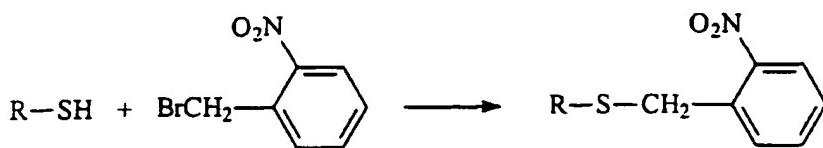
Thiol derivatives of non-metals and metalloids can be prepared from their halides in the presence of a hydrogen halide acceptor hydrogen halide acceptor or by using a metal thiolate, such as lead, where Et represents an ethyl group, Pb is lead, and the other symbols are as defined above [M. E. Peach, "Thiols as Nucleophiles", in The Chemistry of the Thiol Group, 1974, John Wiley and Sons, pp. 747.]:



Energy Sensitive Protecting Groups

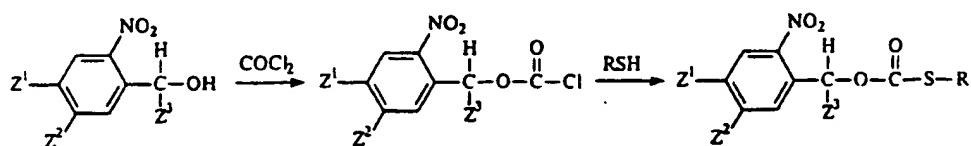
L. 2-Nitrobenzyl derivatives

The 2-nitrobenzyl derivatives can be prepared by reaction of the corresponding 2-nitrobenzyl halide with a thiol in the presence of a base:



II. 2-Nitrobenzyloxycarbonyl Derivatives

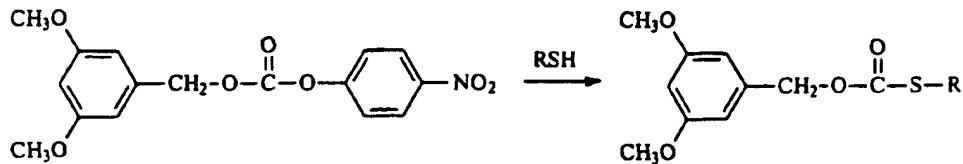
The 2-nitrobenzyloxycarbonyl derivatives can be prepared by the reaction of phosgene with the corresponding alcohol, i.e., 2-nitrobenzyl alcohol, 6-nitroveratryl alcohol, 2-nitrobenzhydrol, and 2,2'-dinitrodiphenylmethanol. The resulting acyl chloride can then be reacted with a thiol to yield the corresponding 2-nitrobenzyloxycarbonyl derivative:



where Z^1 and Z^2 are H, or OCH_3 , and Z^3 is H, C_6H_5 , or $o\text{-O}_2\text{N-C}_6\text{H}_4$.

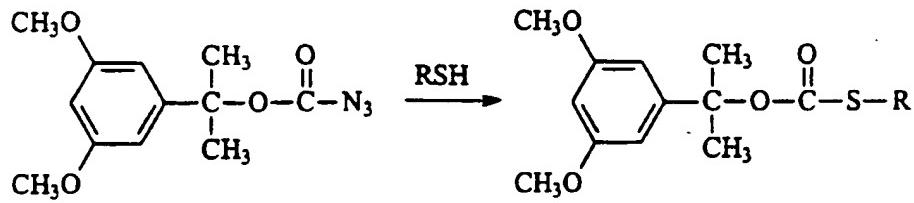
III. Benzylloxycarbonyl Derivatives

The 3,5-dimethoxybenzyloxycarbonyl group can be introduced by reacting 3,5-dimethoxybenzyl *p*-nitrophenyl carbonate with a thiol:



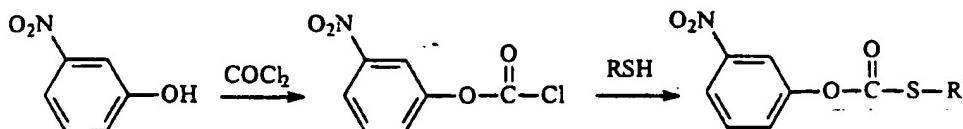
IV. α,α -Dimethylbenzyloxycarbonyl Derivatives

The α,α -dimethyl-3,5-dimethoxybenzyloxycarbonyl compounds can be prepared by the reaction of α,α -dimethyl-3,5-dimethoxybenzyloxycarbonyl azide with a thiol:



V. 3-Nitrophenyloxycarbonyl Derivatives

The 3-nitrophenyloxycarbonyl compound can be prepared by reaction of 3-nitrophenol with phosgene to yield 3-nitrophenyloxycarbonyl chloride. The latter can then be reacted with a thiol:

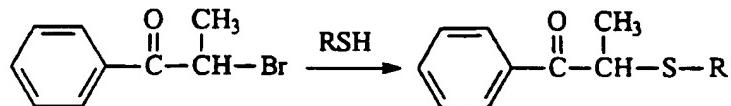


VI. Phenacyl Derivatives

The 4-methoxyphenacyl compound can be prepared by reaction of phenacyl bromide with a thiol:

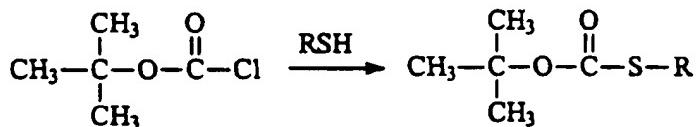


The α -methylphenacyl compound can be prepared by reaction of alpha-methylphenacyl bromide with a thiol:



VII. tert-Butyloxycarbonyl Derivatives

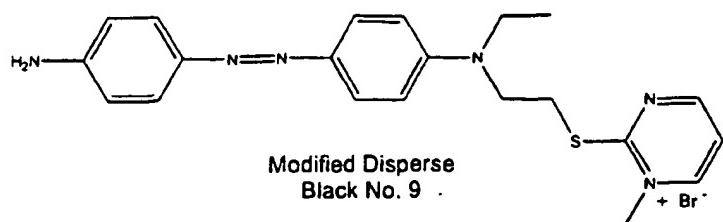
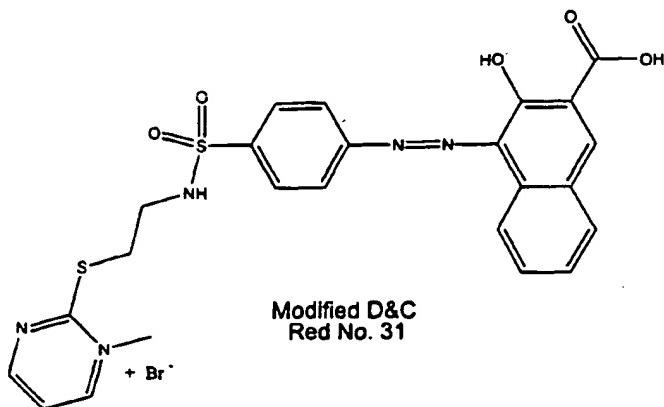
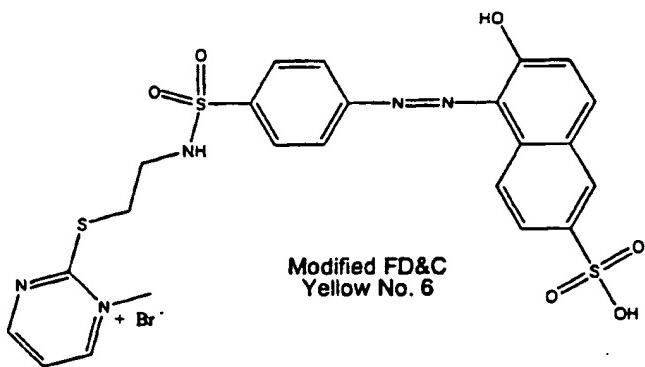
The tert-butyloxycarbonyl compound can be prepared by reaction of tert-butyloxycarbonyl chloride with a thiol:

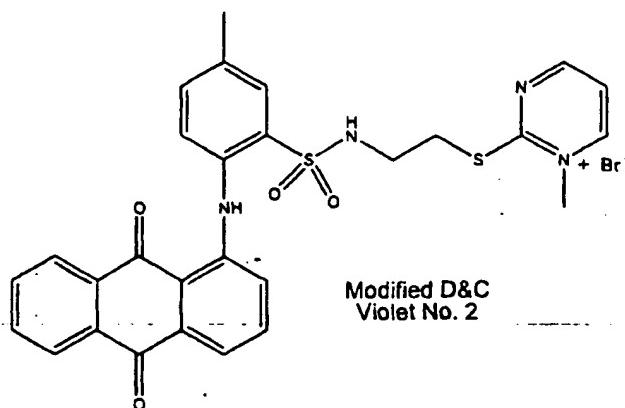
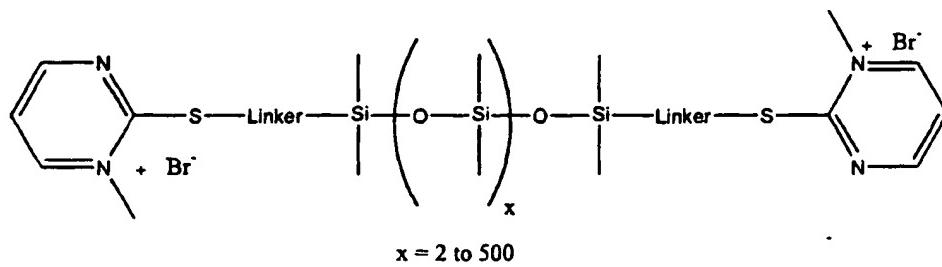
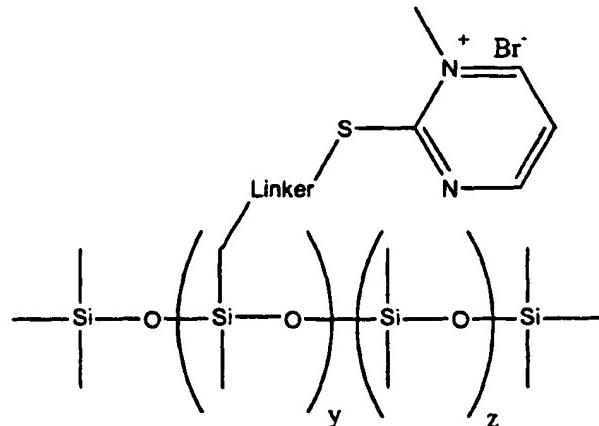


EXAMPLES OF PREFERRED MODIFIED COSMETICALLY ACTIVE AGENTS

The following are non-limiting examples of preferred cosmetically active functional group, R, and "hook" combinations for use in topical formulas:

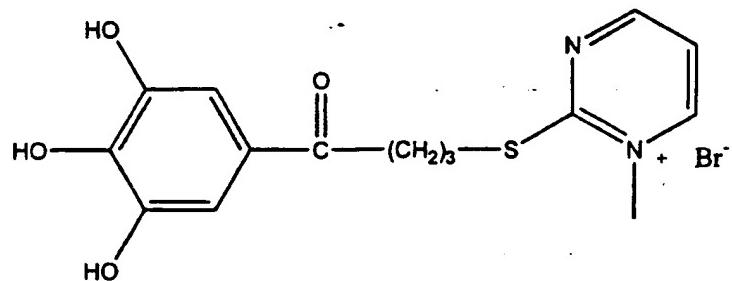
EXAMPLE 19

**EXAMPLE 20****EXAMPLE 21****EXAMPLE 22**

**EXAMPLE 23****Modified Silicone****EXAMPLE 24****Modified Silicone** $y = 1 \text{ to } 100$ $x = 2 \text{ to } 500$

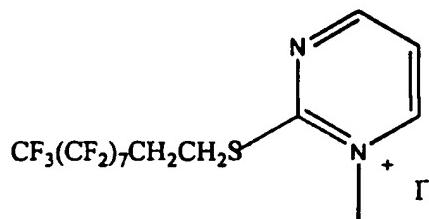
EXAMPLE 25

Modified Anti-oxidant



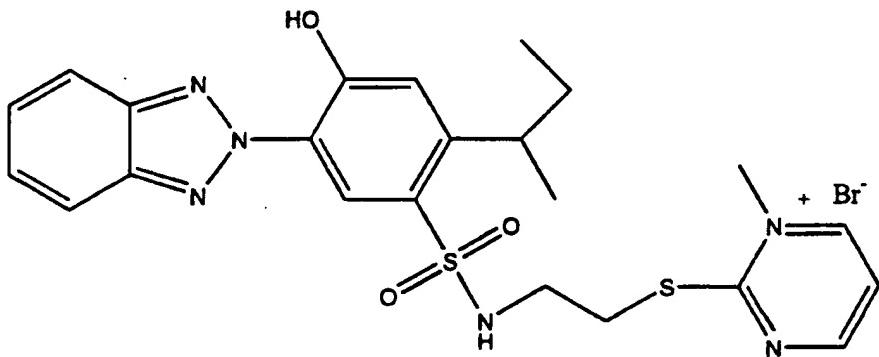
EXAMPLE 26

Modified Perfluoro Conditioner



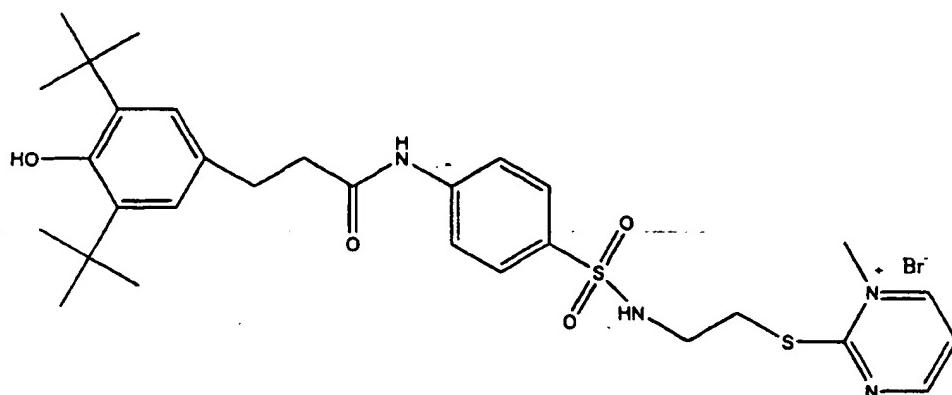
EXAMPLE 27

Modified UV Absorber

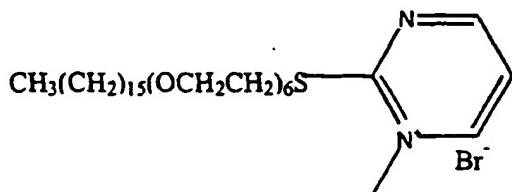


EXAMPLE 28

Modified Anti-oxidant

EXAMPLE 29

Modified Conditioner



wherein Linker represents any straight, branched or mono- or polycyclic aliphatic, mono or polyunsaturated alkyl, aryl, heteroalkyl, heteroaliphatic or heteroolefinic system including 1 to 30 carbon atoms together with 0-15 heteroatoms, especially O, N, S, P, Si, and can incorporate one or more substituents including, but not limited to, poly or perfluoro substitution.

These compounds are made by synthesis methods known in the art, including but not limited to those described above and those described in Sokolowska-Gaida, J. and Freeman, H., Dyes and Pigments (1990) Vol. 14, pp. 35-48, European Patent Application EP 0437099 A1 Published by Dow Corning Corp. (Inventors: Halloran, D. J., et al.) and the preparation section herein.

EXAMPLE 30

“Terminal” benzylchloride-substituted silicone polymer.

The hydride terminated silicone polymer HMe₂Si-(OSiMe₂)_nOSiMe₂H (35 g, 53.56 mmol, Gelest) was weighed into a 250 mL round bottom flask containing a stir bar. 2,6-di-tert-butylphenol (26 mg, 489 ppm by weight) was added followed by 51 ppm platinum in

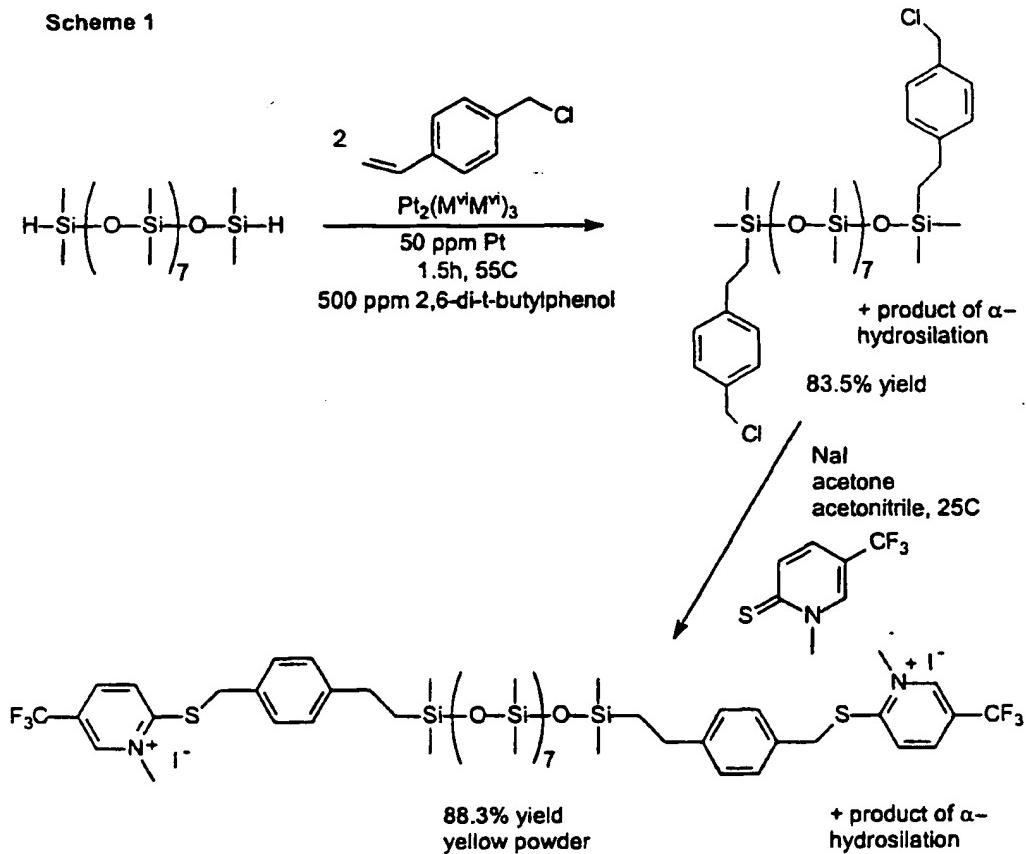
the form of Karstedt's catalyst (GE Silicones Product, 10.2% platinum by weight). The pale yellow solution was placed in a 50°C oil bath. Vinylbenzylchloride (16.8 mL, 119.2 mmol, Aldrich) was added slowly dropwise by syringe with stirring. The solution quickly became cloudy yellow and remained that way until about one minute after the addition was complete. At this time the reaction mixture turned dark brown. The mixture was stirred at 52°C for 1.5 hours after the addition was complete. The brown mixture was then washed with methanol (1/3 by volume) two times to remove excess vinylbenzylchloride. The product, a cloudy brown oil, was isolated after drying under vacuum in 83.5 % yield (42.89 g, 44.74 mmol). ¹H NMR (acetone-d₆): 7.33 (pseudo t, J = 8.0 Hz, aryl), 7.23 (pseudo d, J = 8.0 Hz, aryl), 7.13 (pseudo d, J = 8.2 Hz, aryl), 4.66 (s, 4H, CH₂Cl), 2.70 (m, 2.4H, SiCH₂CH₂Ar), 2.27 (q, J = 7.6 Hz, 0.8H, SiCH(Me)Ar), 1.38 (d, J = 7.6 Hz, 2.4H, SiCH(Me)Ar), 0.94 (m, 2.4H, SiCH₂CH₂Ar), 0.12 (s, 54H, SiMe). The aryl resonances integrate to be 8H total. This product is cloudy brown due to the presence of colloidal platinum. Alternatively, we have found that a very pale yellow product, identical by ¹H NMR spectroscopy, can be isolated when the material (mixture of hydrosilation isomers) is prepared using the heterogeneous catalyst Pt/Al₂O₃ (5% Pt). Also noteworthy is the fact that with higher molecular weight silicones, it is possible and recommended to use larger amounts of methanol in the washing step. See Scheme 1.

Pyridinium-substituted silicone polymer.

Inside a helium filled dry box, 42.89 g (44.74 mmol) of the "terminal" benzylchloride-substituted silicone polymer was added to a 250 mL round bottom flask containing a stir bar. To this was added 10 mL acetone (dried over drierite) and 35 mL anhydrous acetonitrile. Sodium iodide (13.45 g, 89.73 mmol, dried under vacuum at 110°C) was added slowly as a solid to the amber solution while sodium chloride quickly precipitated. The NaI addition was followed by 1-methyl-5-(trifluoromethyl)-2(1H)-pyridinethione (17.30 g, 89.55 mmol, prepared by Starks Associates, Buffalo, NY), added piecewise as a solid. The orange mixture was allowed to stir at room temperature for 3 days. Outside the drybox, the mixture was filtered, and the volatile materials were then removed from the solution under vacuum. The crude product was dissolved in a minimum amount of acetone (about 75 mL) forming a dark orange solution. Pentane (250 mL) was added to precipitate the product which was filtered on a frit and washed with pentane (5 x 50 mL). The product was isolated in 88% yield (59 g) as a yellow powder. ¹H NMR (acetone-d₆): 9.73 (s, 2H, pyH), 8.73 (m, 4H, pyH), 7.56 (pseudo t, J = 8 Hz, phenyl), 7.29 (pseudo d, J = 8Hz, phenyl), 7.20 (pseudo d, J = 8Hz, phenyl), (the three phenyl resonances integrate to 8H total), 5.03 (s, 4H, CH₂S), 4.49 (s, 6H, NMe), 2.71 (m, 2.4H, SiCH₂CH₂Ar), 2.29 (q, J = 7.4 Hz.

0.8H, SiCH(Me)Ar), 1.39 (d, $J = 7.4$ Hz, 2.4H, SiCH(Me)Ar), 0.94 (m, 2.4H, SiCH₂CH₂Ar), 0.12 (s, 54H, SiMe). See Scheme 1.

Scheme 1

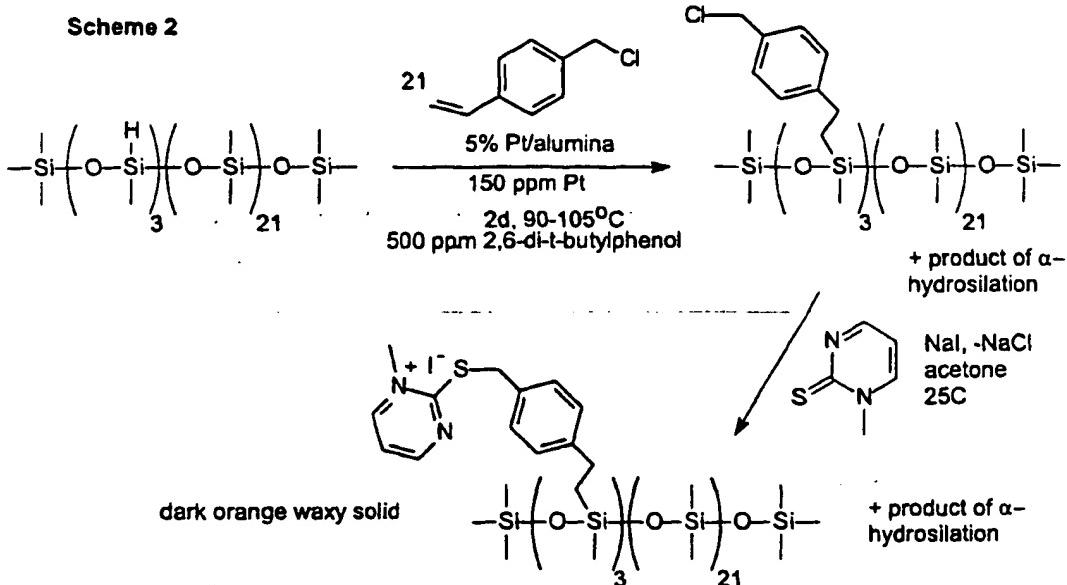
**EXAMPLE 31****"On-chain" benzylchloride-substituted silicone polymer.**

The "on-chain" hydride silicone polymer $\text{Me}_3\text{Si}-(\text{OSiMe}_2)_{21}-(\text{OSiHMe})_2-\text{OSiMe}_3$ (200 g, 102.0 mmol, GE Silicones Product) was weighed into a 250 mL round bottom flask containing a stir bar. To this was first added 2,6-di-tert-butylphenol (128 mg, 504 ppm by weight) and then 150 ppm platinum in the form of the heterogeneous catalyst $\text{Pt}/\text{Al}_2\text{O}_3$ (5% Pt by weight). The pale yellow solution was placed in a 50°C oil bath and vinylbenzylchloride (50.1 mL, 355.3 mmol, Aldrich) was added by syringe with stirring. The mixture was stirred at 60°C for 4 days. The dark yellow-green reaction mixture was then washed with methanol (1/2 by volume) three times to remove excess vinylbenzylchloride. The product, a clear yellow oil, was isolated in 79.0 % yield after drying under vacuum (194.99 g, 80.64 mmol). $^1\text{H NMR}$ (acetone- d_6): 7.33 (pseudo

τ , J = 7.8 Hz, 6 H, aryl), 7.21 (m, 6 H, aryl), 4.65 (s, 6.0 H, CH₂Cl), 2.73 (m, 4H, SiCH₂CH₂Ar), 2.23 (m, 1H, SiCH(Me)Ar), 1.40 (m, 3H, SiCH(Me)Ar), 0.93 (m, 4H, SiCH₂CH₂Ar), 0.12 (s, 154H, SiMe). The aryl resonances integrate to be 12H total. The final product showed some solubility in methanol so smaller amounts may be recommended in the washing step. Significantly lower reaction times (ca. 1-2 hours) are needed when the heterogeneous catalyst is replaced with Karstedt's catalyst, particularly for on-chain substituted hydrides, or when the described reaction is heated to a higher temperature. See Scheme 2.

Pyrimidinium-substituted silicone polymer.

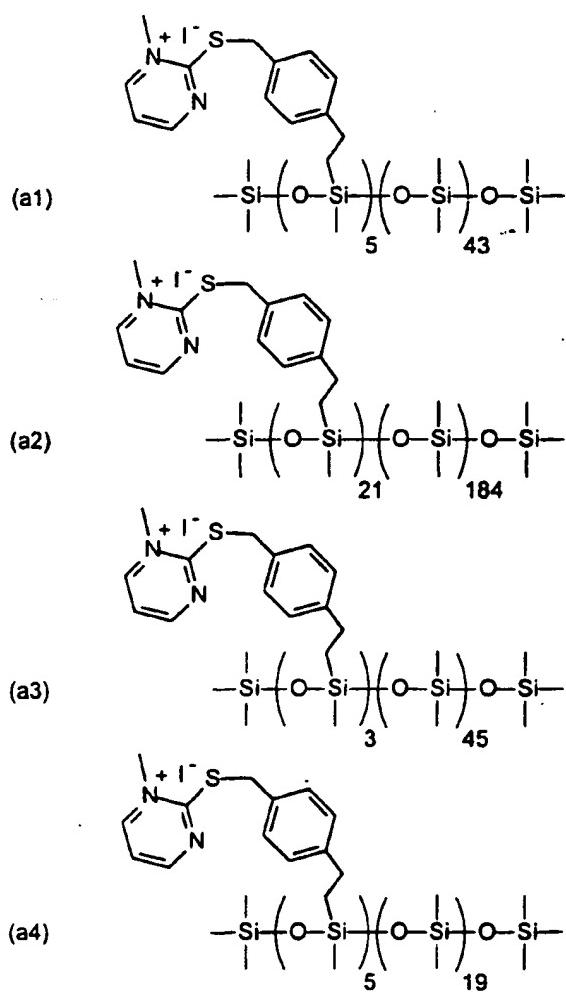
This "on-chain" benzylchloride-substituted silicone polymer (31.32 g, 12.95 mmol) was added to a 250 mL round bottom flask containing a stir bar inside a helium-filled dry box. To this was added 20 mL acetone (dried over drierite) and sodium iodide (5.46 g, 36.39 mmol, dried under vacuum at 110°C) as a solid. The solution became cloudy and quickly precipitated sodium chloride. Another 10 mL of acetone was added followed by 4.49 g (35.58 mmol) of the 2(1H)-pyrimidinethione (prepared by Starks Associates, Buffalo, NY), added piecewise as a solid. The orange mixture was allowed to stir overnight (approximately 16 hrs.) at room temperature. Outside the dry box, the precipitate was removed and the volatile materials evaporated under vacuum. The product was isolated in 97.3% yield (35.43 g) as a waxy, dark orange solid. ¹H NMR (acetone-d₆): 9.72 (s, 3 H, pyH), 9.39 (m, 3 H, pyH), 8.02 (pseudo t, J = 4.8 Hz, 3 H, pyH), 7.48 (pseudo d, J = 6.7 Hz, 6H, phenyl), 7.22 (m, 6H, phenyl), 4.82 (s, 6.3 H, CH₂S), 4.34 (s, 9.0 H, NMe), 2.72 (m, 4H, SiCH₂CH₂Ar), 2.20 (q, J = 7.4 Hz, 1H, SiCH(Me)Ar), 1.39 (m, 3H, SiCH(Me)Ar), 0.92 (m, 4H, SiCH₂CH₂Ar), 0.12 (s, 154 H, SiMe). Further studies revealed that the reaction with the pyrimidine thione can be performed under air with solvent used as received with the same results. See Scheme 2. The distribution of the on-chain substitution is random, not blocked as depicted schematically. However, the invention is not limited to randomly distributed polymer.

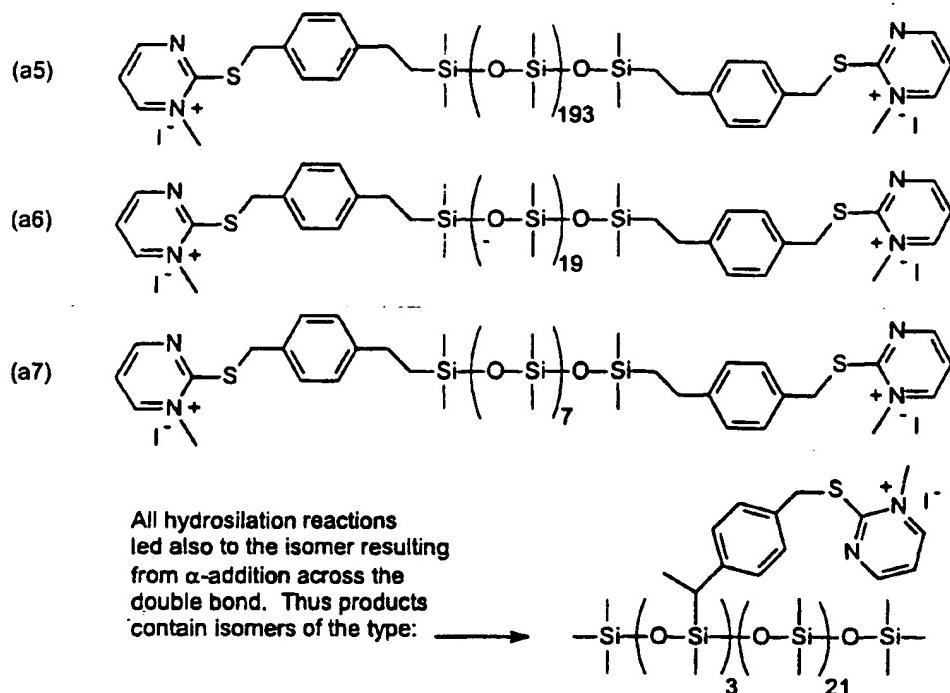


EXAMPLES 32-38

Other pyrimidinium-substituted silicone polymers.

A number of other hook-functionalized silicone polymers were prepared. Vinyl benzylchloride hydrosilation reactions were performed as described in both Examples 1 and 2 while the method used to prepare the pyrimidinium-substituted materials was as described in the second part of Example 2. The new materials synthesized are shown as follows:



**EXAMPLE 39****Benzylchloride-substituted silicone resin.**

The hydride substituted silicone resin MH_2Q (101.05g, 0.932 mol Si-H) was weighed into a 500 mL round-bottom flask containing a stir bar. 2,6-di-tert-butylphenol (61.0 mg, 529 ppm by weight) was added followed by 37.6 ppm of platinum in the form of Karstedt's catalyst (GE Silicones Product 89023, 10.0% platinum by weight). The mixture was placed in a 55°C oil bath and vinylbenzylchloride (14.30 g, 93.7 mmol, Aldrich) was added dropwise over a period of one hour. At the end of the addition, the solution went from clear yellow to cloudy yellow. The mixture was stirred at 55°C for 17 hours and then at 95°C for four hours to complete the reaction as determined by 1H NMR spectroscopy. The mixture was transferred to a 500-mL three-necked round-bottom flask which was placed in a hot oil bath. The internal temperature was raised to 120°C and 1-hexene (150 mL) was added dropwise over the course of about three hours. The mixture was stirred for an additional 16 hours, however, the temperature dropped due to excess 1-hexene and this hindered the reaction. The excess 1-hexene was removed under vacuum. The reaction was set up again, this time with a slower addition of 1-hexene at 120°C. After a total of 3 days of reaction time, which includes the previous removal step, the final product, a cloudy dark brown liquid, was isolated in 94.8% yield (176.18 g). 1H

NMR (acetone-d₆): 7.32 (m, phenyl), 7.24 (pseudo d, J = 5.5 Hz, phenyl), 7.16 (m, phenyl), 4.65 (s, ArCH₂Cl), 2.73 (m, SiCH(Me)Ar), 2.03 (s, SiCH(Me)Ar), 1.31 (br m, SiCH₂CH₂Ar and hexyl), 0.88 (br m, hexyl), 0.65 (br m, hexyl), 0.18 (br m, SiCH₂CH₂Ar and hexyl), -0.24 (br s, SiMe). Shorter reaction times are required if the temperature of the reaction with 1-hexene is maintained at 120°C.

Pyrimidinium-substituted silicone resin.

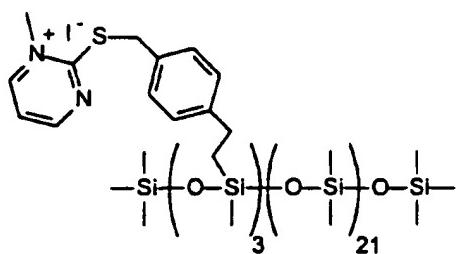
The benzylchloride-functionalized resin was converted to the pyrimidinium substituted material as described in Example 31. The product was isolated in 87.8% yield (25.9 g) as a viscous dark orange liquid.

Hair care benefits.

In order to measure hair care benefits imparted by the new silicone materials, treated hair switches (4 grams) were contacted with formulations containing the pyrimidinium-substituted silicone polymer described in Example 31 which is referred to as the "3Hook Polymer". Following treatment and simulated consumer use, combing forces were measured using a Reed Combing Machine.

The study of combining forces showed that hair switches treated with the hook-substituted silicone polymer consistently exhibited lower combing forces than the controls. The sample which did contain the hook silicone polymer demonstrated combining benefits over the sample which did not contain the hook silicone polymer. Combing benefits are also evident in the samples containing the 3Hook Polymer compared with the analogous samples which contained PDMS (polydimethylsiloxane, 5 centistokes, 5% by weight) as a control.

3Hook Polymer:



Overall, use of the 3Hook Polymer in the hair treatment formulation clearly led to wet combing benefits whether or not conditioner was used. Wet combing benefits were found when the hair was treated once and then subjected to four simulated weeks of shampooing. The combing benefit imparted to hair treated only once was just as profound as that found for hair that was treated weekly with the hook silicone polymer. In addition, the benefit imparted to the hair by the 3Hook polymer was durable, lasting through at least 16 shampoos.

While typical embodiments have been set forth for the purpose of illustration, the foregoing descriptions should not be deemed to be a limitation on the scope of the invention. Accordingly, various modifications, adaptations, and alternatives may occur to one skilled in the art without departing from the spirit and scope of the present invention.

METHODS OF USING THE PROTECTED THIOL COMPOUNDS OF THE PRESENT INVENTION

The method of use of the various protected thiol compounds is dependent on the product form utilized. The use would be as typically used for the product chosen.

The protected thiol compound of the present invention can be used in a variety of ways in hair care compositions. For example, in the most basic sense the cosmetic actives of the present invention can be applied directly to the hair in a alcohol/solvent/water solution comprising:

Protected thiol cosmetic active of Examples 1-20, 30, 31, 39	0.5 to 10%
Hydroalcoholic solvent	0 to 95.00%
pH modifier, i.e., NaOH or citric acid	pH 3 to 10*
Water	Q.S.

* Note, the pH will vary based on the particular "hook" compound of use and can be adjusted either just prior to treatment with hair or simultaneously with the treatment of hair.

After application, the hair is washed or rinsed to remove excess solvent. The resulting protected thiol cosmetic active will be delivered and bound to the hair permanently, e.g. benefit will last beyond 40 to 80 or more shampoos.

A simple non-limiting dye composition using the protected thiol compounds of the present invention comprises the following composition ranges (depending on what colour is desired):

Modified D&C Violet No. 2 of Example 21	0.00% to 3.00%
Modified D&C Red No. 31 of Example 19	0.00% to 3.00%
Modified D&C Yellow No. 6 of Example 20	0.00% to 3.00%
Modified D&C Black No. 9 of Example 18	0.00% to 3.00%
2-propanol	50.00%
Sodium Hydroxide	to pH 9-10
Water	Q.S.

wherein the total dye concentration is between 1% and 5%. The preparation of this composition and treatment with hair for proof of performance is described as follows: The dyes are added to the water and 2-propanol solution in a jar and stirred until thoroughly dissolved at room

temperature. The hair to be treated is submerged into the solution such that the hair weight comprises 10 to 40 wt% of the composition. The sodium hydroxide is then added, a cap is placed on the jar and the jar containing the solution plus hair is shaken for five minutes. The hair is then removed from the jar and rinsed thoroughly.

A simple non-limiting conditioning composition using a protected thiol compound of the present invention comprises:

The Modified Silicone of Example 23	5.00%
Methanol	90.00%
NaOH	to pH 8-10
Water	Q.S.

The preparation of this composition and treatment with hair for proof of performance is described as follows: The modified silicone is added to the methanol in a jar and stirred until thoroughly dissolved at 100°F. The water and NaOH is then added with stirring until the solution is thoroughly mixed. With a syringe, one gram of the resulting solution is applied per gram of the hair to be treated. The applied solution is then worked through the hair while wearing rubber gloves. The hair is then covered with plastic wrap and let sit for up to two hours. The hair is then rinsed thoroughly.

The protected thiol compounds can be achieved with any of the protected hooks described herein. Of course, the protected thiol compounds of the present inventions can be applied in differing matrices and formulas as described previously herein.

The protected thiol compounds may also be added to technologies currently well known in the art to treat substrates such as hair, teeth, finger nails, textiles, and animal fur. Nonlimiting examples of such compositions are described in the references below, each of which is incorporated herein by reference in its entirety:

Shampoos - U.S. Patent No. RE 34,584 (Grote et al.) issued April 12, 1994; U.S. Patent No. 4,345,080 (Bolich) issued August 17, 1982; U.S. Patent No. 4,379,753 (Bolich) issued April 12, 1983; and U.S. Patent No. 4,705,681 (Maes et al.) issued November 10, 1987.

Hair conditioners - U.S. Patent No. 4,387,090 (Bolich) issued June 7, 1983; U.S. Patent No. 5,674,478 (Dodd et al.) issued October 7, 1997; and U.S. Patent No. 5,750,122 (Evans et al.) issued May 12, 1998.

Hair styling compositions - U.S. Patent No. 5,166,276 (Hayama et al.) issued November 24, 1992; U.S. Patent No. 5,565,193 (Midha et al.) October 15, 1996; and U.S. Patent No. 5,658,557 (Bolich et al.) issued August 19, 1997.

Hair coloring compositions - U.S. Patent No. 4,197,865 (Jacquet et al.) issued April 15, 1980, U.S. Patent No. 4,125,367 (Bugaut et al.) issued November 14, 1978, U.S. Patent No. 5,114,429 (Junino et al.) issued May 19, 1992, and U.S. Patent No. 5,279,620 (Junino et al.) issued January 18, 1994.

Mascara compositions - Commonly assigned U.S. Patent Application Serial Nos. 08/951,285 (Alwatarri et al.), filed October 16, 1997, (Attorney's Docket 6345C); 08/757,538 (Bartholomey et al.), filed November 27, 1996 (Attorney's Docket 6397); and 09/121,138 (Alwatarri et al.), filed July 23, 1998 (Attorney's Docket 5654C2); and in PCT Application Nos. US96/04154, published October 31, 1996; US97/19786, published May 7, 1998; and US97/21890, published June 4, 1998.

Nail polish and nail polish subcoat compositions - U.S. Patent 4,179,304 (Rossomando) issued December 18, 1979, U.S. Patent 5,538,717 (LaPoterie) issued July 23, 1996, and U.S. Patent 5,639,447 (Patel) issued June 17, 1997, U.S. Patent 5,567,428 (Hughes) issued October 22, 1996.

Toothpaste compositions - U.S. Patent 4,254,101 (Denny) issued March 3, 1981, and U.S. Patent 4,314,990 (Denny et al.) issued February 9, 1982, and PCT Application No. WO 96/15767 (Unilever PLC) published May 30, 1996.

Textile dye and treatment compositions -

Other typical compositions are found in Cosmetic and Toiletry Formulations, 2nd Ed, Flick, E. W., Noyes Publications (N.J.), Harry's Cosmeticology, 7th Ed., Harry, R.G., Wilkinson, J.B., and Moore R.J., Chemical Pub. Co. (NY) (1982); and Cosmetics, Science and Technology, 2nd Ed., Balsam, M.S. and Sagarin, E.S., Wiley-Interscience (NY) (1972) (3 volumes).

Other embodiments of the present invention comprise a system comprising a topical composition containing the protected thiol compound and an activating mechanism. For example the conditioner composition:

EXAMPLE 40

Pyridinium, 1-methyl-2-[(hexadecyl)thio]-, bromide	3.00%
Urea	10.00%
Cocoamidopropyl Betaine	0.80%
isopropanol	50.00%
Water	Q.S.

can be applied simultaneously with a 5% solution of thioglycolic acid. A preferred embodiment is a kit wherein the dye solution and the thioglycolic acid are packaged in separate chambers of a dual chamber package and delivered simultaneously from the package.

WHAT IS CLAIMED IS:

1. A topical composition for treating amino acid based substrates comprising a protected thiol compound having the formula

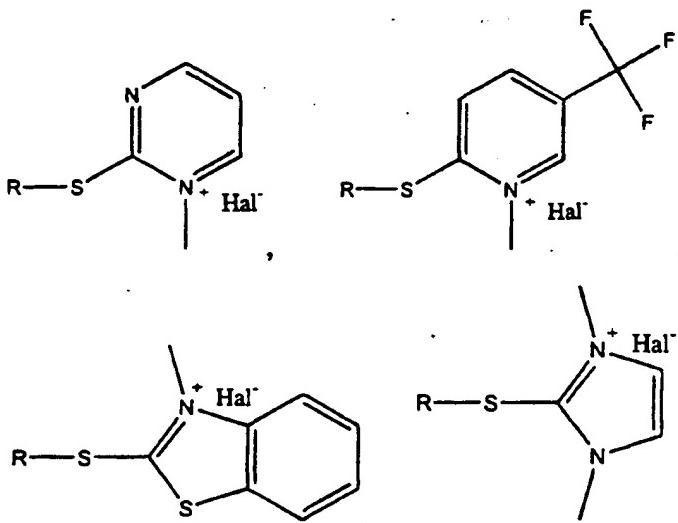


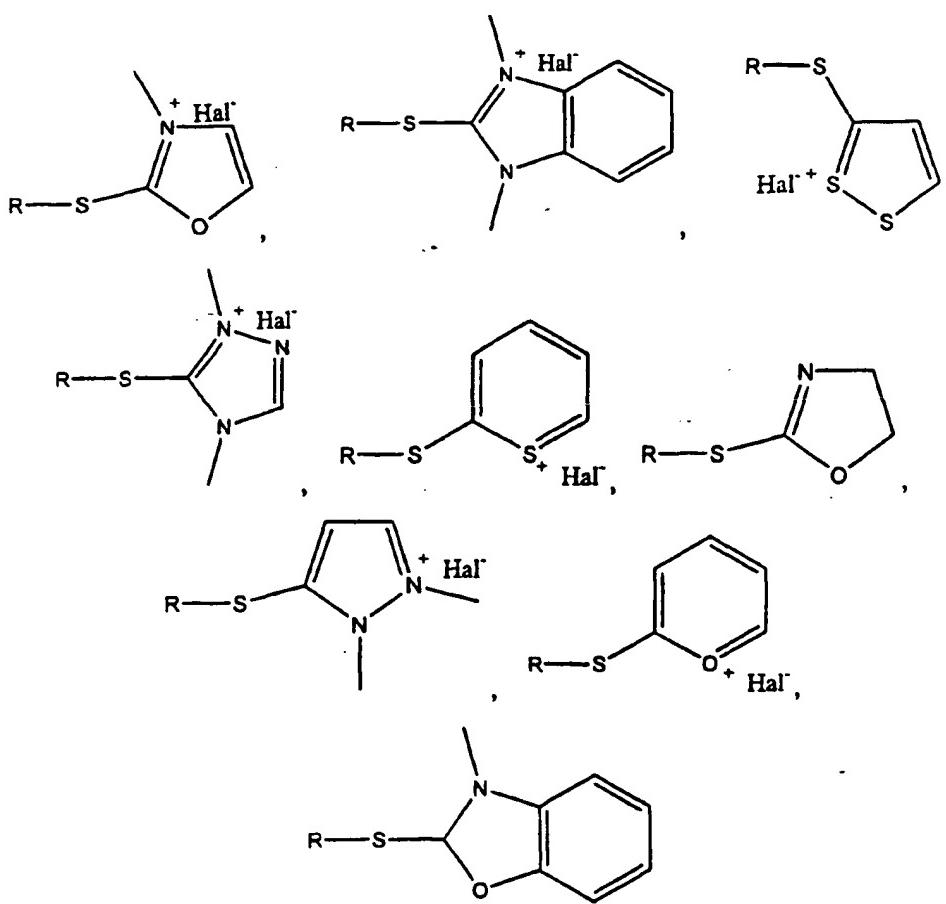
where R is a mono or multivalent cosmetically active functional group, S is sulfur, Pr is a protecting group and m is an integer between 1 and 100.

2. A topical composition according to Claim 1, wherein the functional group, R, is selected from the group consisting of antimicrobial compounds, UV-absorbing compounds, skin conditioning agents, hair conditioning agents, hair repair agents, hair styling agents, hair dyes, scalp treatment agents, anti-inflammatory compounds, antioxidants, coloring agents, perfumes, oral care actives, skin moisturizers, pharmaceutical agents, antidandruff agents, insect repellents, moisturizers, humectants, pearlescent and/or opacifying materials, fabric care actives, pet grooming actives, fabric anti-wrinkling agents, shrink-resistant actives, laundry care actives, hard surfaces actives, textile actives, textile dyes, water-proofing agents, cationic polymers, cationic surface modifiers, hydrophobic surface modifiers, anionic surface modifiers, absorbents, antifungal agents, insecticidal agents, textile color guards, nail actives such as enamel and polish, eyelash actives and mascara, antiperspirant and deodorant actives, anti-acne actives, odor control actives, fluorescent actives, bleaching agents, enzymes, antibodies, dispersing aids, emollients, stabilizers, anti-static agents, anti-seborrhea agents, brighteners, fluorescent dyes, softeners, cross-linkers, and mixtures thereof.
3. A topical composition according to any of the previous claims, wherein the protecting group is selected from the group consisting heterocyclic protecting groups, sp^2 aliphatic trigonal carbon protecting groups, sp^3 carbon electrophilic protecting groups, metal based protecting groups, non-metalloid based protecting groups, energy-sensitive protecting groups and mixtures thereof.
4. A topical composition according to any of the previous claims, wherein the protecting group is a heterocyclic protecting group selected from the group consisting of mono- or polyunsaturated or saturated heterocyclic rings, heterocyclic ring systems, fused heterocyclic ring systems, substituted heterocyclic rings, substituted heterocyclic ring systems, substituted fused heterocyclic ring systems, and mixtures thereof.

5. A topical composition according to any of the previous claims, wherein the heterocyclic protecting group is selected from the group consisting of six membered heterocycles with one, two, three or four heteroatoms, six membered heterocyclics containing O, N, or S with C=O, C=S or C=C exocyclic groups, cationic six membered heterocycles with one or two heteroatoms, five membered heterocycles with one, two, or three heteroatoms, cationic, five membered heterocycles with two or more heteroatoms, seven membered heterocycles, cationic seven membered heterocycles, combinations of heterocycles in a ring system and a fused system both of which may include carbocyclic rings without heteroatoms, and mixtures thereof.

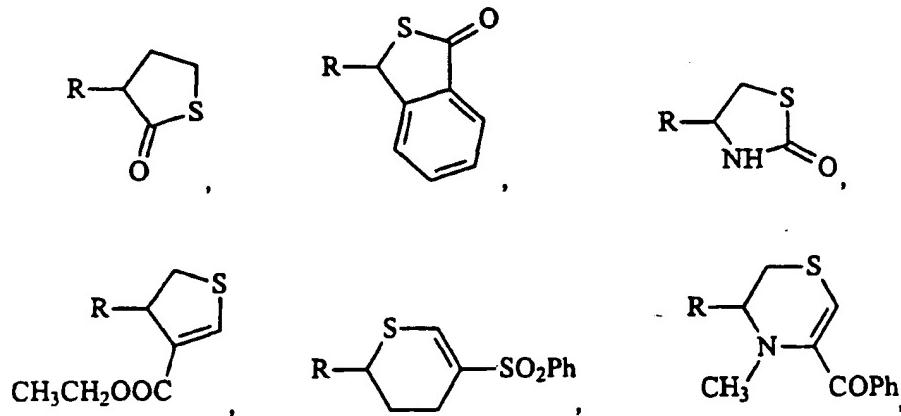
6. A topical composition according to any of the previous claims, wherein the protected thiol compound is selected from the group consisting of

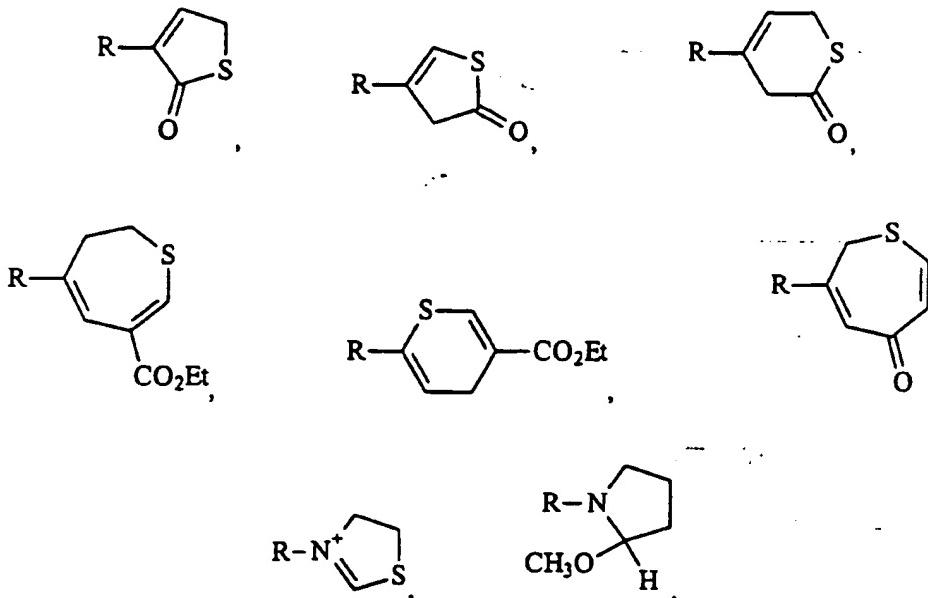




and mixtures thereof, wherein Hal^- is Cl^- , Br^- , I^- or any suitable negatively charged counterion.

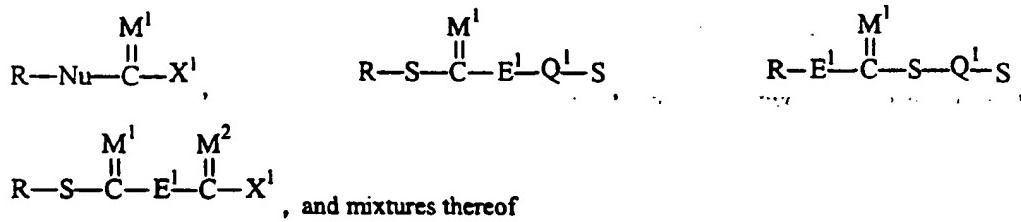
7. A topical composition according to any of the previous claims, wherein the protected thiol compound is selected from the group consisting of





and mixtures thereof.

8. A topical composition according to Claim 3, wherein the protecting group is an sp^2 aliphatic trigonal carbon group such that the protected thiol compound has the formula selected from the group consisting of

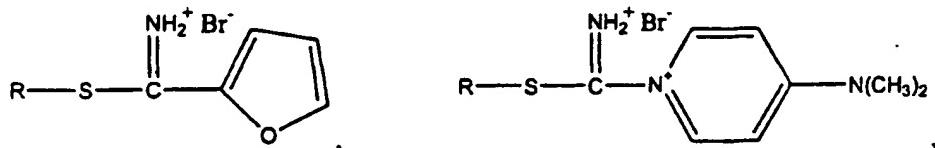
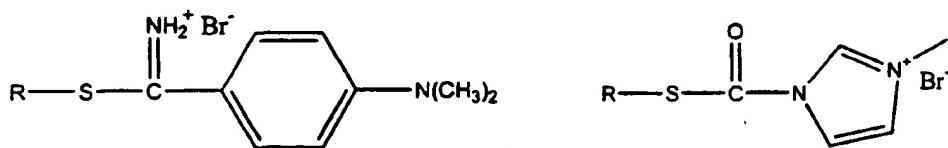
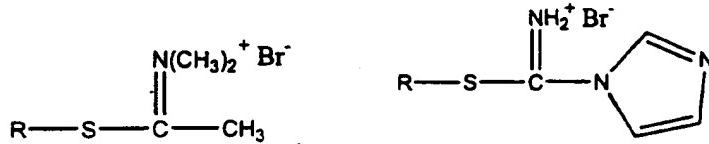
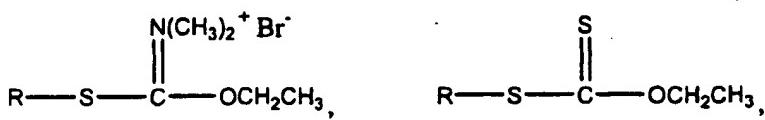


wherein M^1, M^2 are O, S, NA^1 , NOA^1 , NA^1A^{2+} , or $CA^1=CA^2Y^1$; E^1 is O, S, NA^1 , CA^1A^2 ; or Nu^1 is NHA^1A^{2+} , NA^1A^2 , OHA^1+ , or OA^1 ; and X^1 represents an electron withdrawing or electron donating group with a Hammett sigma para value between -1.0 and +1.5 comprising C-linked groups of the classes defined below as A^1, A^2, A^3 ; S-linked groups including SA^1 , SCN , SO_2A^1 , SO_3A^1 , SSA^1 , SOA^1 , $SONA^1A^2$, SNA^1A^2 , $S(NA^1)A^2$, $S(O)(NA^1)A^2$, $SA^1(NA^2)$; O-linked groups including OA^1 , OOA^1 , OCN , ONA^1A^2 ; N-linked groups including NA^1A^2 , $NA^1A^2A^3$, NC, NA^1OA^2 , NA^1SA^2 , NCO, NCS, NO_2 , $N=NA^1$, $N=NOA^1$, NA^1CN , $N=C=NA^1$, $NA^1NA^2A^3$, $NA^1NA^2NA^3A^4$, $NA^1N=NA^2$; other miscellaneous groups including $COHal$, CON ,

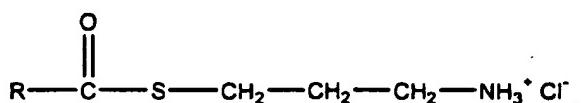
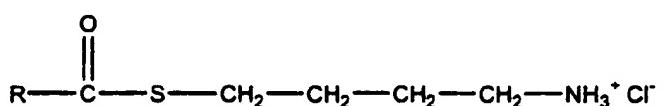
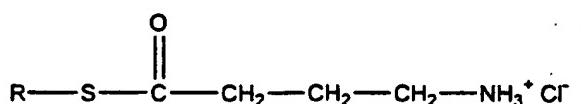
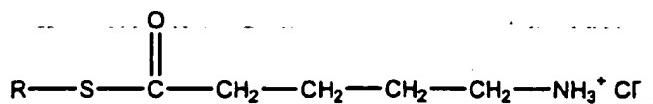
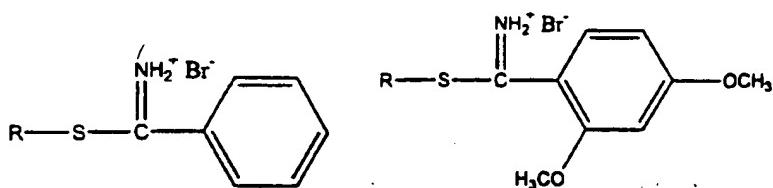
CONA^1_2 , $\text{CONA}^1\text{COA}^2$, $\text{C}(\text{=NA}^1)\text{NA}^1\text{A}^2$, CHO, CHS, CN, NC, Hal, and derived groups that connect one or more of X^1 , X^2 , X^3 , X^4 , X^5 via a ring system.

9. A topical composition according to Claim 8, wherein the sp^2 aliphatic trigonal carbon protecting group-nucleophile moiety is selected from derivatives of thiocarboxylic acid, carbonodithioic acid, carbonothioic acid, carbamothioic acid, dithiocarboxylic acid, carbonotriethioic acid, carbamodithioic acid, carboximidothioic acid, carbonimidodithioic acid, and carbonimidothioic acid, and mixtures thereof.

10. A topical composition according to Claim 9 wherein the protected thiol compound is selected from the group consisting of



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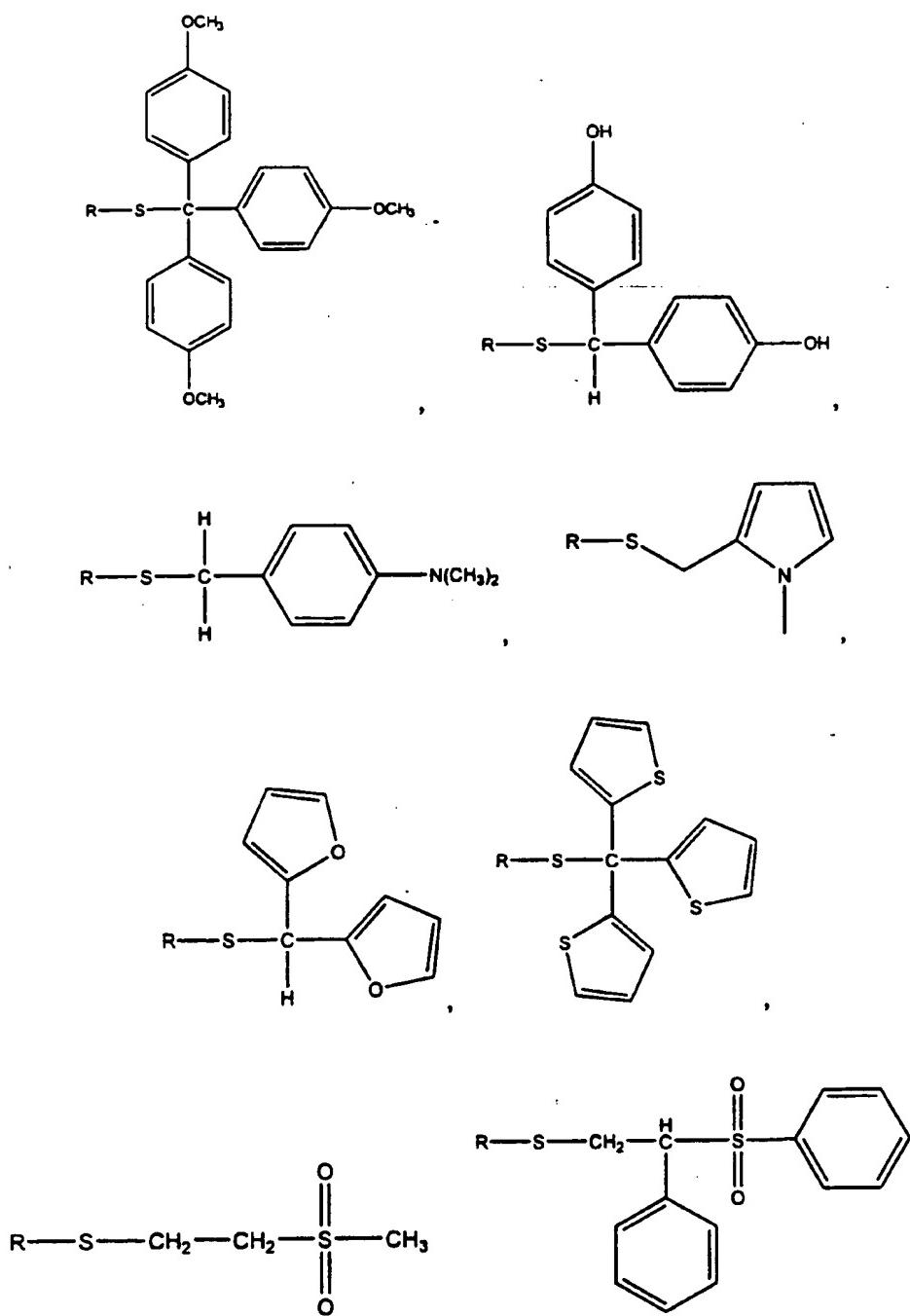


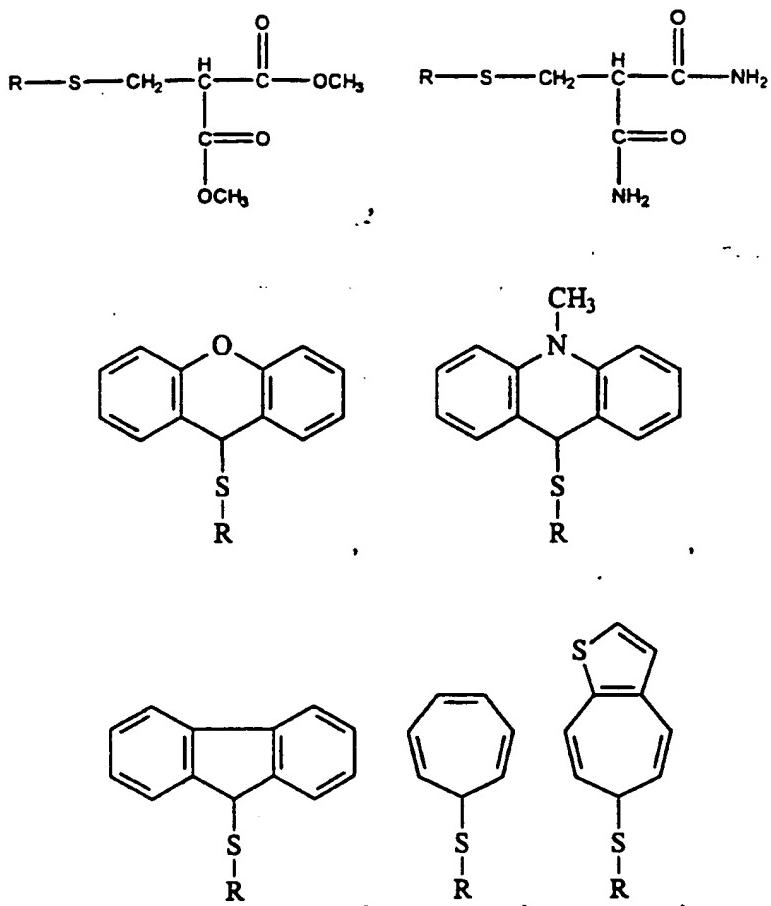
and mixtures thereof.

11. A topical composition according to Claim 3, wherein the protecting group is an sp^3 carbon electrophilic protecting group such that the nucleophile-protecting group moiety is selected from the group consisting of monothioacetal groups, monothioketal groups, monothioorthoester groups, monothioorthocarbonate groups, dithioacetal groups, dithiolethal groups, dithioorthoester groups, dithioorthocarbonate groups, trithioorthoester groups, thiohemiaminal groups, monothioorthoamide groups, dithioorthoamide groups, sp^3 carbon groups capable of undergoing heterolytic β -elimination, and sp^3 carbon ring systems, and mixtures thereof.

12. A topical composition according to Claim 11 wherein the protected thiol compound is selected from the group consisting of

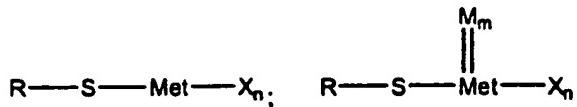
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and mixtures thereof.

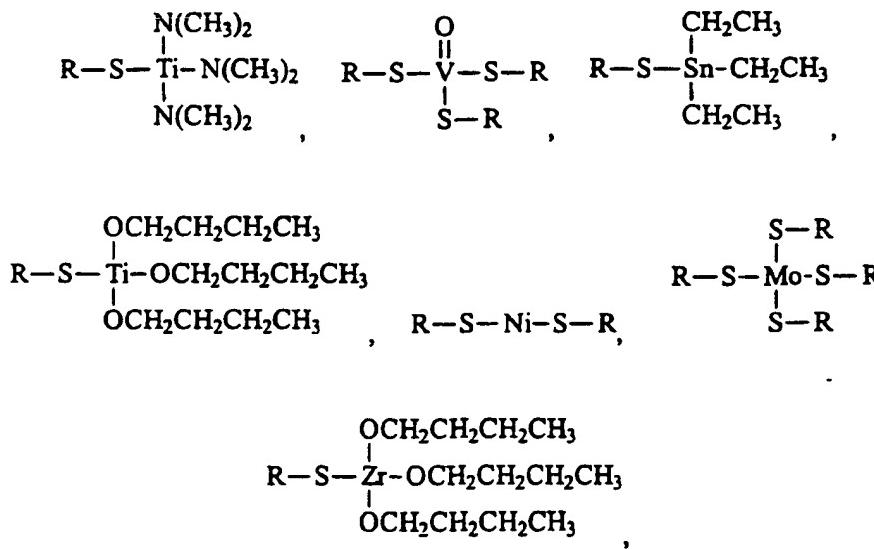
13. A topical composition according to Claim 3, wherein the protecting group is a metal based protecting group such that the protected thiol compound has the formula selected from the group consisting of



and mixtures thereof, wherein Met is an alkaline earth metal, transition metal or a representative metal selected from the group consisting of Mg, Ca, Sr, Ba, La, Ti, Zr, V, Cr, Mo, W, Mn, Fe, Co, Rh, Ni, Pd, Pt, Cu, Ag, Au, Zn, In, Sn, and Bi.; wherein n and m are zero or integers such that $1 + 2m + n$ equals the valency of Met; X represents independent electron withdrawing, electron neutral or electron donating groups with Hammett sigma para values between -1.0 and +1.5, and

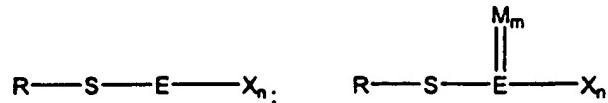
M is O, S, NA¹ or CA¹A², where A¹ and A² represent, independently from one another, a monovalent group which can be the cosmetic active group, R, or H or a straight, branched or mono- or poly- cyclic aliphatic, mono or polyunsaturated alkyl, aryl, heteroalkyl, heteroaliphatic or heteroolefinic system including 1 to 30 carbon atoms together with 0-15 heteroatoms.

14. A topical composition according to Claim 13 wherein the protected thiol compound is selected from the group consisting of



and mixtures thereof.

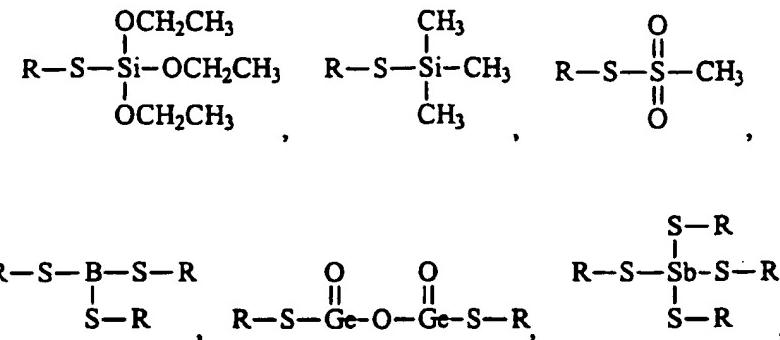
15. A topical composition according to Claim 3, wherein the protecting group is a non-metal or metalloid based protecting group such that the protected thiol compound has the formula selected from the group consisting of



and mixtures thereof, wherein E is a representative non-metal or metalloid element selected from the group consisting of B, Al, Si, Ge, N, P, S, Se, Sb, and Te; wherein n and m are zero or integers such that 1 + 2m + n equals the valency of E; X represents independent electron withdrawing, electron neutral or electron donating groups with Hammett sigma para values between -1.0 and +1.5, and M is O, S, NA¹ or CA¹A², where A¹ and A² represent, independently from one another, a monovalent group which can be the cosmetic active group, R, or H or a

straight, branched or mono- or poly- cyclic aliphatic, mono or polyunsaturated alkyl, aryl, heteroalkyl, heteroaliphatic or heteroolefinic system including 1 to 30 carbon atoms together with 0-15 heteroatoms.

16. A topical composition according to Claim 15, wherein the protected thiol compound is selected from the group consisting of

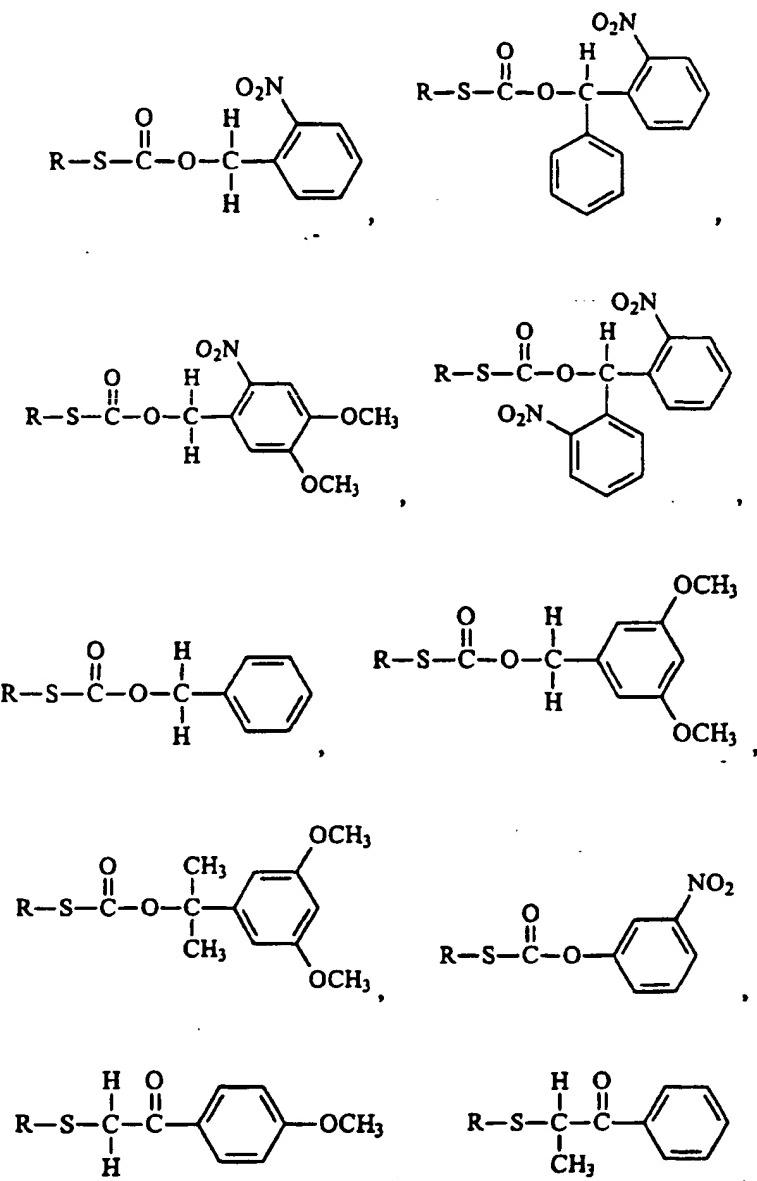


and mixtures thereof.

17. A topical composition according to Claim 3, wherein the protecting group is an energy sensitive protecting group selected from the group consisting of 2-Nitrobenzyl groups, 2-Nitrobenzyloxycarbonyl groups, Benzyloxycarbonyl groups, α,α -Dimethylbenzyloxycarbonyl groups, 3-Nitrophenyloxycarbonyl groups, Phenacyl groups, tert-Butyloxycarbonyl groups, and mixtures thereof.

18. A topical composition according to Claim 17, wherein the protecting group is an energy sensitive protecting group selected from the group consisting of 6-nitroveratryloxycarbonyl, dimethyldimethoxybenzyloxycarbonyl, nitrobenzyloxycarbonyl, 5-bromo-7-nitroindolinyl, O-hydroxy-alpha-methyl-cinnamoyl, 2-oxymethylene anthraquinone, and mixtures thereof.

19. A topical composition according to Claim 17, wherein the protected thiol compound is selected from the group consisting of



and mixtures thereof.

20. A system comprising:

- a topical composition according to any of the previous claims; and
- an activating mechanism.

21. A system according to Claim 20, wherein the activating mechanism is a pH modifier.
22. A system according to Claim 20, wherein the activating mechanism is water.
23. A system according to Claim 20, wherein the activating mechanism is an energy source.
24. A system according to Claim 20, wherein the activating mechanism is a separate nucleophile.
25. A system according to Claim 20, wherein the activating mechanism is pre-reduced hair.
26. A kit comprising:
 - a) the system according to Claim 21; and
 - b) a package comprising a first and second chamber;
wherein the topical composition is packaged in and delivered out of one chamber and
the pH modifier is packaged in and delivered out of the second chamber.
27. A hair care composition comprising the topical composition according to any of Claims 1 to 19.
28. A hair care composition according to Claim 27 wherein the protected thiol compound comprises from 0.000001% to 30% of the composition.
29. A hair care composition according to Claim 28, wherein the functional group, R, is selected from the group consisting of hair conditioners, hair styling agents, dyes and coloring agents, sunscreens, fragrances, antidandruff agents, and mixtures thereof.
30. A textile care composition comprising the topical composition according to any of Claims 1 to 19.
31. A textile care composition according to Claim 30, wherein the protected thiol compound comprises from 0.00001% to 30% of the composition.

32. A textile care composition according to Claim 31, wherein the functional group, R, is selected from the group consisting of dyes and coloring agents, odor control actives, sealants, fragrances, and mixtures thereof.

33. A cosmetic composition comprising the topical composition according to any of Claims 1 to 19.

34. A cosmetic composition according to Claim 33, wherein the protected thiol compound comprises from 0.000001% to 30% of the composition.

35. A cosmetic composition according to Claim 34, wherein the functional group, R, is selected from the group consisting of dyes and coloring agents, sealants, resins, varnishes, latex finishes, and mixtures thereof.

36. An oral care composition comprising the topical composition according to any of Claims 1 to 19.

37. An oral care composition according to Claim 36, wherein the protected thiol compound comprises from 0.000001% to 30% of the composition.

38. An oral care composition according to Claim 37, wherein the functional group, R, is selected from the group consisting of anti-caries agents, plaque buffers, anti-plaque agents, agents for alleviating sensitive teeth, materials that form films and block pores, oral pharmaceutical actives, biomolecules, anti-tartar agents, agents for treating bad breath, anti-calculus agents, and mixtures thereof.

39. An animal care composition comprising the topical composition according to any of Claims 1 to 19.

40. An animal care composition according to Claim 39, wherein the protected thiol compound comprises from 0.000001% to 30% of the composition.

41. An animal care composition according to Claim 40, wherein the functional group, R, is selected from the group consisting of antimicrobial agents, insect repellents, grooming actives, and mixtures thereof.
42. A method for attaching a functional group to an amino acid based substrate comprising applying the topical composition according to any of Claims 1 to 19 to the amino acid based substrate.
43. A method according to Claim 42 wherein the acid based substrate is selected from the group consisting of wool, cotton, animal fur, animal skin, human hair, human skin, human nails, and human teeth.
44. A method for attaching a functional group to human hair comprising applying the hair care composition according to any of Claims 27 to 29 to human hair in need of such treatment.
45. A method for attaching a functional group to textiles comprising applying the textile care composition according to any of Claims 30 to 32 to textiles in need of such treatment.
46. A method for attaching a functional group to finger nails or eyelashes comprising applying the cosmetic composition according to any of Claims 33 to 35 to nails or eyelashes in need of such treatment.
47. A method for attaching a functional group to teeth comprising applying the oral care composition according to any of Claims 36 to 38 to teeth in need of such treatment.
48. A method for attaching a functional group to animal fur comprising applying the animal care composition according to any of Claims 39 to 41 to animal fur in need of such treatment.
49. A topical composition which has the improved combined benefits of stability to air and attachment of the cosmetically active functional group to amino acid substrates upon application without pretreatment of the substrate over previously topical compositions.
50. A hair care composition which results in covalent attachment of cosmetically active functional groups to human hair with significantly less damage occurring on the hair.

51. A process for treating hair comprising the step of applying a safe and effective amount of the hair care composition of any of Claims 27 to 29 to human hair in need of treatment and the step of applying a pH modifier to the hair.

52. The process for treating hair according to Claim 51, wherein the step of applying the hair care composition and the step of applying the pH modifier are performed simultaneously.

53. A textile care composition which results in covalent attachment of cosmetically active functional groups to textiles without severe treatment or pretreatment processes.

54. A silicone composition which comprises at least one polysiloxane or silicone resin, at least one linker, and at least one molecular hook.

55. The composition of claim 54 in which the at least one linker is bound to a polysiloxane or silicone resin through a silicon, carbon, oxygen, nitrogen, or sulfur atom.

56. The composition of claim 55 in which the at least one linker is bound to a polysiloxane or silicone resin through a silicon atom.

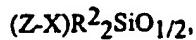
57. The composition of claim 54 in which the at least one polysiloxane or silicone resin has the formula:



where the subscripts a, c, d, e, f and g are zero or a positive integer, subject to the limitation that the sum of the subscripts b, d and f is one or greater; where M has the formula:



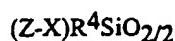
M' has the formula:



D has the formula:



D' has the formula:



T has the formula:



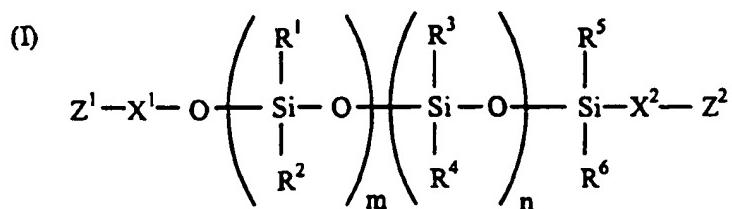
T' has the formula:

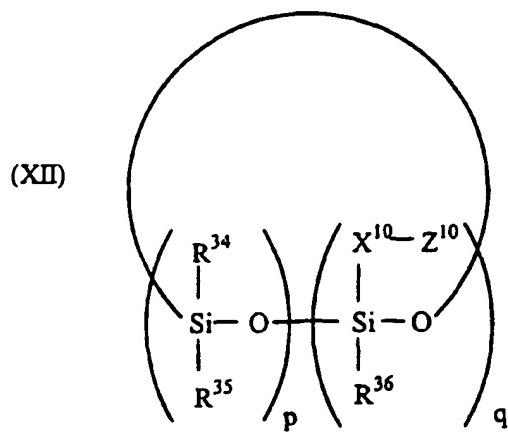
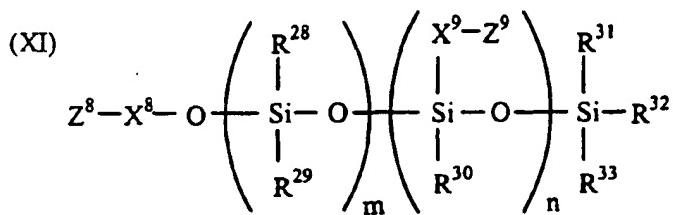
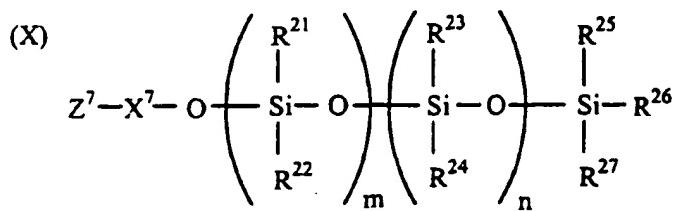
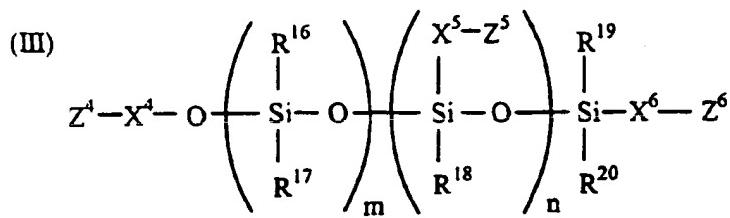
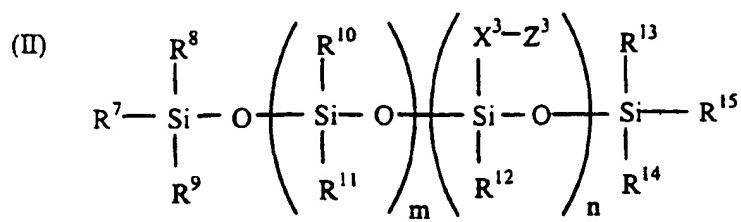


and Q has the formula $SiO_{4/2}$, where each R^1 , R^2 , R^3 , R^4 , R^5 is independently at each occurrence a hydrogen atom, C_{1-22} alkyl, C_{1-22} alkoxy, C_{2-22} alkenyl, C_{6-14} aryl, and C_{6-22} alkyl-substituted aryl, C_{6-22} aralkyl, or C_{1-22} fluoroalkyl; each Z, independently at each occurrence, is a molecular hook; and each X, independently at each occurrence, is a linker.

58. The composition of claim 57 in which the average number of X-Z moieties on a polysiloxane or silicone resin is between 1 and 100, preferably between 1 and 6, and more preferably between 3 and 6.

59. The composition of claim 57 in which the at least one polysiloxane or silicone resin comprises at least one compound of the following formulas, (I), (II), (III), (X), (XI), or (XII):





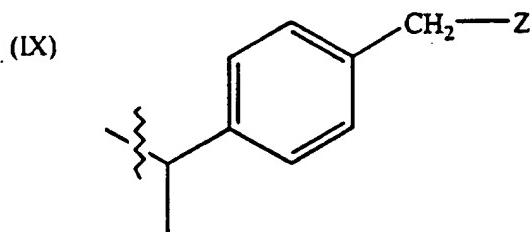
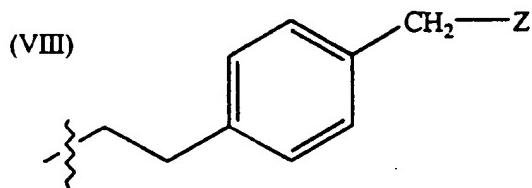
wherein each R¹⁻³⁶ is independently at each occurrence a hydrogen atom, C₁₋₂₂ alkyl, C₁₋₂₂ alkoxy, C₁₋₂₂ alkenyl, C₆₋₁₄ aryl, and C₆₋₂₂ alkyl-substituted aryl, C₆₋₂₂ aralkyl, and C₁₋₂₂ fluoroalkyl; Z¹⁻¹⁰, independently at each occurrence, is a molecular hook; and X¹⁻¹⁰, independently at each occurrence, is a linker; wherein "m" in each formula has a value in a range between about 0 and about 13,000; "n" in each formula has a value in a range between about 0 and about 13,000; "m+n" in each formula has a value in a range between about 1 and about 13,000; "q" has a value of at least one and "p+q" has a value of at least 3.

60. The composition in accordance with claim 59, wherein a polysiloxane or silicone resin comprises at least one compound of formulas (I), (II), (III), (X), or (XI), wherein R¹⁻³³ is methyl; "m" in each formula has a value in a range between about 1 and about 50; "n" in each formula has a value in a range between about 0 and about 50; and "m+n" in each formula has a value in a range between about 3 and about 70.
61. The composition in accordance with claim 59, wherein a polysiloxane or silicone resin comprises at least one compound of formula (XII), wherein "q" has a value of at least one and "p+q" has a value of 3-6.
62. The composition in accordance with claim 57, wherein the linker comprises a C₁-C₅₀ alkyl, aryl, or alkylaryl group, or a C₁-C₅₀ heteroaryl group containing one or more heteroatoms.
63. The composition in accordance with claim 62, wherein the moiety Z-X is prepared by a process which comprises combining a hook with a linker precursor comprising a linker and a leaving group.
64. The composition in accordance with claim 62, wherein the leaving group is selected from the group consisting of chloride, bromide, iodide, tosylate, mesylate, phosphate, and cyclic leaving groups containing at least one heteroatom.
65. The composition in accordance with claim 64, wherein the leaving group is iodide.
66. The composition in accordance with claim 54, wherein the linker comprises at least one moiety of the formula -D-Ar(Y)_n-CH₂- wherein "Ar" comprises an aromatic or heteroaromatic

group; "Y" is a C₁₋₂₂ straight chain, branched, cycloaliphatic, or aralkyl group; C₆₋₁₄ aryl group; fluoro, chloro, bromo, iodo, nitro, nitroso, nitrile, trifluoromethyl, trifluoropropyl, alkyloxycarbonyl, alkylcarbonyl, alkylamido, alkyl ether, or aryl ether group; "n" has a value between zero and the number of free valence sites on the aromatic or heteroaromatic ring; "D" comprises a group bound to a polysiloxane or to a silicone resin, said D group comprising a C₁₋₂₂ straight chain alkyl, branched alkyl, cycloaliphatic, or aralkyl group which optionally may contain a functional group, said functional group being bound to D in a pendent position or separating D from the aromatic or heteroaromatic group, or separating D from a polysiloxane or from a silicone resin, or in more than one of these positions, and wherein said functional group comprises carbonyl, alkylcarbonyl, oxycarbonyl, alkyloxycarbonyl, nitrile, amido, alkylamido, trifluoromethyl, chloro, bromo, or fluoro.

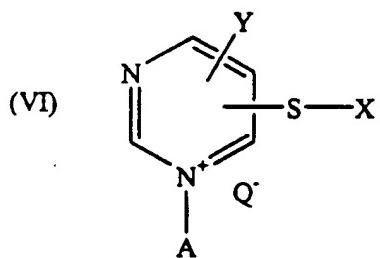
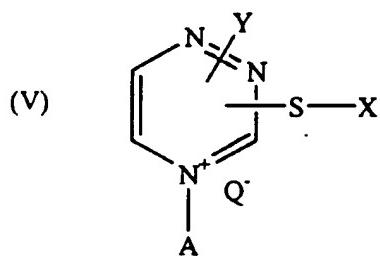
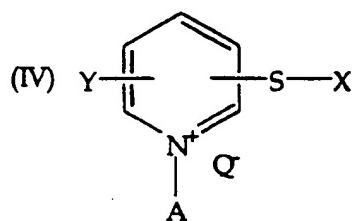
67. The composition in accordance with claim 66, wherein the aromatic or heteroaromatic group comprises phenyl, biphenyl, toluyl, naphthyl, pyridyl, quinolyl, triazinyl, pyrimidyl, pyridazinyl, furyl, furoyl, or thiienyl.

68. The composition in accordance with claim 66, wherein the linker consists of at least one compound of the formulas (VIII) and (IX) :



69. The composition in accordance with claim 57, wherein the molecular hook comprises a heterocyclic pyridinium compound, a heterocyclic triazinium compound, or a heterocyclic pyrimidinium compound.

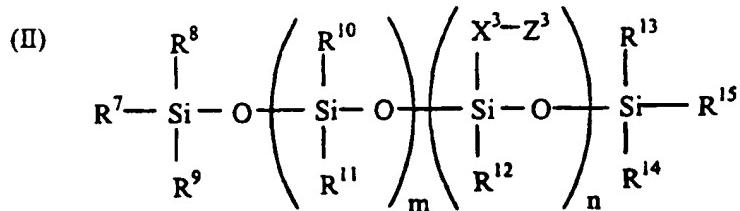
70. The composition in accordance with claim 69, wherein the molecular hook is at least one member selected from the group consisting of a heterocyclic pyridinium compound (IV), a heterocyclic triazinium (V), and a heterocyclic pyrimidinium compound (VI) :



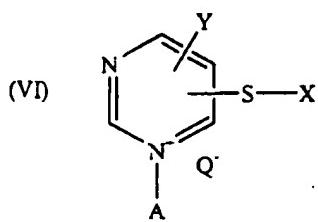
wherein X is a linker; Y is hydrogen or is selected from electron withdrawing, electron neutral, or electron donating groups with Hammett sigma para values between -1.0 and +1.5 comprising carbon-linked groups of the classes defined as A¹, A², A³, and A⁴; S-linked groups including SA¹, SCN, SO₂A¹, SO₃A¹, SSA¹, SOA¹, SO₂NA¹A², SNA¹A², S(NA¹)A², SA¹(NA²), SONA¹A²; O-linked groups including OA¹, OCN, ONA¹A²; N-linked groups including NA¹A², NA¹A²A³, NA¹OA², NA¹SA², NCO, NCS, NO₂, N=NA¹, N=NOA¹, NA¹CN, N=C=NA¹, NA¹NA²A³, NA¹NA²NA³A⁴, NA¹N=NA²; other groups including CONA¹₂, CONA¹COA², C(=NA¹)NA¹A², CHO, CHS, CN, NC, Hal, and derived groups that connect one or more of the optional

substituents via a ring system; Hal is fluorine, chlorine, bromine, or iodine; and wherein A, A¹, A², A³, and A⁴ each represent, independently from one another, a monovalent group which can be the cosmetic active group, R, or H or any of the following: a straight, branched or mono- or polycyclic aliphatic, mono- or polyunsaturated alkyl, aryl, heteroalkyl, heteroaliphatic or heteroolefinic system including 1 to 30 carbon atoms together with 0 to 15 heteroatoms, including oxygen, nitrogen, sulfur, phosphorus, silicon and incorporating one or more substituents including poly or perfluoro substitution; and wherein the counterion, Q⁻, is selected from the group consisting of halides, borates, phosphates, tosylates, mesylates, and triflates.

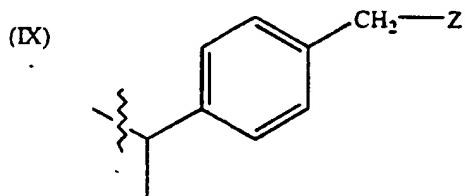
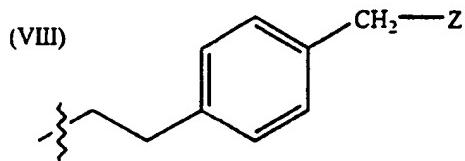
71. A hair care composition comprising the composition of claim 54.
72. A textile care composition comprising the composition of claim 54.
73. A cosmetic composition comprising the composition of claim 54.
74. An oral care composition comprising the composition of claim 54.
75. An animal care composition comprising the composition of claim 54.
76. A silicone composition comprising at least one compound of the formula (II) :



where each R⁷⁻¹⁵ is methyl; Z³ is a pyrimidinium molecular hook of the formula (VI)

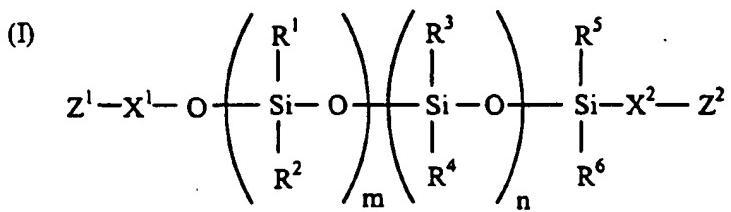


wherein Y is hydrogen, A is methyl; Q is iodide; and X is at least one compound of the formulas (VIII) and (IX) :

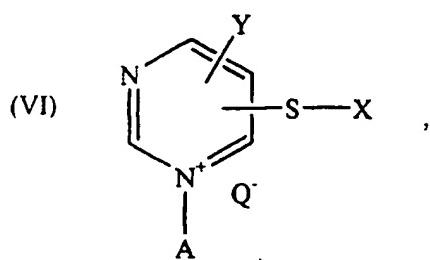


wherein Z is Z³; and wherein "m" has a value in a range between about 15 and about 55; "n" has a value in a range between about 3 and about 6.

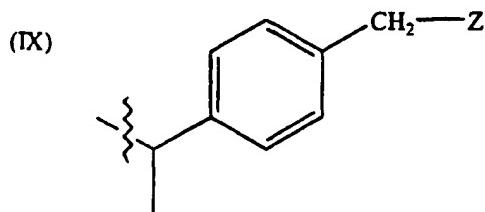
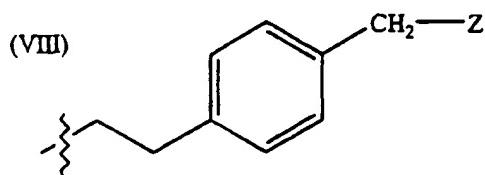
77. A silicone composition comprising at least one compound of the formula (I) :



where each R¹⁻⁶ is methyl; Z¹⁻² are each a pyrimidinium molecular hook of the formula (VI)



wherein Y is hydrogen, A is methyl; Q is iodide; and X is at least one compound of the formulas (VIII) and (IX) :



wherein Z is Z^{1-2} ; and wherein "m+n" has a value in a range between about 18 and about 61.

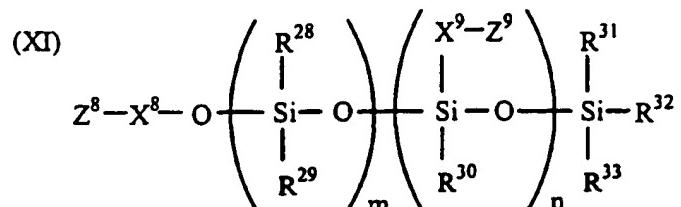
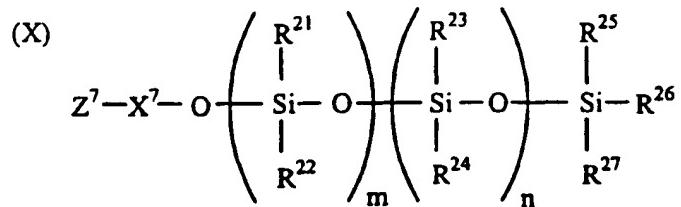
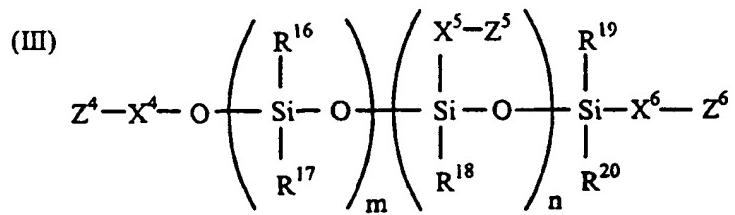
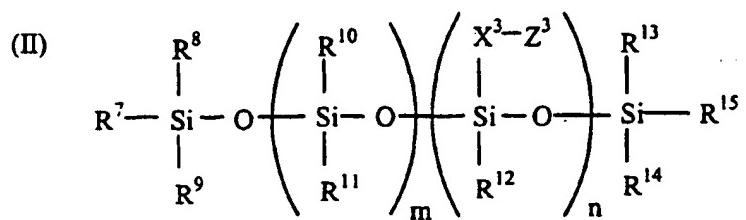
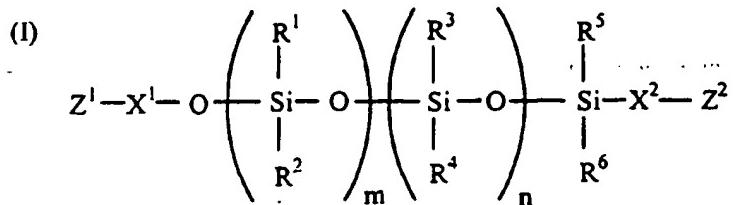
78. A method for making a silicone composition comprising at least one polysiloxane or silicone resin, at least one linker, and at least one molecular hook, which method comprises combining a linker and a molecular hook with a polysiloxane or silicone resin.

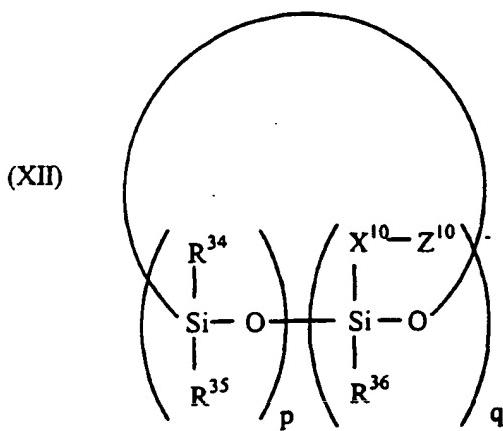
79. The method of claim 78 which comprises combining at least one linker with a polysiloxane or silicone resin and subsequently combining said combination with at least one molecular hook.

80. The method of claim 78 in which the at least one linker is bound to a polysiloxane or silicone resin through a silicon, carbon, oxygen, nitrogen, or sulfur atom.

81. The method of claim 80 in which the at least one linker is bound to a polysiloxane or silicone resin through a silicon atom.

82. The method of claim 78 in which the at least one polysiloxane or silicone resin comprises at least one compound of the following formulas, (I), (II), (III), (X), (XI), or (XII):





where each R¹⁻³⁶ is independently at each occurrence a hydrogen atom, C₁₋₂₂ alkyl, C₁₋₂₂ alkoxy, C₂₋₂₂ alkenyl, C₆₋₁₄ aryl, and C₆₋₂₂ alkyl-substituted aryl, C₆₋₂₂ aralkyl, and C₁₋₂₂ fluoroalkyl; Z¹⁻¹⁰, independently at each occurrence, is a molecular hook; and X¹⁻¹⁰, independently at each occurrence, is a linker; wherein "m" in each formula has a value in a range between about 0 and about 13,000; "n" in each formula has a value in a range between about 0 and about 13,000; "m+n" in each formula has a value in a range between about 1 and about 13,000; "q" has a value of at least one and "p+q" has a value of at least 3.

83. The method of claim 82 in which the average number of X-Z moieties on a polysiloxane or silicone resin is between 1 and 100, preferably between 1 and 6, more preferably between about 3 and about 6.

84. The method of claim 82, wherein the moiety Z-X is prepared by a process which comprises combining a hook with a linker precursor comprising a linker and a leaving group.

85. The method of claim 84, wherein the leaving group is selected from the group consisting of chloride, bromide, iodide, tosylate, mesylate, phosphate, and cyclic leaving groups containing at least one heteroatom.

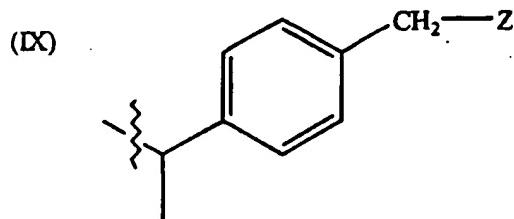
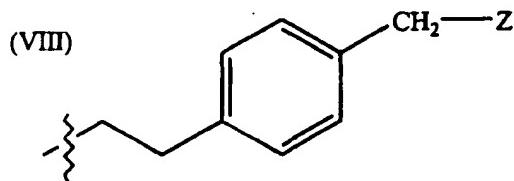
86. The method of claim 85, wherein the leaving group is iodide.

87. The method of claim 78, wherein the linker comprises at least one moiety of the formula -D-Ar(Y)_n-CH₂- wherein "Ar" comprises an aromatic or heteroaromatic group; "Y" is a C₁₋₂₂

straight chain, branched, cycloaliphatic, or aralkyl group; C₆₋₁₄ aryl group; fluoro, chloro, bromo, iodo, nitro, nitr so, nitrile, trifluoromethyl, trifluoropropyl, alkyloxycarbonyl, alkylcarbonyl, alkylamido, alkyl ether group; "n" has a value between zero and the number of free valence sites on the aromatic or heteroaromatic ring; "D" comprises a group bound to a polysiloxane or to a silicone resin, said D group comprising a C₁₋₂₂ straight chain alkyl, branched alkyl, cycloaliphatic, or aralkyl group which optionally may contain a functional group, said functional group being bound to D in a pendent position or separating D from the aromatic or heteroaromatic group, or separating D from a polysiloxane or from a silicone resin, or in more than one of these positions, and wherein said functional group comprises carbonyl, alkylcarbonyl, oxycarbonyl, alkyloxycarbonyl, nitrile, amido, alkylamido, trifluoromethyl, chloro, bromo, or fluoro.

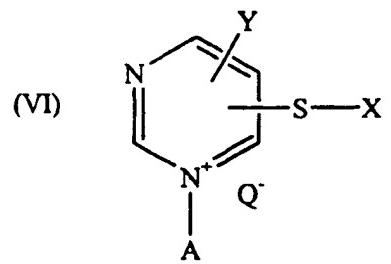
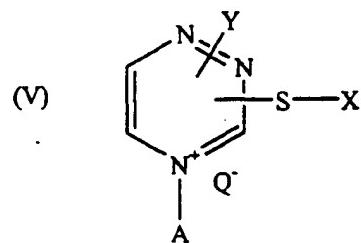
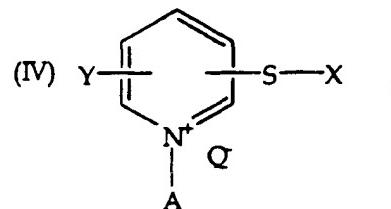
88. The method of claim 87, wherein the aromatic or heteroaromatic group comprises phenyl, biphenyl, toluyl, naphthyl, pyridyl, quinolyl, triazinyl, pyrimidyl, pyridazinyl, furyl, furoyl, or thienyl.

89. The method of claim 87, wherein the linker consists of at least one compound of the formulas (VIII) and (IX) :



90. The method of claim 82, wherein the molecular hook comprises a heterocyclic pyridinium compound, a heterocyclic triazinium compound, or a heterocyclic pyrimidinium compound.

91. The method of claim 90, wherein the molecular hook is at least one member selected from the group consisting of a heterocyclic pyridinium compound (IV), a heterocyclic triazinium (V), and a heterocyclic pyrimidinium compound (VI) :



wherein X is a linker; Y is hydrogen or is selected from electron withdrawing, electron neutral, or electron donating groups with Hammett sigma para values between -1.0 and +1.5 comprising carbon-linked groups of the classes defined as A¹, A², A³, and A⁴; S-linked groups including SA¹, SCN, SO₂A¹, SO₃A¹, SSA¹, SOA¹, SO₂NA¹A², SNA¹A², S(NA¹)A², SA¹(NA²), SONA¹A²; O-linked groups including OA¹, OCN, ONA¹A²; N-linked groups including NA¹A², NA¹A²A³, NA¹OA², NA¹SA², NCO, NCS, NO₂, N=NA¹, N=NOA¹, NA¹CN, N=C=NA¹, NA¹NA²A³, NA¹NA²NA³A⁴, NA¹N=NA²; other groups including CONA¹₂, CONA¹COA², C(=NA¹)NA¹A², CHO, CHS, CN, NC, Hal, and derived groups that connect one or more of the optional substituents via a ring system; Hal is fluorine, chlorine, bromine, or iodine; and wherein A, A¹, A², A³, and A⁴ each represent, independently from one another, a monovalent group which can be the cosmetic active group, R, or H or any of the following: a straight, branched or mono- or

polycyclic aliphatic, mono- or polyunsaturated alkyl, aryl, heteroalkyl, heteroaliphatic or heteroolefinic system including 1 to 30 carbon atoms together with 0 to 15 heteroatoms, including oxygen, nitrogen, sulfur, phosphorus, silicon and incorporating one or more substituents including poly or perfluoro substitution; and wherein the counterion, Q⁻, is selected from the group consisting of halides, borates, phosphates, tosylates, mesylates, and triflates.